

**PROCESS FOR THE PREPARATION OF COMPOUNDS USEFUL AS
INHIBITORS OF SGLT**

CROSS REFERENCE TO RELATED APPLICATIONS

5 This application claims the benefit of U.S. Provisional Application No. 61/106,231, filed on October 17, 2008 and U.S. Provisional Application No. 61/106,260, filed on October 17, 2008, which are incorporated by reference herein in their entirety.

FIELD OF THE INVENTION

10 The present invention is directed to a novel process for the preparation of compounds having inhibitory activity against sodium-dependent glucose transporter (SGLT) being present in the intestine or kidney.

BACKGROUND OF THE INVENTION

15 Diet therapy and exercise therapy are essential in the treatment of diabetes mellitus. When these therapies do not sufficiently control the conditions of patients, insulin or an oral antidiabetic agent is additionally used for the treatment of diabetes. At the present, there have been used as an antidiabetic agent biguanide compounds, sulfonylurea compounds, insulin resistance improving agents and α -glucosidase inhibitors. However, these
20 antidiabetic agents have various side effects. For example, biguanide compounds cause lactic acidosis, sulfonylurea compounds cause significant hypoglycemia, insulin resistance improving agents cause edema and heart failure, and α -glucosidase inhibitors cause abdominal bloating and diarrhea. Under such circumstances, it has been desired to develop novel drugs for
25 treatment of diabetes mellitus having no such side effects.

 Recently, it has been reported that hyperglycemia participates in the onset and progressive impairment of diabetes mellitus, i.e., glucose toxicity theory. Namely, chronic hyperglycemia leads to decrease of insulin secretion and further to decrease of insulin sensitivity, and as a result, the blood glucose
30 concentration is increased so that diabetes mellitus is self-exacerbated [Unger, R.H., et al., "Hyperglycemia as an inducer as well as a consequence of impaired islet cell function and insulin resistance: implication for the management of diabetes", Diabetologia, 1985, vol. 28, pp119-121; Rossetti, L.,

et al., "Glucose Toxicity", Diabetes Care, 1990, vol. 13, no. 6, pp 610-630;]. Therefore, by treating hyperglycemia, the aforementioned self-exacerbating cycle is interrupted so that the prophylaxis or treatment of diabetes mellitus is made possible.

5 As one of the methods for treating hyperglycemia, it is considered to excrete an excess amount of glucose directly into urine so that the blood glucose concentration is normalized. For example, by inhibiting sodium-dependent glucose transporter being present at the proximal convoluted tubule of kidney, the re-absorption of glucose at the kidney is inhibited, by which the
10 excretion of glucose into urine is promoted so that the blood glucose level is decreased. In fact, it is confirmed that by continuous subcutaneous administration of phlorizin having SGLT inhibitory activity to diabetic animal models, hyperglycemia is normalized and the blood glucose level thereof can be kept normal for a long time so that the insulin secretion and insulin
15 resistance are improved [Rossetti, L., et al., "Correction of Hyperglycemia with Phlorizin Normalizes Tissue sensitivity to Insulin in Diabetic Rats", J. Clin. Invest., 1987, vol. 79, pp1510-1515; Rossetti, L., et al., "Effect of Chronic Hyperglycemia on in Vivo Insulin Secretion in Partially Pancreatectomized Rats", J. Clin. Invest., 1987, vol. 80, pp1037-1044; Kahn, B.B., et al.,
20 "Normalization of blood glucose in diabetic rats with phlorizin treatment reverses insulin-resistant glucose transport in adipose cells without restoring glucose transporter gene expression", J. Clin. Invest., 1991, vol. 87, pp561-570]

 In addition, by treating diabetic animal models with SGLT inhibitory
25 agents for a long time, insulin secretion response and insulin sensitivity of the animals are improved without incurring any adverse affects on the kidney or imbalance in blood levels of electrolytes, and as a result, the onset and progress of diabetic nephropathy and diabetic neuropathy are prevented [Tsujihara, K., et al., "Na⁺-Glucose Cotransporter (SGLT) Inhibitors as
30 Antidiabetic Agents. 4. Synthesis and Pharmacological Properties of 4'-Dehydroxyphlorizin Derivatives Substituted on the B Ring", J. Med. Chem., 1999, vol.42, pp5311-5324; Arakawa, K., et al., "Improved diabetic syndrome in C57BL/Ks-db/db mice by oral administration of the Na⁺-glucose cotransporter

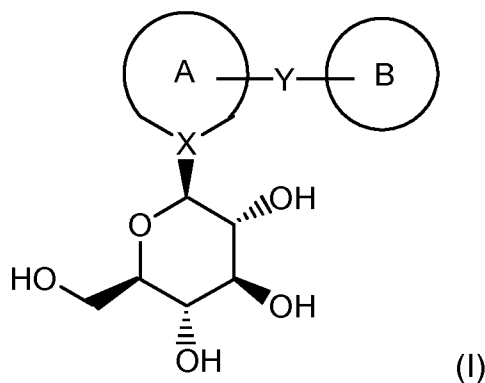
inhibitor T-1095, Br. J. Pharmacol., 2001, vol. 132, pp578-586; Ueta, K., et al., "Long-term treatment with the Na⁺-glucose cotransporter inhibitor T-1095 causes sustained improvement in hyperglycemia and prevents diabetic neuropathy in Goto-kakizaki Rats", Life Sciences, 2005, vol. 76, pp2655-2668]

5 [From the above, SGLT inhibitors may be expected to improve insulin secretion and insulin resistance by decreasing the blood glucose level in diabetic patients and further prevent the onset and progress of diabetes mellitus and diabetic complications.

Nomura, S., et al., United States Patent Application Publication No. 10 2005/0233988, published October 20, 2005, discloses SGLT inhibitors and preparation methods thereof.

SUMMARY OF THE INVENTION

The present invention is directed to a process for the preparation of compounds of formula (I)



wherein Ring A and Ring B are one of the following:

(1) Ring A is an optionally substituted unsaturated monocyclic heterocyclic ring, and Ring B is an optionally substituted unsaturated monocyclic heterocyclic ring, an optionally substituted unsaturated fused heterobicyclic ring, or an optionally substituted benzene ring; or

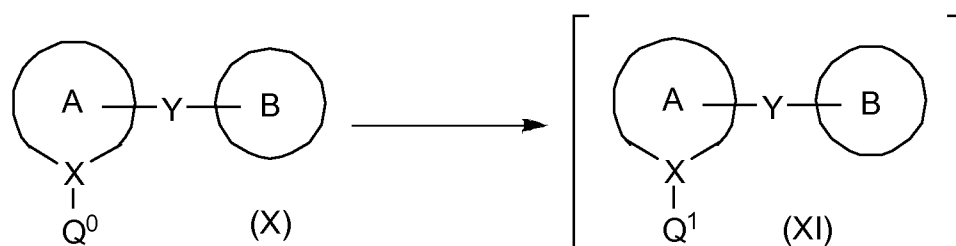
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(2) Ring A is an optionally substituted benzene ring, and Ring B is an optionally substituted unsaturated monocyclic heterocyclic ring, or an optionally substituted unsaturated fused heterobicyclic ring wherein Y is linked to the heterocyclic ring of the fused heterobicyclic ring; or

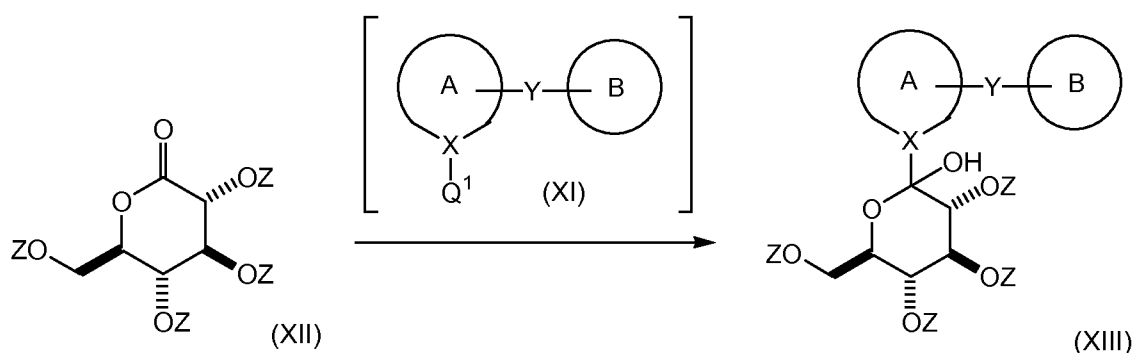
25 (3) Ring A is an optionally substituted unsaturated fused heterobicyclic ring, wherein the sugar moiety X-(sugar) and the moiety -Y-(Ring B) are both

on the same heterocyclic ring of the fused heterobicyclic ring, and Ring B is an optionally substituted unsaturated monocyclic heterocyclic ring, an optionally substituted unsaturated fused heterobicyclic ring, or an optionally substituted benzene ring;

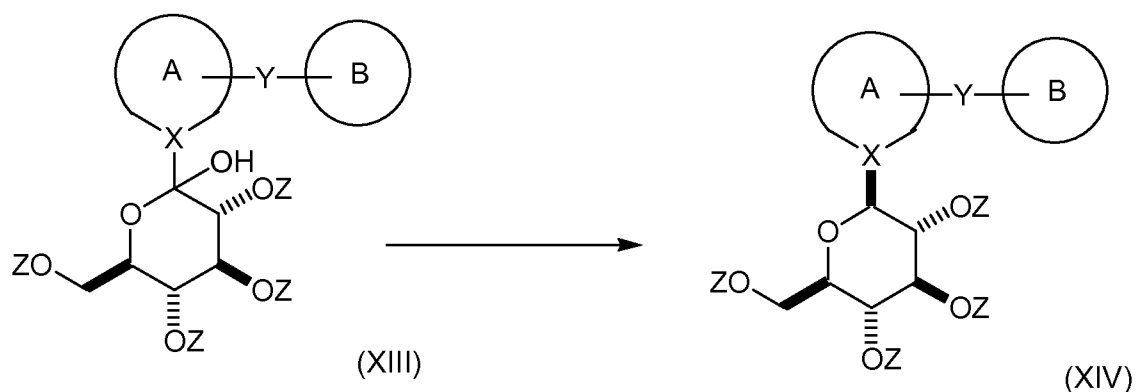
- 5 X is a carbon atom;
 Y is $-(CH_2)_n-$; wherein n is 1 or 2;
 provided that in Ring A, X is part of an unsaturated bond;
 or a pharmaceutically acceptable salt or solvate thereof; comprising



- 10 reacting a compound of formula (X) wherein Q^0 is bromo or iodo, with a complex of di(C_{1-4} alkyl)magnesium with lithium chloride or a complex of C_{1-4} alkyl magnesium chloride with lithium chloride or a complex of C_{1-4} alkyl magnesium bromide with lithium chloride; in an organic solvent or mixture thereof; at a temperature in the range of from about ambient temperature to
- 15 about -78°C ; to yield the corresponding compound of formula (XI), wherein Q^1 is the corresponding MgCl or MgBr ;

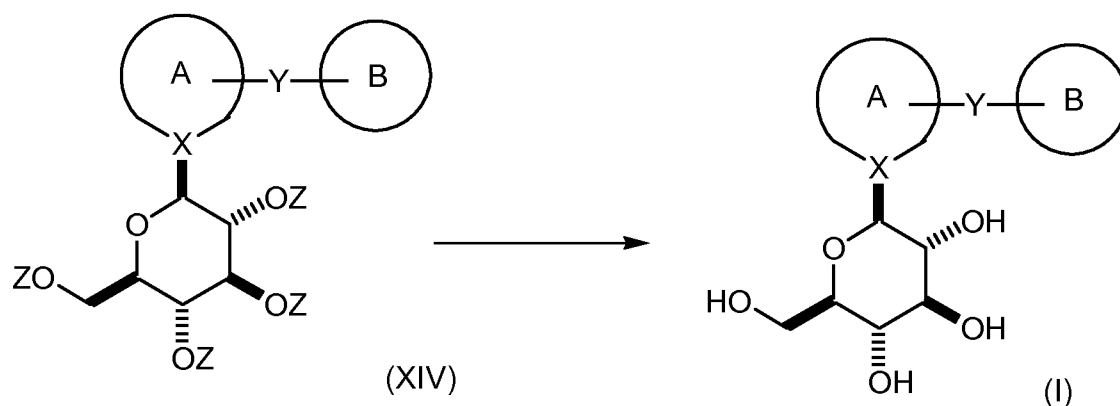


- reacting the compound of formula (XI) with a compound of formula (XII), wherein Z is an oxygen protecting group; in an organic solvent or mixture
- 20 thereof; at a temperature in the range of from about ambient temperature to about -78°C ; to yield the corresponding compound of formula (XIII);



reacting the compound of formula (XIII) with a Lewis acid; in the presence of a silane reagent; in an organic solvent or mixture thereof; at a temperature in the range of from about 0°C to about reflux; to yield the

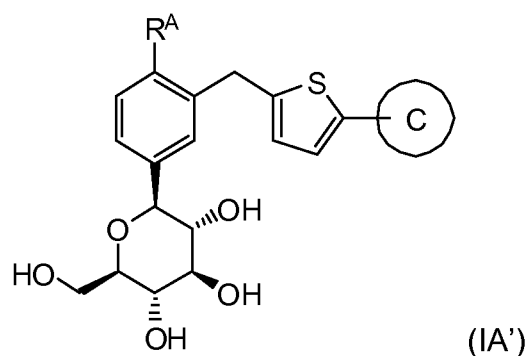
5 corresponding compound of formula (XIV);



de-protecting the compound of formula (XIV); to yield the corresponding compound of formula (I).

In an embodiment, the present invention is directed to a novel process

10 for the preparation of compounds of formula (IA')



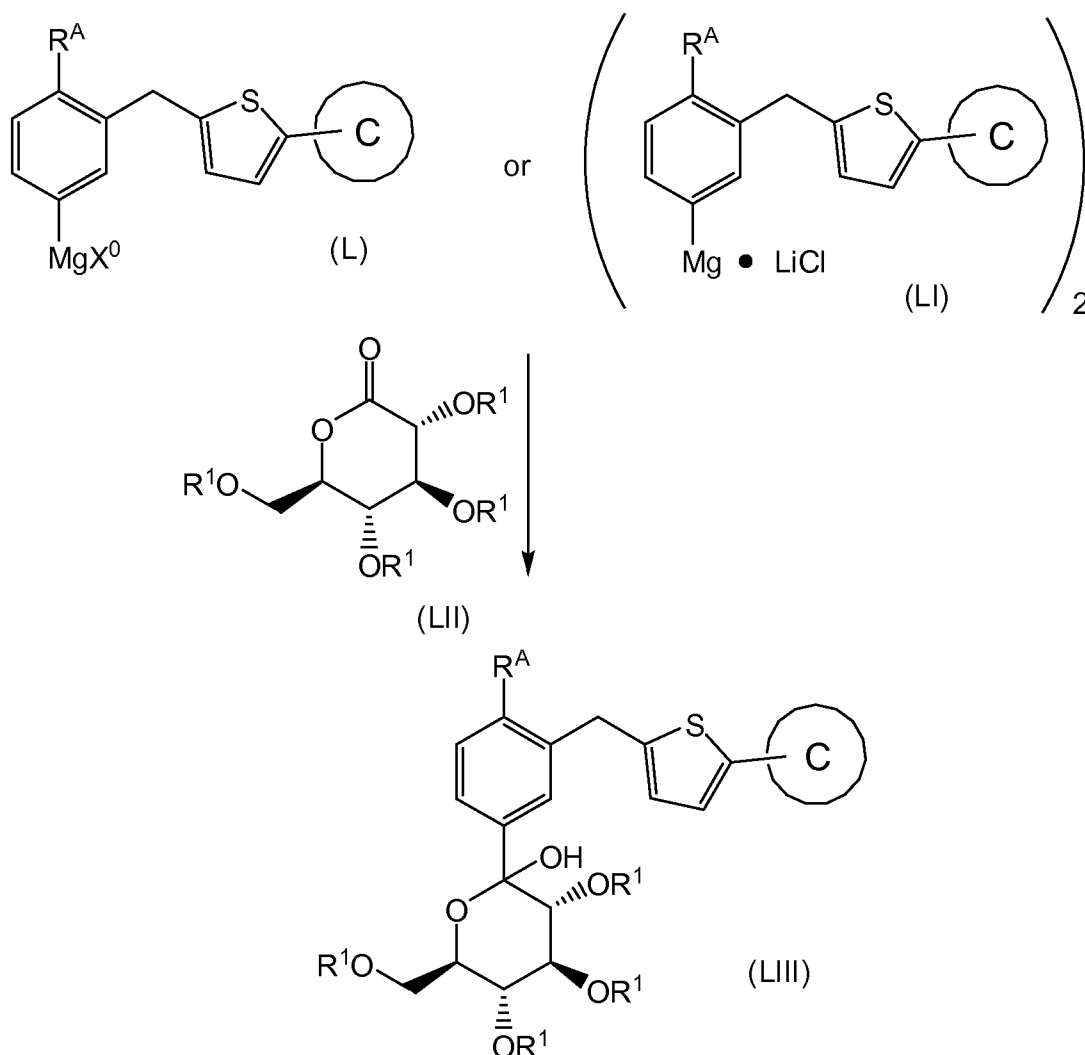
wherein

R^A is halogen or lower alkyl;

Ring C is phenyl substituted with 1-3 substituents selected from the group consisting of halogen, cyano, lower alkyl, halo-lower alkyl, lower alkoxy, halo-lower alkoxy, methylenedioxy, ethyleneoxy, mono- or di-lower alkylamino, carbamoyl, and mono- or di-lower alkylcarbamoyl;

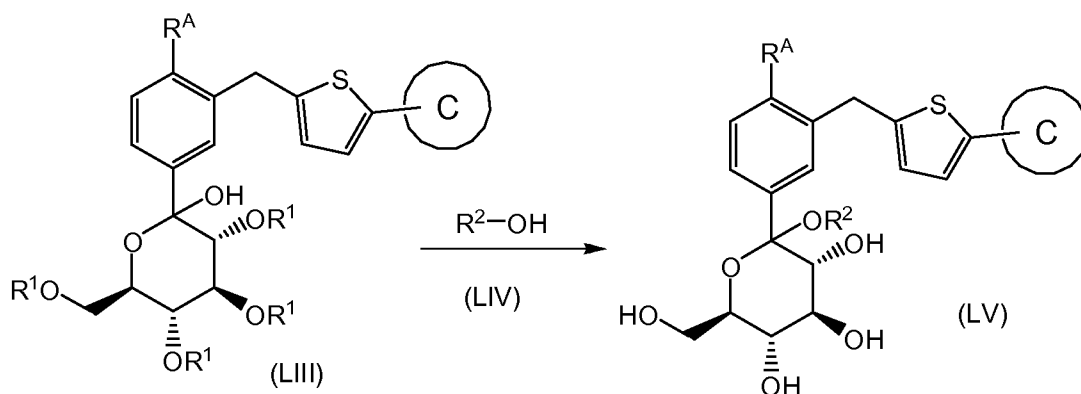
- 5 or heterocyclyl substituted by 1-3 substituents selected from the group consisting of halogen, cyano, lower alkyl, halo-lower alkyl, lower alkoxy, halo-lower alkoxy, mono- or di-lower alkylamino, carbamoyl, and mono- or di-lower alkylcarbamoyl;

and pharmaceutically acceptable salts thereof; comprising steps of:

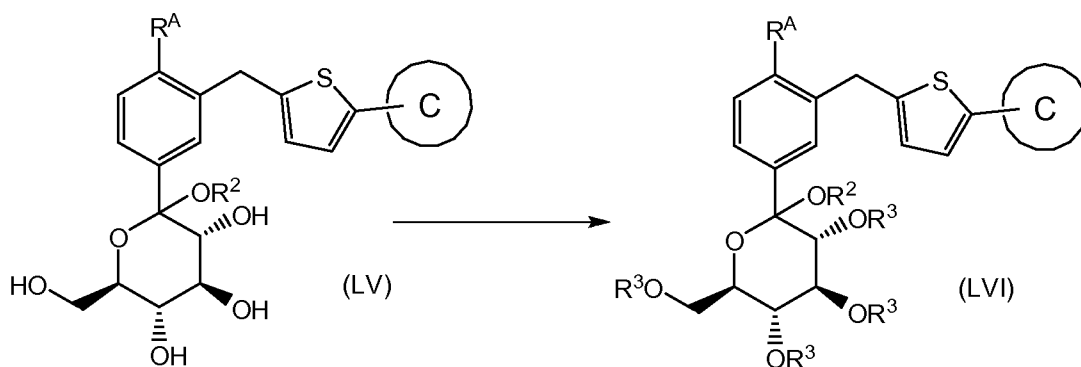


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reacting a compound of formula (L) wherein X^0 is selected from the group consisting of Cl, Br, I and $Cl \bullet LiCl$ or a compound of formula (LI) with a compound of formula (LII), wherein R^1 is tri-lower alkyl silyl; to yield the corresponding compound of formula (LIII);

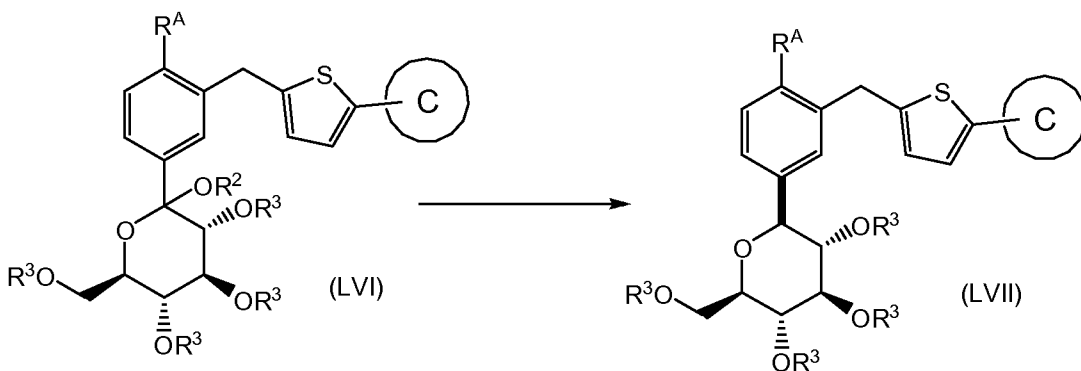


reacting the compound of formula (LIII) with an alcohol of formula (LIV), wherein R^2 is lower alkyl; in the presence of an acid; to yield the corresponding compound of formula (LV);



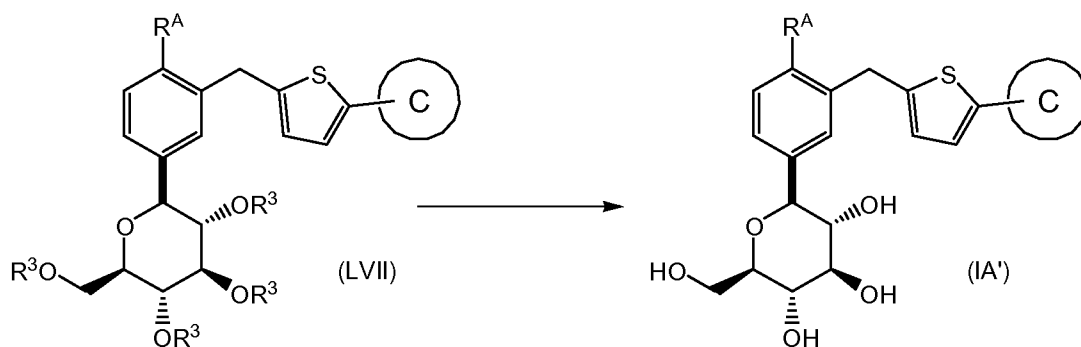
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protecting the hydroxyl groups on the compound of formula (LV); to yield the corresponding compound of formula (LVI); wherein each R^3 is an hydroxyl protecting group;



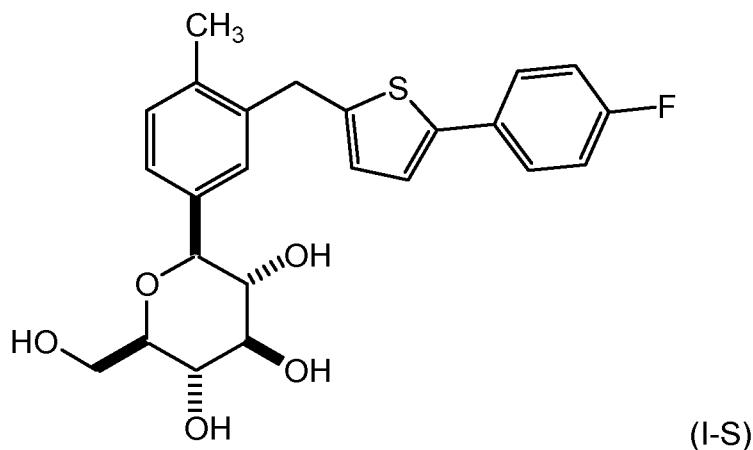
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reducing the compound of formula (LVI); to yield the corresponding compound of formula (LVII);

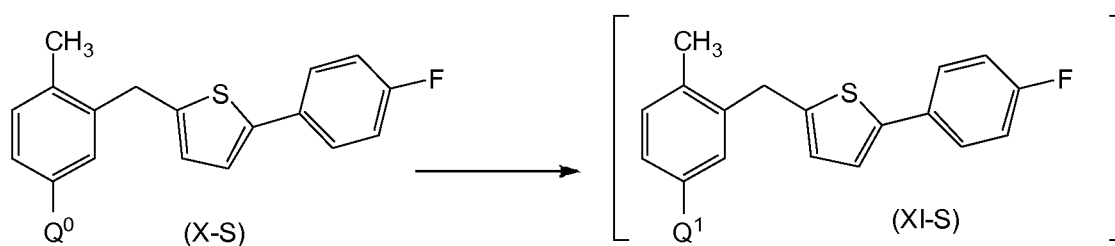


removing the protecting groups on the hydroxyls of the compound of formula (LVII); to yield the corresponding compound of formula (IA').

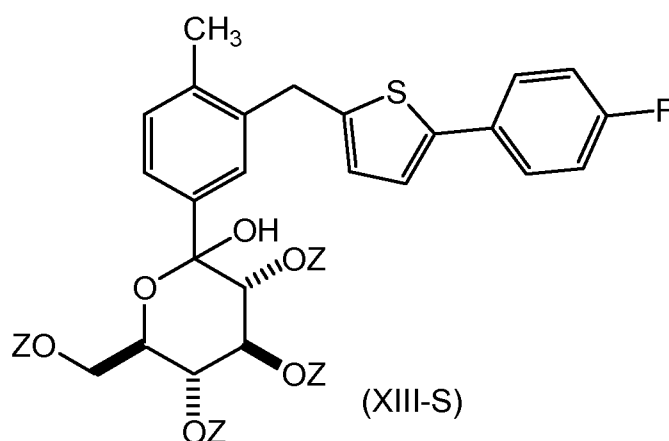
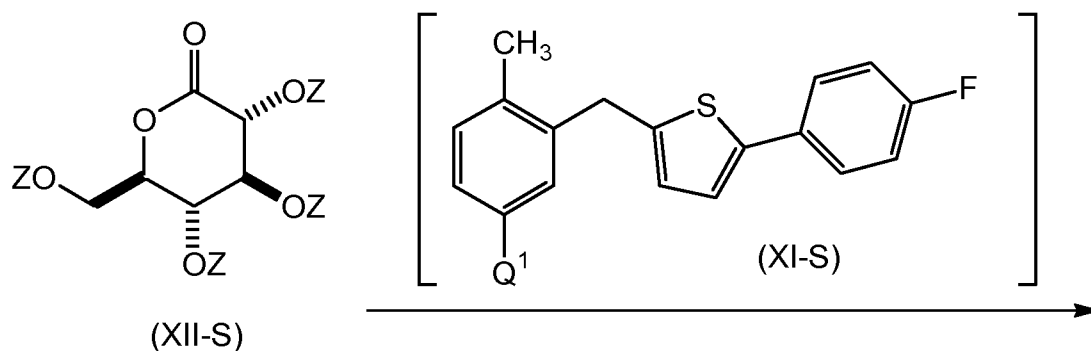
In an embodiment, the present invention is directed to a process for the
 5 preparation of a compound of formula (I-S)



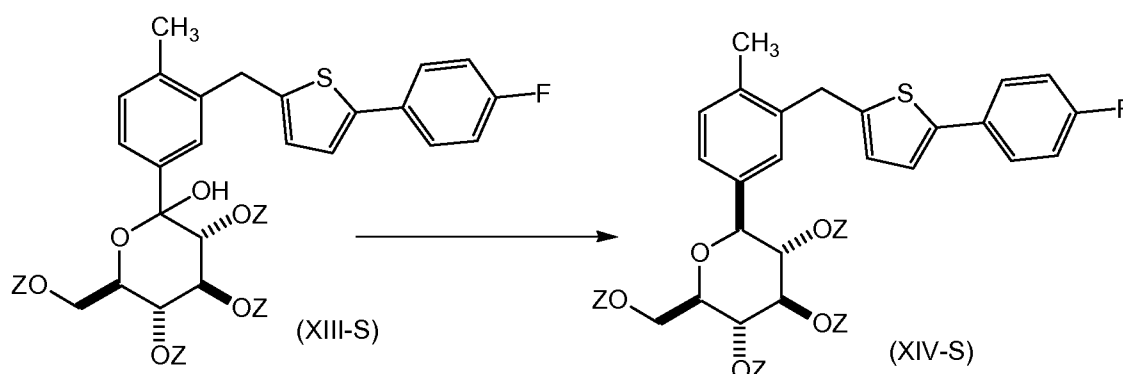
or solvate thereof; (also known as 1-(β-D-glucopyranosyl)-4-methyl-3-[5-(4-fluorophenyl)-2-thienylmethyl]benzene); comprising



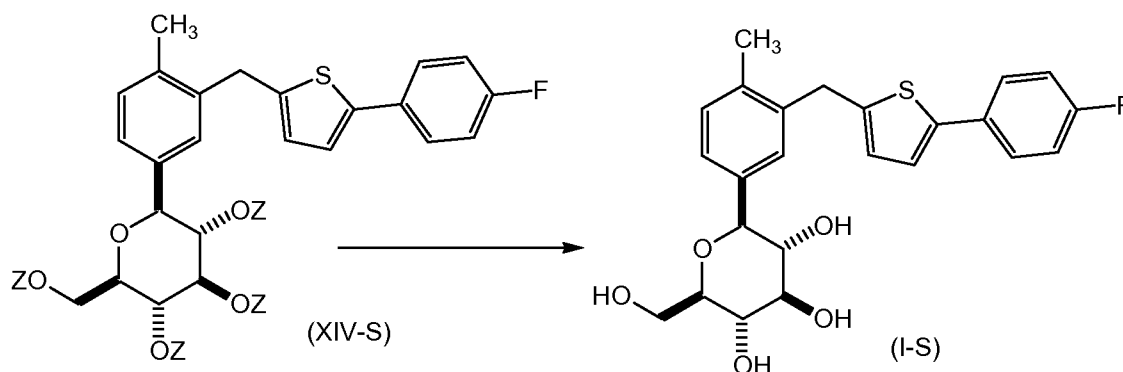
10 reacting a compound of formula (X-S) wherein Q^0 is bromo or iodo, with a complex of di(C_{1-4} alkyl)magnesium with lithium chloride or a complex of C_{1-4} alkyl magnesium chloride with lithium chloride or a complex of C_{1-4} alkyl magnesium bromide with lithium chloride; in an organic solvent or mixture thereof; at a temperature in the range of from about ambient temperature to
 15 about -78°C ; to yield the corresponding compound of formula (XI-S), wherein Q^1 is the corresponding MgCl or MgBr;



reacting the compound of formula (XI-S) with a compound of formula (XII-S), wherein Z is an oxygen protecting group; in an organic solvent or mixture thereof; at a temperature in the range of from about ambient
 5 temperature to about -78°C; to yield the corresponding compound of formula (XIII-S);

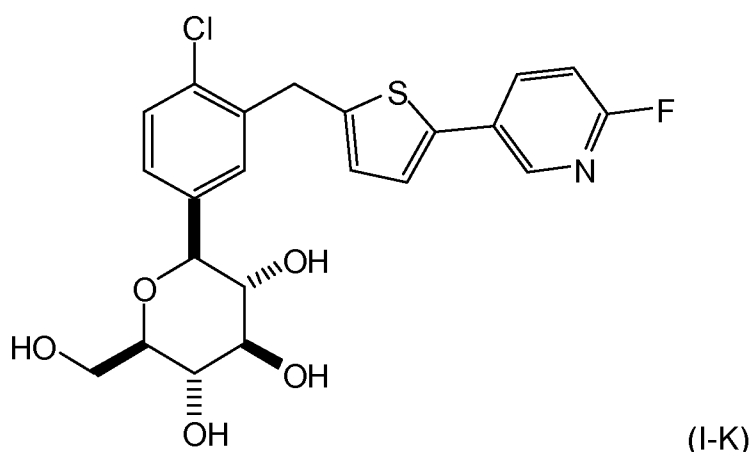


reacting the compound of formula (XIII-S) with a Lewis acid; in the presence of a silane reagent; in an organic solvent or mixture thereof; at a
 10 temperature in the range of from about 0°C to about reflux; to yield the corresponding compound of formula (XIV-S);

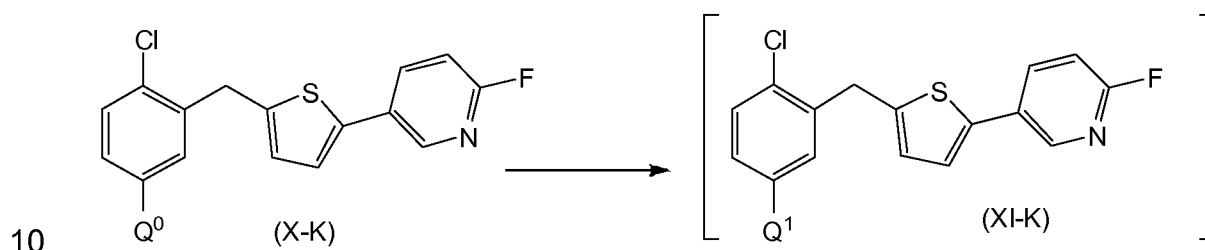


de-protecting the compound of formula (XIV-S); to yield the corresponding compound of formula (I-S).

In another embodiment, the present invention is directed to a process for
5 the preparation of a compound of formula (I-K)

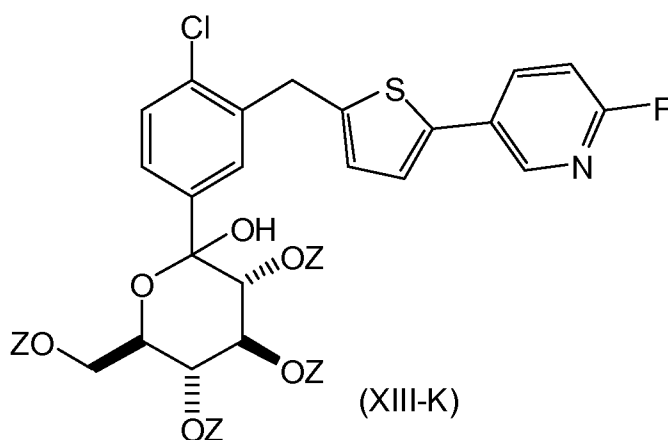
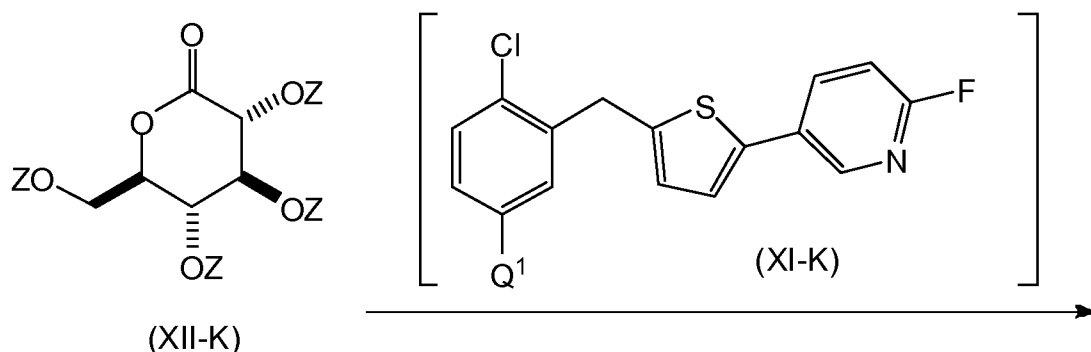


or pharmaceutically acceptable salt or solvate thereof; (also known as 1-(β-D-glucopyranosyl)-4-chloro-3-[5-(4-fluoro-3-pyridyl)-2-thienylmethyl]benzene); comprising

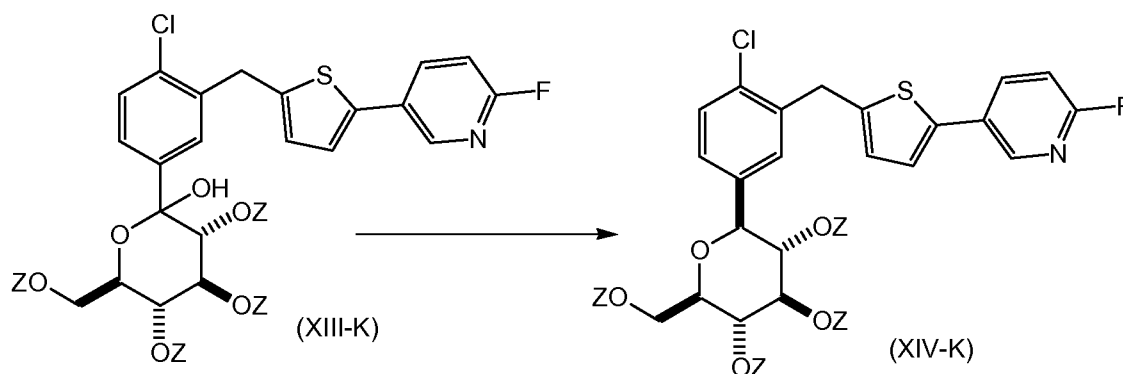


10 reacting a compound of formula (X-K) wherein Q^0 is bromo or iodo with a complex of di(C_{1-4} alkyl)magnesium with lithium chloride or a complex of C_{1-4} alkyl magnesium chloride with lithium chloride or a complex of C_{1-4} alkyl magnesium bromide with lithium chloride; in an organic solvent or mixture
15 thereof; at a temperature in the range of from about ambient temperature to

about -78°C ; to yield the corresponding compound of formula (XI-K), wherein Q^1 is the corresponding MgCl or MgBr ;

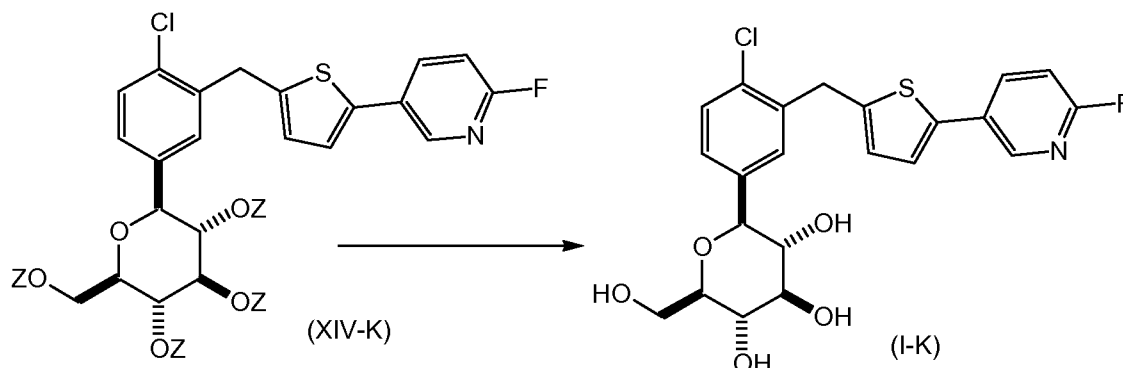


reacting the compound of formula (XI-K) with a compound of formula (XII-K), wherein Z is an oxygen protecting group; in an organic solvent or mixture thereof; at a temperature in the range of from about ambient temperature to about -78°C ; to yield the corresponding compound of formula (XIII-K);



reacting the compound of formula (XIII-K) with a Lewis acid; in the presence of a silane reagent; in an organic solvent or mixture thereof; at a

temperature in the range of from about 0°C to about reflux; to yield the corresponding compound of formula (XIV-K);



de-protecting the compound of formula (XIV-K); to yield the
5 corresponding compound of formula (I-K).

The present invention is further directed to processes for the preparation of compounds of formula (X-S) and compounds of formula (X-K), as described in more detail in Scheme 4 and 5, which follow herein.

The present invention is further directed to a product prepared according
10 to any of the processes described herein.

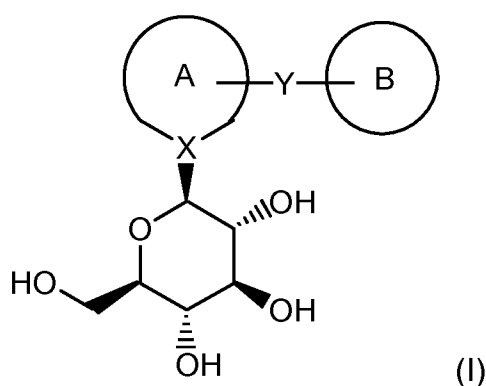
Illustrative of the invention is a pharmaceutical composition comprising a pharmaceutically acceptable carrier and the product prepared according to any of the processes described herein. An illustration of the invention is a pharmaceutical composition made by mixing the product prepared according to any of the processes described herein and a pharmaceutically acceptable carrier. Illustrating the invention is a process for making a pharmaceutical composition comprising mixing the product prepared according to any of the processes described herein and a pharmaceutically acceptable carrier.

Exemplifying the invention are methods of treating a disorder mediated by SGLT (including treating or delaying the progression or onset of diabetes mellitus, diabetic retinopathy, diabetic neuropathy, diabetic nephropathy, delayed wound healing, insulin resistance, hyperglycemia, hyperinsulinemia, elevated blood levels of fatty acids, elevated blood levels of glycerol, hyperlipidemia, obesity, hypertriglyceridemia, Syndrome X, diabetic complications, atherosclerosis, or hypertension,) comprising administering to the subject in need thereof a therapeutically effective amount of any of the compounds or pharmaceutical compositions described above.

Further exemplifying the invention are methods of treating type 1 and type 2 diabetes mellitus, comprising administering to a subject in need of treatment a therapeutically effective amount of a therapeutically effective amount of any of the compounds or pharmaceutical compositions described above, alone or in combination with at least one antidiabetic agent, agent for treating diabetic complications, anti-obesity agent, antihypertensive agent, antiplatelet agent, anti-atherosclerotic agent and/or hypolipidemic agent.

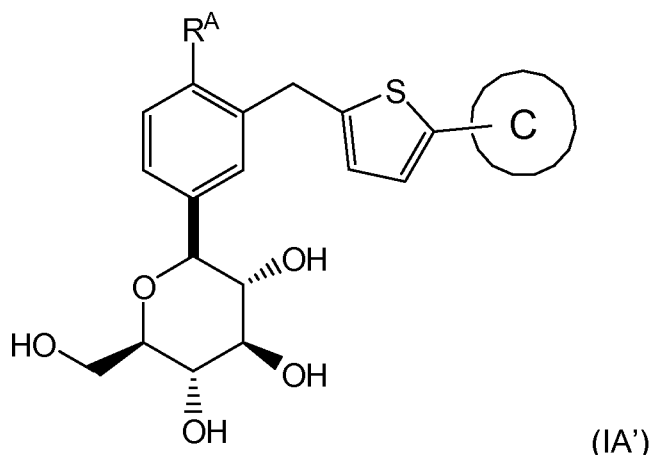
DETAILED DESCRIPTION OF THE INVENTION

The present invention is directed to a process for the preparation of compounds of formula (I)



wherein X, Y, Ring A and Ring B are as herein defined; and pharmaceutically acceptable salts or solvates thereof; as described in more detail herein. The compounds of the formula (I) exhibits an inhibitory activity against sodium-dependent glucose transporter being present in the intestine and the kidney of mammalian species, and is useful in the treatment of diabetes mellitus or diabetic complications such as diabetic retinopathy, diabetic neuropathy, diabetic nephropathy, obesity, and delayed wound healing. In an embodiment, the present invention is directed to a process for the preparation of a compound of formula (I-S), as described in more detail herein. In another embodiment, the present invention is directed to a process for the preparation of a compound of formula (I-K), as described in more detail herein.

The present invention is further directed to a process for the preparation of compounds of formula (IA')



wherein R^A and Ring C are as herein defined; and pharmaceutically acceptable salts thereof. The compounds of formula (IA') are known to possess activity as inhibitors of sodium-dependent glucose transporters, and show excellent blood glucose lowering effect. The compounds of formula (IA') may therefore be useful for the treatment or prevention of diabetes mellitus, diabetic complications (e.g., diabetic retinopathy, diabetic neuropathy, and diabetic nephropathy), and related diseases such as obesity.

The present invention is further directed to processes for the preparation of compounds of formula (X-S) and compounds of formula (X-K), which compounds are intermediates useful in the synthesis of the compounds of formula (I), more particularly, in the synthesis of the compound of formula (I-S) and compound of formula (I-K).

The term “**halogen**”, shall include chlorine, bromine, fluorine and iodine. When referring to substituents on the compound of formula (I), the term “**halogen atom**” or “**halo**” shall mean chlorine, bromine and fluorine, and chlorine and fluorine are preferable.

The term “**alkyl group**” means a straight or branched saturated monovalent hydrocarbon chain having 1 to 12 carbon atoms. The straight chain or branched chain alkyl group having 1 to 6 carbon atoms is preferable, and the straight chain or branched chain alkyl group having 1 to 4 carbon atoms is more preferable. Examples thereof are methyl group, ethyl group, propyl group, isopropyl group, butyl group, t-butyl group, isobutyl group, pentyl group, hexyl group, isohexyl group, heptyl group, 4,4-dimethylpentyl group, octyl group, 2,2,4-trimethylpentyl group, nonyl group, decyl group, and various

branched chain isomers thereof. Further, the alkyl group may optionally and independently be substituted by 1 to 4 substituents as listed below, if necessary.

The term "**lower alkyl**" means a straight or branched saturated monovalent hydrocarbon chain having 1 to 6 carbon atoms. Preferably, "lower alkyl" means a straight or branched carbon chain having 1 to 4 carbon atoms. Most preferably, "lower alkyl" means a straight carbon chain having one or two carbon atoms. Examples of "lower alkyl" include methyl, ethyl, propyl, isopropyl, butyl, t-butyl, isobutyl, pentyl, hexyl and various branched chain isomers thereof.

The term "**alkylene group**" or "**alkylene**" means a straight or branched divalent saturated hydrocarbon chain having 1 to 12 carbon atoms. The straight chain or branched chain alkylene group having 1 to 6 carbon atoms is preferable, and the straight chain or branched chain alkylene group having 1 to 4 carbon atoms is more preferable. Examples thereof are methylene group, ethylene group, propylene group, trimethylene group, etc. If necessary, the alkylene group may optionally be substituted in the same manner as the above-mentioned "alkyl group". Where alkylene groups as defined above attach at two different carbon atoms of the benzene ring, they form an annelated five, six or seven membered carbocycle together with the carbon atoms to which they are attached, and may optionally be substituted by one or more substituents defined below.

The term "**alkenyl group**" means a straight or branched monovalent hydrocarbon chain having 2 to 12 carbon atoms and having at least one double bond. Preferable alkenyl group is a straight chain or branched chain alkenyl group having 2 to 6 carbon atoms, and the straight chain or branched chain alkenyl group having 2 to 4 carbon atoms is more preferable. Examples thereof are vinyl group, 2-propenyl group, 3-butenyl group, 2-butenyl group, 4-pentenyl group, 3-pentenyl group, 2-hexenyl group, 3-hexenyl group, 2-heptenyl group, 3-heptenyl group, 4-heptenyl group, 3-octenyl group, 3-nonenyl group, 4-decenyl group, 3-undecenyl group, 4-dodecenyl group, 4,8,12-tetradecatrienyl group, etc. The alkenyl group may optionally and

independently be substituted by 1 to 4 substituents as mentioned below, if necessary.

The term “**alkenylene group**” means a straight or branched divalent hydrocarbon chain having 2 to 12 carbon atoms and having at least one double bond. The straight chain or branched chain alkenylene group having 2 to 6 carbon atoms is preferable, and the straight chain or branched chain alkenylene group having 2 to 4 carbon atoms is more preferable. Examples thereof are vinylene group, propenylene group, butadienylene group, etc. If necessary, the alkylene group may optionally be substituted by 1 to 4 substituents as mentioned below, if necessary. Where alkenylene groups as defined above attach at two different carbon atoms of the benzene ring, they form an annelated five, six or seven membered carbocycle (e.g., a fused benzene ring) together with the carbon atoms to which they are attached, and may optionally be substituted by one or more substituents defined below.

The term “**alkynyl group**” means a straight or branched monovalent hydrocarbon chain having at least one triple bond. The preferable alkynyl group is a straight chain or branched chain alkynyl group having 2 to 6 carbon atoms, and the straight chain or branched chain alkynyl group having 2 to 4 carbon atoms is more preferable. Examples thereof are 2-propynyl group, 3-butynyl group, 2-butynyl group, 4-pentynyl group, 3-pentynyl group, 2-hexynyl group, 3-hexynyl group, 2-heptynyl group, 3-heptynyl group, 4-heptynyl group, 3-octynyl group, 3-nonyl group, 4-decynyl group, 3-undecynyl group, 4-dodecynyl group, etc. The alkynyl group may optionally and independently be substituted by 1 to 4 substituents as mentioned below, if necessary.

The term “**cycloalkyl group**” means a monocyclic or bicyclic monovalent saturated hydrocarbon ring having 3 to 12 carbon atoms, and the monocyclic saturated hydrocarbon group having 3 to 7 carbon atoms is more preferable. Examples thereof are a monocyclic alkyl group and a bicyclic alkyl group such as cyclopropyl group, cyclobutyl group, cyclopentyl group, cyclohexyl group, cycloheptyl group, cyclooctyl group, cyclodecyl group, etc. These groups may optionally and independently be substituted by 1 to 4 substituents as mentioned below, if necessary. The cycloalkyl group may optionally be condensed with a saturated hydrocarbon ring or an unsaturated

hydrocarbon ring (said saturated hydrocarbon ring and unsaturated hydrocarbon ring may optionally contain an oxygen atom, a nitrogen atom, a sulfur atom, SO or SO₂ within the ring, if necessary), and the condensed saturated hydrocarbon ring and the condensed unsaturated hydrocarbon ring may be optionally and independently be substituted by 1 to 4 substituents as mentioned below.

The term “**cycloalkylidene group**” means a monocyclic or bicyclic divalent saturated hydrocarbon ring having 3 to 12 carbon atoms, and the monocyclic saturated hydrocarbon group having 3 to 6 carbon atoms is preferable. Examples thereof are a monocyclic alkylidene group and a bicyclic alkylidene group such as cyclopropylidene group, cyclobutylidene group, cyclopentylidene group, cyclohexylidene group, etc. These groups may optionally and independently be substituted by 1 to 4 substituents as mentioned below, if necessary. Besides, the cycloalkylidene group may optionally be condensed with a saturated hydrocarbon ring or an unsaturated hydrocarbon ring (said saturated hydrocarbon ring and unsaturated hydrocarbon ring may optionally contain an oxygen atom, a nitrogen atom, a sulfur atom, SO or SO₂ within the ring, if necessary), and the condensed saturated hydrocarbon ring and the unsaturated hydrocarbon ring may be optionally and independently be substituted by 1 to 4 substituents as mentioned below.

The term “**cycloalkenyl group**” means a monocyclic or bicyclic monovalent unsaturated hydrocarbon ring having 4 to 12 carbon atoms and having at least one double bond. The preferable cycloalkenyl group is a monocyclic unsaturated hydrocarbon group having 4 to 7 carbon atoms. Examples thereof are monocyclic alkenyl groups such as cyclopentenyl group, cyclopentadienyl group, cyclohexenyl group, etc. These groups may optionally and independently be substituted by 1 to 4 substituents as mentioned below, if necessary. Besides, the cycloalkenyl group may optionally be condensed with a saturated hydrocarbon ring or an unsaturated hydrocarbon ring (said saturated hydrocarbon ring and unsaturated hydrocarbon ring may optionally contain an oxygen atom, a nitrogen atom, a sulfur atom, SO or SO₂ within the ring, if necessary), and the condensed saturated hydrocarbon ring and the

unsaturated hydrocarbon ring may be optionally and independently be substituted by 1 to 4 substituents as mentioned below.

The term “**cycloalkynyl group**” means a monocyclic or bicyclic unsaturated hydrocarbon ring having 6 to 12 carbon atoms, and having at least one triple bond. The preferable cycloalkynyl group is a monocyclic unsaturated hydrocarbon group having 6 to 8 carbon atoms. Examples thereof are monocyclic alkynyl groups such as cyclooctynyl group, cyclodecynyl group. These groups may optionally be substituted by 1 to 4 substituents as mentioned below, if necessary. Besides, the cycloalkynyl group may optionally and independently be condensed with a saturated hydrocarbon ring or an unsaturated hydrocarbon ring (said saturated hydrocarbon ring and unsaturated hydrocarbon ring may optionally contain an oxygen atom, a nitrogen atom, a sulfur atom, SO or SO₂ within the ring, if necessary), and the condensed saturated hydrocarbon ring or the unsaturated hydrocarbon ring may be optionally and independently be substituted by 1 to 4 substituents as mentioned below.

The term “**aryl group**” means a monocyclic or bicyclic monovalent aromatic hydrocarbon group having 6 to 10 carbon atoms. Examples thereof are phenyl group, naphthyl group (including 1-naphthyl group and 2-naphthyl group). These groups may optionally and independently be substituted by 1 to 4 substituents as mentioned below, if necessary. Besides, the aryl group may optionally be condensed with a saturated hydrocarbon ring or an unsaturated hydrocarbon ring (said saturated hydrocarbon ring and unsaturated hydrocarbon ring may optionally contain an oxygen atom, a nitrogen atom, a sulfur atom, SO or SO₂ within the ring, if necessary), and the condensed saturated hydrocarbon ring or the unsaturated hydrocarbon ring may be optionally and independently be substituted by 1 to 4 substituents as mentioned below.

The term “**unsaturated monocyclic heterocyclic ring**” means an unsaturated hydrocarbon ring containing 1-4 heteroatoms independently selected from a nitrogen atom, an oxygen atom and a sulfur atom, and the preferable one is a 4- to 7-membered saturated or unsaturated hydrocarbon ring containing 1-4 heteroatoms independently selected from a nitrogen atom,

an oxygen atom and a sulfur atom. Examples thereof are pyridine, pyrimidine, pyrazine, furan, thiophene, pyrrole, imidazole, pyrazole, oxazole, isoxazole, 4,5-dihydrooxazole, thiazole, isothiazole, thiadiazole, triazole, tetrazole, etc.

Among them, pyridine, pyrimidine, pyrazine, furan, thiophene, pyrrole,

- 5 imidazole, oxazole, and thiazole can be preferably used. The "unsaturated monocyclic heterocyclic ring" may optionally and independently be substituted by 1-4 substituents as mentioned below, if necessary.

- The term "**unsaturated fused heterobicyclic ring**" means hydrocarbon ring comprised of a saturated or a unsaturated hydrocarbon ring condensed
10 with the above mentioned unsaturated monocyclic heterocyclic ring where said saturated hydrocarbon ring and said unsaturated hydrocarbon ring may optionally contain an oxygen atom, a nitrogen atom, a sulfur atom, SO, or SO₂ within the ring, if necessary. The "unsaturated fused heterobicyclic ring" includes, for example, benzothiophene, indole, tetrahydrobenzothiophene,
15 benzofuran, isoquinoline, thienothiophene, thienopyridine, quinoline, indoline, isoindoline, benzothiazole, benzoxazole, indazole, dihydroisoquinoline, etc. Further, the "heterocyclic ring" also includes possible N- or S-oxides thereof.

- The term "**heterocyclyl**" means a monovalent group of the above-mentioned unsaturated monocyclic heterocyclic ring or unsaturated fused
20 heterobicyclic ring and a monovalent group of the saturated version of the above-mentioned unsaturated monocyclic heterocyclic or unsaturated fused heterobicyclic ring. If necessary, the heterocyclyl may optionally and independently be substituted by 1 to 4 substituents as mentioned below.

- In an embodiment of the present invention, in compounds of formula
25 (IA'), the term "heterocyclyl" refers to a monovalent group of an unsaturated hydrocarbon ring containing 1-4 heteroatoms independently selected from a nitrogen atom, an oxygen atom and a sulfur atom, and the preferable one is a 4- to 7-membered saturated or unsaturated hydrocarbon ring containing 1-4 heteroatoms independently selected from a nitrogen atom, an oxygen atom and
30 a sulfur atom. Examples of "heterocyclyl" include pyridyl, pyrimidyl, pyrazinyl, furyl, thienyl, pyrrolyl, imidazolyl, pyrazolyl, oxazolyl, isoxazolyl, 4,5-dihydrooxazolyl, thiazolyl, isothiazolyl, thiadiazolyl, triazolyl, and tetrazolyl.

Preferable examples of "heterocyclyl" include pyridyl, pyrimidyl, pyrazinyl, furyl, thienyl, pyrrolyl, imidazolyl, oxazolyl, and thiazolyl.

The term "**alkanoyl group**" means a formyl group and ones formed by binding an "alkyl group" to a carbonyl group.

- 5 The term "**alkoxy group**" means ones formed by binding an "alkyl group" to an oxygen atom.

The term "**lower alkoxy**" refers to the above lower alkyl group linked to an oxygen atom. Preferably, "lower alkoxy" means a straight or branched alkyl-oxy group having 1 to 4 carbon atoms. Examples of "lower alkoxy" include
10 methoxy, ethoxy, propoxy, isopropoxy, butoxy, t-butoxy, isobutoxy, pentyloxy, hexyloxy and various branched chain isomers thereof.

The **substituent** for the above each group includes, for example, a halogen atom (fluorine, chlorine, bromine), a nitro group, a cyano group, an oxo group, a hydroxy group, a mercapto group, a carboxyl group, a sulfo group, an
15 alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, a cycloalkenyl group, a cycloalkynyl group, an aryl group, a heterocyclyl group, an alkoxy group, an alkenyloxy group, an alkynyloxy group, a cycloalkyloxy group, a cycloalkenyloxy group, a cycloalkynyloxy group, an aryloxy group, a heterocyclyloxy group, an alkanoyl
20 group, an alkenylcarbonyl group, an alkynylcarbonyl group, a cycloalkylcarbonyl group, a cycloalkenylcarbonyl group, a cycloalkynylcarbonyl group, an arylcarbonyl group, a hetero-cyclylcarbonyl group, an alkoxy-carbonyl group, an alkenyloxy-carbonyl group, an alkynyloxy-carbonyl group, a cycloalkyloxy-carbonyl group, a cycloalkenyl-oxy-carbonyl group, a cyclo-
25 alkynyl-oxycarbonyl group, an aryloxycarbonyl group, a hetero-cyclyloxycarbonyl group, an alkanoyloxy group, an alkenyl-carbonyloxy group, an alkynyl-carbonyloxy group, a cycloalkyl-carbonyloxy group, a cycloalkenyl-carbonyloxy group, a cycloalkynyl-carbonyloxy group, an arylcarbonyloxy group, a hetero-cyclylcarbonyloxy group, an alkylthio group, an alkenyl-thio
30 group, an alkynylthio group, a cycloalkylthio group, a cycloalkenyl-thio group, a cycloalkynylthio group, an arylthio group, a heterocyclylthio group, an amino group, a mono- or di-alkyl-amino group, a mono- or di-alkanoylamino group, a mono- or di-alkoxy-carbonyl-amino group, a mono- or di-arylcarbonyl-amino

group, an alkylsulfinylamino group, an alkyl-sulfonyl-amino group, an arylsulfinylamino group, an arylsulfonylamino group, a carbamoyl group, a mono- or di-alkyl-carbamoyl group, a mono- or di-arylcarbamoyl group, an alkylsulfinyl group, an alkenyl-sulfinyl group, an alkynylsulfinyl group, a cycloalkyl-sulfinyl group, a cycloalkenylsulfinyl group, a cycloalkynyl-sulfinyl group, an arylsulfinyl group, a heterocyclyl-sulfinyl group, an alkyl-sulfonyl group, an alkenylsulfonyl group, an alkynylsulfonyl group, a cycloalkylsulfonyl group, a cycloalkenyl-sulfonyl group, a cycloalkynylsulfonyl group, an aryl-sulfonyl group, and a heterocyclylsulfonyl group. Each group as mentioned above may optionally be substituted by these substituents.

Further, the terms such as a haloalkyl group, a halo-lower alkyl group, a haloalkoxy group, a halo-lower alkoxy group, a halophenyl group, or a haloheterocyclyl group mean an alkyl group, a lower alkyl group, an alkoxy group, a lower alkoxy group, a phenyl group or a heterocyclyl group (hereinafter, referred to as an alkyl group, etc.) being substituted by one or more halogen atoms, respectively. Preferable ones are an alkyl group, etc. being substituted by 1 to 7 halogen atoms, and more preferable ones are an alkyl group, etc. being substituted by 1 to 5 halogen atoms. Similarly, the terms such as a hydroxyalkyl group, a hydroxy-lower alkyl group, a hydroxyalkoxy group, a hydroxy-lower alkoxy group and a hydroxyphenyl group mean an alkyl group, etc., being substituted by one or more hydroxy groups. Preferable ones are an alkyl group, etc., being substituted by 1 to 4 hydroxy groups, and more preferable ones are an alkyl group, etc., being substituted by 1 to 2 hydroxy groups. Further, the terms such as an alkoxyalkyl group, a lower alkoxyalkyl group, an alkoxy-lower alkyl group, a lower alkoxy-lower alkyl group, an alkoxyalkoxy group, a lower alkoxyalkoxy group, an alkoxy-lower alkoxy group, a lower alkoxy-lower alkoxy group, an alkoxyphenyl group, and a lower alkoxyphenyl group means an alkyl group, etc., being substituted by one or more alkoxy groups. Preferable ones are an alkyl group, etc., being substituted by 1 to 4 alkoxy groups, and more preferable ones are an alkyl group, etc., being substituted by 1 to 2 alkoxy groups.

The terms "**arylalkyl**" and "**arylalkoxy**" as used alone or as part of another group refer to alkyl and alkoxy groups as described above having an aryl substituent.

5 The term "**lower**" used in the definitions for the formulae in the present specification means a straight or branched carbon chain having 1 to 6 carbon atoms, unless defined otherwise. More preferably, it means a straight or branched carbon chain having 1 to 4 carbon atoms.

10 The term "**prodrug**" means an ester or carbonate, which is formed by reacting one or more hydroxy groups of the compound of the formula I with an acylating agent substituted by an alkyl, an alkoxy or an aryl by a conventional method to produce acetate, pivalate, methylcarbonate, benzoate, etc. Further, the prodrug includes also an ester or amide, which is similarly formed by reacting one or more hydroxy groups of the compound of the formula I with an
15 α -amino acid or a β -amino acid, etc. using a condensing agent by a conventional method.

The **pharmaceutically acceptable salt** of the compound of the formula I includes, for example, a salt with an alkali metal such as lithium, sodium, potassium, etc.; a salt with an alkaline earth metal such as calcium,
20 magnesium, etc.; a salt with zinc or aluminum; a salt with an organic base such as ammonium, choline, diethanolamine, lysine, ethylenediamine, t-butylamine, t-octylamine, tris(hydroxymethyl)aminomethane, N-methyl glucosamine, triethanolamine and dehydroabietylamine; a salt with an inorganic acid such as hydrochloric acid, hydrobromic acid, hydroiodic acid, sulfuric acid, nitric acid,
25 phosphoric acid, etc.; or a salt with an organic acid such as formic acid, acetic acid, propionic acid, oxalic acid, malonic acid, succinic acid, fumaric acid, maleic acid, lactic acid, malic acid, tartaric acid, citric acid, methanesulfonic acid, ethanesulfonic acid, benzenesulfonic acid, etc.; or a salt with an acidic amino acid such as aspartic acid, glutamic acid, etc.

30 The compound of the present invention also includes a mixture of stereoisomers, or each pure or substantially pure isomer. For example, the present compound may optionally have one or more asymmetric centers at a carbon atom containing any one of substituents. Therefore, the compound of

the formula I may exist in the form of enantiomer or diastereomer, or a mixture thereof. When the present compound (I) contains a double bond, the present compound may exist in the form of geometric isomerism (cis-compound, trans-compound), and when the present compound (I) contains an unsaturated bond
5 such as carbonyl, then the present compound may exist in the form of a tautomer, and the present compound also includes these isomers or a mixture thereof. The starting compound in the form of a racemic mixture, enantiomer or diastereomer may be used in the processes for preparing the present compound. When the present compound is obtained in the form of a
10 diastereomer or enantiomer, they can be separated by a conventional method such as chromatography or fractional crystallization.

In addition, the present compound (I) includes an intramolecular salt, hydrate, solvate or polymorph thereof.

Examples of the optionally substituted unsaturated monocyclic
15 heterocyclic ring of the present invention include an unsaturated monocyclic heterocyclic ring which may optionally be substituted by 1-5 substituents selected from the group consisting of a halogen atom, a nitro group, a cyano group, an oxo group, a hydroxyl group, a mercapto group, a carboxyl group, a sulfo group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl
20 group, a cycloalkylidenemethyl group, a cycloalkenyl group, a cycloalkynyl group, an aryl group, a heterocyclyl group, an alkoxy group, an alkenyloxy group, an alkynyloxy group, a cycloalkyloxy group, a cycloalkenyloxy group, a cycloalkynyloxy group, an aryloxy group, a heterocyclyloxy group, an alkanoyl group, an alkenylcarbonyl group, an alkynylcarbonyl group, a
25 cycloalkylcarbonyl group, a cycloalkenylcarbonyl group, a cycloalkynylcarbonyl group, an arylcarbonyl group, a heterocyclylcarbonyl group, an alkoxy carbonyl group, an alkenyloxy carbonyl group, an alkynyloxy carbonyl group, a cycloalkyloxy carbonyl group, a cycloalkenyloxy carbonyl group, a cycloalkynyloxy carbonyl group, an aryloxy carbonyl group, a
30 heterocyclyloxy carbonyl group, an alkanoyloxy group, an alkenylcarbonyloxy group, an alkynylcarbonyloxy group, a cycloalkylcarbonyloxy group, a cycloalkenylcarbonyloxy group, a cycloalkynylcarbonyloxy group, an arylcarbonyloxy group, a heterocyclylcarbonyloxy group, an alkylthio group, an

alkenylthio group, an alkynylthio group, a cycloalkylthio group, a cycloalkenylthio group, a cycloalkynylthio group, an arylthio group, a heterocyclylthio group, an amino group, a mono- or di-alkylamino group, a mono- or di-alkanoylamino group, a mono- or di-alkoxycarbonylamino group, a mono- or di-arylcarbonylamino group, an alkylsulfinylamino group, an alkylsulfonylamino group, an arylsulfinylamino group, an arylsulfonylamino group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, a mono- or di-arylcarbamoyl group, an alkylsulfinyl group, an alkenylsulfinyl group, an alkynylsulfinyl group, a cycloalkylsulfinyl group, a cycloalkenylsulfinyl group, a cycloalkynylsulfinyl group, an arylsulfinyl group, a heterocyclylsulfinyl group, an alkylsulfonyl group, an alkenylsulfonyl group, an alkynylsulfonyl group, a cycloalkylsulfonyl group, a cycloalkenylsulfonyl group, a cycloalkynylsulfonyl group, an arylsulfonyl group, and a heterocyclylsulfonyl group wherein each substituent may optionally be further substituted by these substituents.

Examples of the optionally substituted unsaturated fused heterobicyclic ring of the present invention include an unsaturated fused heterobicyclic ring which may optionally be substituted by 1-5 substituents selected from the group consisting of a halogen atom, a nitro group, a cyano group, an oxo group, a hydroxy group, a mercapto group, a carboxyl group, a sulfo group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidene- methyl group, a cycloalkenyl group, a cycloalkynyl group, an aryl group, a heterocyclyl group, an alkoxy group, an alkenyloxy group, an alkynyloxy group, a cycloalkyloxy group, a cycloalkenyloxy group, a cycloalkynyloxy group, an aryloxy group, a heterocycliloxy group, an alkanoyl group, an alkenylcarbonyl group, an alkynylcarbonyl group, a cycloalkylcarbonyl group, a cycloalkenyl- carbonyl group, a cycloalkynyl- carbonyl group, an arylcarbonyl group, a heterocyclylcarbonyl group, an alkoxycarbonyl group, an alkenyloxycarbonyl group, an alkynyloxy- carbonyl group, a cycloalkyloxycarbonyl group, a cycloalkenyloxy- carbonyl group, a cycloalkynyloxycarbonyl group, an aryloxycarbonyl group, a heterocycliloxy carbonyl group, an alkanoyloxy group, an alkenylcarbonyloxy group, an alkynylcarbonyloxy group, a cyclo- alkylcarbonyloxy group, a cycloalkenylcarbonyloxy group, a cyclo- alkynylcarbonyloxy group, an

arylcarbonyloxy group, a heterocyclyl- carbonyloxy group, an alkylthio group,
 an alkenylthio group, an alkynylthio group, a cycloalkylthio group, a
 cycloalkenylthio group, a cycloalkynylthio group, an arylthio group, a
 heterocyclylthio group, an amino group, a mono- or di-alkylamino group, a
 5 mono- or di-alkanoyl- amino group, a mono- or di-alkoxycarbonylamino group,
 a mono- or di-arylcarbonylamino group, an alkylsulfinylamino group, an alkyl-
 sulfonylamino group, an arylsulfinylamino group, an arylsulfonylamino group, a
 carbamoyl group, a mono- or di-alkylcarbamoyl group, a mono- or di-
 arylcarbamoyl group, an alkylsulfinyl group, an alkenylsulfinyl group, an
 10 alkynylsulfinyl group, a cycloalkylsulfinyl group, a cyclo- alkenylsulfinyl group, a
 cycloalkynylsulfinyl group, an arylsulfinyl group, a heterocyclylsulfinyl group, an
 alkylsulfonyl group, an alkenylsulfonyl group, an alkynylsulfonyl group, a
 cycloalkylsulfonyl group, a cyclo- alkenylsulfonyl group, a cycloalkynylsulfonyl
 group, an arylsulfonyl group, and a heterocyclylsulfonyl group, wherein each
 15 substituent may optionally be further substituted by these substituents.

Examples of the optionally substituted benzene ring of the present
 invention include a benzene ring which may optionally be substituted by 1-5
 substituents selected from the group consisting of a halogen atom, a nitro
 group, a cyano group, a hydroxy group, a mercapto group, a carboxyl group, a
 20 sulfo group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl
 group, a cycloalkylidenemethyl group, a cycloalkenyl group, a cycloalkynyl
 group, an aryl group, a heterocyclyl group, an alkoxy group, an alkenyloxy
 group, an alkynyloxy group, a cycloalkyloxy group, a cycloalkenyloxy group, a
 cycloalkynyloxy group, an aryloxy group, a heterocyclioxy group, an alkanoyl
 25 group, an alkenylcarbonyl group, an alkynylcarbonyl group, a
 cycloalkylcarbonyl group, a cycloalkenylcarbonyl group, a cycloalkynylcarbonyl
 group, an arylcarbonyl group, a heterocyclylcarbonyl group, an alkoxycarbonyl
 group, an alkenyloxycarbonyl group, an alkynyloxycarbonyl group, a
 cycloalkyloxycarbonyl group, a cycloalkenyloxycarbonyl group, a cycloalkynyl-
 30 oxy carbonyl group, an aryloxycarbonyl group, a heterocyclioxycarbonyl group,
 an alkanoyloxy group, an alkenylcarbonyloxy group, an alkynylcarbonyloxy
 group, a cycloalkylcarbonyloxy group, a cycloalkenylcarbonyloxy group, a
 cycloalkynylcarbonyloxy group, an arylcarbonyloxy group, a

heterocyclylcarbonyloxy group, an alkylthio group, an alkenylthio group, an alkynylthio group, a cycloalkylthio group, a cycloalkenylthio group, a cycloalkynylthio group, an arylthio group, a heterocyclylthio group, an amino group, a mono- or di-alkylamino group, a mono- or di-alkanoylamino group, a
 5 mono- or di-alkoxycarbonylamino group, a mono- or di-arylcarbonylamino group, an alkylsulfinylamino group, an alkylsulfonylamino group, an arylsulfinylamino group, an arylsulfonylamino group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, a mono- or di-arylcarbamoyl group, an alkylsulfinyl group, an alkenylsulfinyl group, an alkynylsulfinyl group, a
 10 cycloalkylsulfinyl group, a cycloalkenylsulfinyl group, a cycloalkynylsulfinyl group, an arylsulfinyl group, a heterocyclylsulfinyl group, an alkylsulfonyl group, an alkenylsulfonyl group, an alkynylsulfonyl group, a cycloalkylsulfonyl group, a cycloalkenylsulfonyl group, a cycloalkynylsulfonyl group, an arylsulfonyl group, a heterocyclylsulfonyl group, an alkylene group, an alkyleneoxy group, an
 15 alkylenedioxy group, and an alkenylene group wherein each substituent may optionally be further substituted by these substituents.

Moreover, examples of the optionally substituted benzene ring include a benzene ring substituted with an alkylene group to form an annelated carbocycle together with the carbon atoms to which they are attached, and also
 20 includes a benzene ring substituted with an alkenylene group to form an annelated carbocycle such as a fused benzene ring together with the carbon atoms to which they are attached.

Preferable examples of the optionally substituted unsaturated monocyclic heterocyclic ring include an unsaturated monocyclic heterocyclic ring which may optionally be substituted by 1-3 substituents selected from the
 25 group consisting of a halogen atom, a hydroxy group, an alkoxy group, an alkyl group, a haloalkyl group, a haloalkoxy group, a hydroxyalkyl group, an alkoxyalkyl group, an alkoxyalkoxy group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, a cycloalkenyl group, a
 30 cycloalkyloxy group, an aryl group, an aryloxy group, an arylalkoxy group, a cyano group, a nitro group, an amino group, a mono- or di-alkylamino group, an alkanoylamino group, an alkoxycarbonylamino group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group,

an alkanoyl group, an alkylsulfonylamino group, an arylsulfonylamino group, an alkylsulfinyl group, an alkylsulfonyl group, an arylsulfonyl group, a heterocyclyl group, and an oxo group.

Preferable examples of the optionally substituted unsaturated fused
5 heterobicyclic ring include an unsaturated fused heterobicyclic ring which may optionally be substituted by 1-3 substituents independently selected from the group consisting of a halogen atom, a hydroxy group, an alkoxy group, an alkyl group, a haloalkyl group, a haloalkoxy group, a hydroxyalkyl group, an alkoxyalkyl group, an alkoxyalkoxy group, an alkenyl group, an alkynyl group, a
10 cycloalkyl group, a cycloalkylidenemethyl group, a cycloalkenyl group, a cycloalkyloxy group, an aryl group, an aryloxy group, an arylalkoxy group, a cyano group, a nitro group, an amino group, a mono- or di-alkylamino group, an alkanoylamino group, an alkoxycarbonylamino group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group,
15 an alkanoyl group, an alkylsulfonylamino group, an arylsulfonylamino group, an alkylsulfinyl group, an alkylsulfonyl group, an arylsulfonyl group, a heterocyclyl group, and an oxo group.

Preferable examples of the optionally substituted benzene ring include a
benzene ring which may optionally be substituted by 1-3 substituents selected
20 from the group consisting of a halogen atom, a hydroxy group, an alkoxy group, an alkyl group, a haloalkyl group, a haloalkoxy group, a hydroxyalkyl group, an alkoxyalkyl group, an alkoxyalkoxy group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, a cycloalkenyl group, a cycloalkyloxy group, an aryl group, an aryloxy group, an arylalkoxy group, a
25 cyano group, a nitro group, an amino group, a mono- or di-alkylamino group, an alkanoylamino group, an alkoxycarbonylamino group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkanoyl group, an alkylsulfonylamino group, an arylsulfonylamino group, an alkylsulfinyl group, an alkylsulfonyl group, an arylsulfonyl group, a heterocyclyl
30 group, an alkylene group, an alkyleneoxy group, an alkylendioxy group, and an alkenylene group.

In another preferable embodiment of the present invention, the optionally substituted unsaturated monocyclic heterocyclic ring is an

unsaturated monocyclic heterocyclic ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a hydroxy group, a cyano group, a nitro group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, an alkoxy group, an alkanoyl group, an alkylthio group, an alkylsulfonyl group, an alkylsulfinyl group, an amino group, a mono- or di-alkylamino group, an alkanoylamino group, an alkoxycarbonylamino group, a sulfamoyl group, a mono- or di-alkylsulfamoyl group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkylsufonylamino group, a phenyl group, a phenoxy group, a phenylsulfonylamino group, a phenylsulfonyl group, a heterocyclyl group, and an oxo group;

the optionally substituted unsaturated fused heterobicyclic ring is an unsaturated fused heterobicyclic ring which may optionally be substituted by 1-3 substituents selected from the group consisting of a halogen atom, a hydroxy group, a cyano group, a nitro group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, an alkoxy group, an alkylthio group, an alkylsulfonyl group, an alkylsulfinyl group, an amino group, a mono- or di-alkylamino group, an alkanoylamino group, an alkoxycarbonylamino group, a sulfamoyl group, a mono- or di-alkyl- sulfamoyl group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkanoyl group, an alkylsulfonylamino group, a phenyl group, a phenoxy group, a phenylsulfonylamino group, phenylsulfonyl group, a heterocyclyl group, and an oxo group; and

the optionally substituted benzene ring is a benzene ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a hydroxy group, a cyano group, a nitro group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, an alkoxy group, an alkanoyl group, an alkylthio group, an alkylsulfonyl group, an alkylsulfinyl group, an amino group, a mono- or di-alkylamino group, an alkanoylamino group, an alkoxycarbonylamino group, a sulfamoyl group, a mono- or di-alkylsulfamoyl group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkylsufonylamino group, a phenyl group, a phenoxy group, a

phenylsulfonylamino group, a phenylsulfonyl group, a heterocyclyl group, an alkylene group, and an alkenylene group;

wherein each of the above-mentioned substituents on the unsaturated monocyclic heterocyclic ring, the unsaturated fused heterobicyclic ring and the
5 benzene ring may further be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a hydroxy group, a cyano group, an alkyl group, a haloalkyl group, an alkoxy group, a haloalkoxy group, an alkanoyl group, an alkylthio group, an alkylsulfonyl group, a mono- or di-alkylamino group, a carboxyl group, an alkoxycarbonyl group, a phenyl
10 group, an alkyleneoxy group, an alkylendioxy group, an oxo group, a carbamoyl group, and a mono- or di-alkylcarbamoyl group.

In a preferable embodiment, the optionally substituted unsaturated monocyclic heterocyclic ring is an unsaturated monocyclic heterocyclic ring which may optionally be substituted by 1-3 substituents, independently selected
15 from the group consisting of a halogen atom, a cyano group, an alkyl group, an alkoxy group, an alkanoyl group, a mono- or di-alkylamino group, an alkanoylamino group, an alkoxycarbonylamino group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, a phenyl group, a heterocyclyl group, and an oxo group;

20 the optionally substituted unsaturated fused heterobicyclic ring is an unsaturated fused heterobicyclic ring which may optionally be substituted by 1-3 substituents independently selected from the group consisting of a halogen atom, a cyano group, an alkyl group, an alkoxy group, an alkanoyl group, a mono- or di-alkylamino group, an alkanoylamino group, an
25 alkoxycarbonylamino group, a carboxy group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, a phenyl group, a heterocyclyl group, and an oxo group; and

the optionally substituted benzene ring is a benzene ring which may optionally be substituted by 1-3 substituents, independently selected from the
30 group consisting of a halogen atom, a cyano group, an alkyl group, an alkoxy group, an alkanoyl group, a mono- or di-alkylamino group, an alkanoylamino group, an alkoxycarbonylamino group, a carboxyl group, an alkoxycarbonyl

group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, a phenyl group, a heterocyclyl group, an alkylene group, and an alkenylene group;

wherein each of the above-mentioned substituents on the unsaturated monocyclic heterocyclic ring, the unsaturated fused heterobicyclic ring and the
5 benzene ring may further be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a cyano group, an alkyl group, a haloalkyl group, an alkoxy group, a haloalkoxy group, an alkanoyl group, a mono- or di-alkylamino group, a carboxyl group, a hydroxy group, a phenyl group, an alkylenedioxy group, an alkyleneoxy group, an alkoxycarbonyl
10 group, a carbamoyl group and a mono- or di-alkylcarbamoyl group.

In another preferable embodiment,

(1) Ring A is an unsaturated monocyclic heterocyclic ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a hydroxy group, a cyano group, a nitro
15 group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, an alkoxy group, an alkanoyl group, an alkylthio group, an alkylsulfonyl group, an alkylsulfinyl group, an amino group, a mono- or di-alkylamino group, a sulfamoyl group, a mono- or di-alkylsulfamoyl group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-
20 alkylcarbamoyl group, an alkylsufonylamino group, a phenyl group, a phenoxy group, a phenylsulfonylamino group, a phenylsulfonyl group, a heterocyclyl group, and an oxo group, and

Ring B is an unsaturated monocyclic heterocyclic ring, an unsaturated fused heterobicyclic ring, or a benzene ring, each of which may optionally be
25 substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a hydroxy group, a cyano group, a nitro group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, an alkoxy group, an alkanoyl group, an alkylthio group, an alkylsulfonyl group, an alkylsulfinyl group, an amino group, a mono-
30 or di-alkylamino group, a sulfamoyl group, a mono- or di-alkylsulfamoyl group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkylsufonylamino group, a phenyl group, a phenoxy

group, a phenylsulfonylamino group, a phenylsulfonyl group, a heterocyclyl group, an alkylene group, and an alkenylene group;

(2) Ring A is a benzene ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen
5 atom, a hydroxy group, a cyano group, a nitro group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, an alkoxy group, an alkanoyl group, an alkylthio group, an alkylsulfonyl group, an alkylsulfinyl group, an amino group, a mono- or di-alkylamino group, an alkanoylamino group, a sulfamoyl group, a mono- or di-alkylsulfamoyl group, a
10 carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkylsulfonylamino group, a phenyl group, a phenoxy group, a phenylsulfonylamino group, a phenylsulfonyl group, a heterocyclyl group, an alkylene group, and an alkenylene group, and

Ring B is an unsaturated monocyclic heterocyclic ring or an unsaturated
15 fused heterobicyclic ring, each of which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a hydroxy group, a cyano group, a nitro group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, an alkoxy group, an alkanoyl group, an alkylthio group, an alkylsulfonyl group, an alkylsulfinyl group, an amino group, a mono- or di-alkylamino group, a sulfamoyl
20 group, a mono- or di-alkylsulfamoyl group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkylsulfonylamino group, a phenyl group, a phenoxy group, a phenylsulfonylamino group, a phenylsulfonyl group, a heterocyclyl group, an
25 alkylene group and an oxo group; or

(3) Ring A is an unsaturated fused heterobicyclic ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a hydroxy group, a cyano group, a nitro
group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a
30 cycloalkylidenemethyl group, an alkoxy group, an alkanoyl group, an alkylthio group, an alkylsulfonyl group, an alkylsulfinyl group, an amino group, a mono- or di-alkylamino group, a sulfamoyl group, a mono- or di-alkylsulfamoyl group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-

alkylcarbamoyl group, an alkylsulfonylamino group, a phenyl group, a phenoxy group, a phenylsulfonylamino group, a phenylsulfonyl group, a heterocyclyl group, and an oxo group, and

Ring B is an unsaturated monocyclic heterocyclic ring, an unsaturated
5 fused heterobicyclic ring, or a benzene ring, each of which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a hydroxy group, a cyano group, a nitro group, an alkyl group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, an alkoxy group, an alkanoyl group, an alkylthio
10 group, an alkylsulfonyl group, an alkylsulfinyl group, an amino group, a mono- or di-alkylamino group, a sulfamoyl group, a mono- or di-alkylsulfamoyl group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkylsulfonylamino group, a phenyl group, a phenoxy group, a phenylsulfonylamino group, a phenylsulfonyl group, a heterocyclyl
15 group, an alkylene group and an oxo group;

wherein each of the above-mentioned substituents on Ring A and Ring B may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a cyano group, an alkyl group, a haloalkyl group, an alkoxy group, a haloalkoxy group, an alkanoyl group, a
20 mono- or di-alkylamino group, a carboxyl group, a hydroxy group, a phenyl group, an alkylendioxy group, an alkyleneoxy group, an alkoxycarbonyl group, a carbamoyl group and a mono- or di-alkylcarbamoyl group.

In a more preferable embodiment of the present invention, Ring A and Ring B are

25 (1) Ring A is an unsaturated monocyclic heterocyclic ring which may optionally be substituted by a halogen atom, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or an oxo group, and Ring B is (a) a benzene ring which may optionally be substituted by a halogen atom; a cyano group; a lower alkyl group; a halo-lower alkyl group; a lower alkoxy group; a halo-lower
30 alkoxy group; a mono- or di-lower alkylamino group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; or a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a

lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; (b) an unsaturated monocyclic heterocyclic ring which may optionally be substituted by a group selected from a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a mono- or di-lower alkylamino group, a phenyl group which may be substituted with a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; and a heterocyclyl group which may optionally be substituted with a group selected from a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; or (c) an unsaturated fused heterobicyclic ring which may optionally be substituted by a group selected from a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a mono- or di-lower alkylamino group, a phenyl group which may be substituted with a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; and a heterocyclyl group which may optionally be substituted with a group selected from a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group;

(2) Ring A is a benzene ring which may optionally be substituted by a halogen atom, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a phenyl group, or a lower alkenylene group, and Ring B is (a) an unsaturated monocyclic heterocyclic ring which may optionally be substituted by a halogen atom; a cyano group; a lower alkyl group; a halo-lower alkyl group; a phenyl-lower alkyl group; a lower alkoxy group; a halo-lower alkoxy group; a mono- or di-lower alkylamino group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a mono- or di-lower alkylamino group, or a carbamoyl group; or a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a mono- or di-lower alkylamino group or a carbamoyl group; (b) an unsaturated fused heterobicyclic ring which may optionally be substituted by

- a group selected from a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a phenyl-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a mo- or di-lower alkylamino group, a phenyl group which may be substituted with a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; and a heterocyclyl group which may optionally be substituted with a group selected from a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; or
- (3) Ring A is an unsaturated fused heterobicyclic ring which may optionally be substituted by a halogen atom, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or an oxo group, and Ring B is (a) a benzene ring which may optionally be substituted by a group selected from a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a mo- or di-lower alkylamino group, a phenyl group which may be substituted with a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; and a heterocyclyl group which may optionally be substituted with a group selected from a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; (b) an unsaturated monocyclic heterocyclic ring which may optionally be substituted by a halogen atom; a cyano group; a lower alkyl group; a halo-lower alkyl group; a lower alkoxy group; a halo-lower alkoxy group; a mono- or di-lower alkylamino group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; or a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; or (c) an unsaturated fused heterobicyclic ring which may optionally be substituted by a group selected from a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a mo- or di-lower alkylamino group, a phenyl group which may be substituted with a halogen atom, cyano group, a lower alkyl

group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group; and a heterocyclyl group which may optionally be substituted with a group selected from a halogen atom, cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a mono- or di-lower alkylamino group.

5 In another more preferable embodiment, Y is $-\text{CH}_2-$ and is linked at the 3-position of Ring A, with respect to X being the 1-position, Ring A is a benzene ring which is substituted by 1-3 substituents selected from the group consisting of a lower alkyl group, a halo-lower alkyl group, a halogen atom, a lower alkoxy group, a phenyl group, and a lower alkenylene group, and Ring B is an unsaturated monocyclic heterocyclic ring or an unsaturated fused heterobicyclic ring, each of which may be substituted by 1-3 substituents selected from the group consisting of a lower alkyl group, a halo-lower alkyl group, a phenyl-lower alkyl group, a halogen atom, a lower alkoxy group, a halo-lower alkoxy group, a phenyl group, a halophenyl group, a cyanophenyl group, a lower alkylphenyl group, a halo-lower alkylphenyl group, a lower alkoxyphenyl group, a halo-lower alkoxy phenyl group, a lower alkylenedioxyphenyl group, a lower alkyleneoxy phenyl group, a mono- or di-lower alkylaminophenyl group, a carbamoyl phenyl group, a mono- or di-lower alkylcarbamoylphenyl group, a heterocyclyl group, a haloheterocyclyl group, a cyanoheterocyclyl group, a lower alkylheterocyclyl group, a lower alkoxyheterocyclyl group, a mono- or di-lower alkylaminoheterocyclyl group, a carbamoylheterocyclyl group, and a mono- or di-lower alkylcarbamoyl group.

25 In another more preferable embodiment, Y is $-\text{CH}_2-$ and is linked at the 3-position of Ring A, with respect to X being the 1-position, Ring A is an unsaturated monocyclic heterocyclic ring which may be substituted by 1-3 substituents selected from the group consisting of a lower alkyl group, a halogen atom, a lower alkoxy group, and an oxo group, and Ring B is a benzene ring which may be substituted by 1-3 substituents selected from the group consisting of a lower alkyl group, a halo-lower alkyl group, a halogen atom, a lower alkoxy group, , a halo-lower alkoxy group, a phenyl group, a halophenyl group, a cyanophenyl group, a lower alkylphenyl group, a halo-lower alkylphenyl group, a lower alkoxyphenyl group, a heterocyclyl group, a

haloheterocyclyl group, a cyanoheterocyclyl group, a lower alkylheterocyclyl group, and a lower alkoxyheterocyclyl group.

Further, in another preferable embodiment, Y is $-\text{CH}_2-$ and is linked at the 3-position of Ring A, with respect to X being the 1-position, Ring A is an
5 unsaturated monocyclic heterocyclic ring which may be substituted by 1-3 substituents selected from the group consisting of a lower alkyl group, a halogen atom, a lower alkoxy group, and an oxo group, and Ring B is an unsaturated monocyclic heterocyclic ring or an unsaturated fused heterobicyclic ring, each of which may be substituted by 1-3 substituents selected from the
10 group consisting of a lower alkyl group, a halo-lower alkyl group, a halogen atom, a lower alkoxy group, a halo-lower alkoxy group, a phenyl group, a halophenyl group, a cyanophenyl group, a lower alkylphenyl group, a halo-lower alkylphenyl group, a lower alkoxyphenyl group, a halo-lower alkoxyphenyl group, a heterocyclyl group, a haloheterocyclyl group, a cyanoheterocyclyl
15 group, a lower alkylheterocyclyl group, and a lower alkoxyheterocyclyl group.

In a more preferable embodiment of the present invention, X is a carbon atom and Y is $-\text{CH}_2-$.

Further, in another preferable embodiment, Ring A and Ring B are:

(1) Ring A is a benzene ring which may optionally be substituted by 1-3
20 substituents, independently selected from the group consisting of a halogen atom, a lower alkyl group optionally substituted by a halogen atom or a lower alkoxy group, a lower alkoxy group optionally substituted by a halogen atom or a lower alkoxy group, a cycloalkyl group, a cycloalkoxy group, a phenyl group, and a lower alkenylene group, and

25 Ring B is an unsaturated monocyclic heterocyclic ring or an unsaturated fused heterobicyclic ring, each of which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom; a lower alkyl group optionally substituted by a halogen atom, a lower alkoxy group or a phenyl group; a lower alkoxy group optionally substituted by
30 a halogen atom or a lower alkoxy group; a cycloalkyl group; a cycloalkoxy group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, or a carbamoyl group; a heterocyclyl group optionally substituted

by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group or a carbamoyl group; and an oxo group,

5 (2) Ring A is an unsaturated monocyclic heterocyclic ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a lower alkyl group optionally substituted by a lower alkoxy group, a lower alkoxy group optionally substituted by a halogen atom or a lower alkoxy group, a cycloalkyl group, a cycloalkoxy group, and an oxo group, and

10 Ring B is a benzene ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom; a lower alkyl group optionally substituted by a halogen atom, a lower alkoxy group or a phenyl group; a lower alkoxy group optionally substituted by a halogen atom or a lower alkoxy group; a cycloalkyl group; a cycloalkoxy group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group or a halo-lower alkoxy group; a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group or a halo-lower alkoxy group; a lower alkylene group,

20 (3) Ring A is an unsaturated monocyclic heterocyclic ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a lower alkyl group optionally substituted by a halogen atom or a lower alkoxy group, a lower alkoxy group optionally substituted by a halogen atom or a lower alkoxy group, a cycloalkyl group, a cycloalkoxy group, and an oxo group,

25 Ring B is an unsaturated monocyclic heterocyclic ring or an unsaturated fused heterobicyclic ring, each of which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom; a lower alkyl group optionally substituted by a halogen atom, a lower alkoxy group or a phenyl group; a lower alkoxy group optionally substituted by a halogen atom or a lower alkoxy group; a cycloalkyl group; a cycloalkoxy group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group or a halo-

lower alkoxy group; a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group or a halo-lower alkoxy group; and an oxo group;

(4) Ring A is an unsaturated fused heterobicyclic ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a lower alkyl group optionally substituted by a lower alkoxy group, a lower alkoxy group optionally substituted by a halogen atom or a lower alkoxy group, a cycloalkyl group, a cycloalkoxy group, and an oxo group,

Ring B is a benzene ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom; a lower alkyl group optionally substituted by a halogen atom, a lower alkoxy group or a phenyl group; a lower alkoxy group optionally substituted by a halogen atom or a lower alkoxy group; a cycloalkyl group; a cycloalkoxy group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group or a halo-lower alkoxy group; a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group or a halo-lower alkoxy group; and a lower alkylene group, or

(5) Ring A is an unsaturated monocyclic heterocyclic ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom, a lower alkyl group optionally substituted by a lower alkoxy group, a lower alkoxy group optionally substituted by a halogen atom or a lower alkoxy group, a cycloalkyl group, a cycloalkoxy group, and an oxo group,

Ring B is an unsaturated monocyclic heterocyclic ring or an unsaturated fused heterobicyclic ring, each of which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom; a lower alkyl group optionally substituted by a halogen atom, a lower alkoxy group or a phenyl group; a lower alkoxy group optionally substituted by a halogen atom or a lower alkoxy group; a cycloalkyl group; a cycloalkoxy group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group or a halo-

lower alkoxy group; a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group or a halo-lower alkoxy group; and an oxo group.

In another preferable embodiment of the present invention, Y is linked at the 3-position of Ring A, with respect to X being the 1-position, Ring A is a benzene ring which may optionally be substituted by a halogen atom, a lower alkyl group optionally substituted by a halogen atom, a lower alkoxy group, or a phenyl group, and Ring B is an unsaturated monocyclic heterocyclic ring or an unsaturated fused heterobicyclic ring which may optionally be substituted by 1-3 substituents, independently selected from the group consisting of a halogen atom; a lower alkyl group optionally substituted by a halogen atom or a phenyl group; a lower alkoxy group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, or a lower alkoxy group; a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, or a lower alkoxy group; and an oxo group.

In another more preferable embodiment of the present invention, Y is linked at the 3-position of Ring A, with respect to X being the 1-position, Ring A is an unsaturated monocyclic heterocyclic ring which may optionally be substituted by a substituent selected from a halogen atom, a lower alkyl group, and an oxo group, and Ring B is a benzene ring which may optionally be substituted by a substituent selected from the group consisting of a halogen atom; a lower alkyl group optionally substituted by a halogen atom or a phenyl group; a lower alkoxy group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, or a lower alkoxy group; a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, or a lower alkoxy group; and a lower alkylene group.

Preferable examples of unsaturated monocyclic heterocyclic ring include a 5- or 6-membered unsaturated heterocyclic ring containing 1 or 2 hetero atoms independently selected from a nitrogen atom, an oxygen atom, and a sulfur atom. More specifically, preferred are furan, thiophene, oxazole, isoxazole, triazole, tetrazole, pyrazole, pyridine, pyrimidine, pyrazine,

dihydroisoxazole, dihydropyridine, and thiazole. Preferable unsaturated fused heterobicyclic ring includes a 9- or 10-membered unsaturated fused heterocyclic ring containing 1 to 4 hetero atoms independently selected from a nitrogen atom, an oxygen atom, and a sulfur atom. More specifically, preferred
5 are indoline, isoindoline, benzothiazole, benzoxazole, indole, indazole, quinoline, isoquinoline, benzothiophene, benzofuran, thienothiophene, and dihydroisoquinoline.

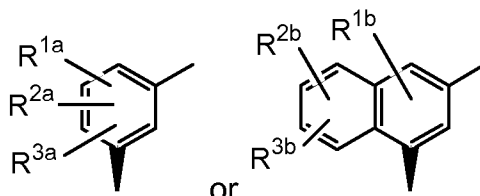
In a more preferred embodiment of the present invention, Ring A is a benzene ring which may optionally be substituted by a substituent selected
10 from the group consisting of a halogen atom, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, and a phenyl group, and Ring B is a heterocyclic ring selected from the group consisting of thiophene, furan, benzofuran, benzothiophene, and benzothiazole, wherein the heterocyclic ring may optionally be substituted by a substituent selected from the following
15 group: a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a phenyl-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a phenyl group, a halophenyl group, a lower alkylphenyl group, a lower alkoxyphenyl group, a thienyl group, a halothienyl group, a pyridyl group, a halopyridyl group, and a thiazolyl group.

In yet another preferred embodiment, Y is $-\text{CH}_2-$, Ring A is an unsaturated monocyclic heterocyclic ring or an unsaturated fused heterobicyclic ring selected from the group consisting of thiophene, dihydroisoquinoline, dihydroisoxazole, triazole, pyrazole, dihydropyridine, dihydroindole, indole, indazole, pyridine, pyrimidine, pyrazine, quinoline, and a isoindoline, wherein
25 the heterocyclic ring may optionally substituted by a substituent selected from the following group: a halogen atom, a lower alkyl group, and an oxo group, and Ring B is a benzene ring which may optionally be substituted by a substituent selected from the following group: a halogen atom, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, and a halo-lower alkoxy
30 group.

In a further preferred embodiment of the present invention, Ring A is a benzene ring which is substituted by a halogen atom or a lower alkyl group, and Ring B is thienyl group which is substituted by phenyl group or a

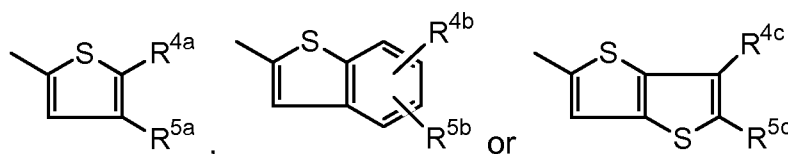
heterocyclyl group in which said phenyl group and heterocyclyl group is substituted by 1-3 substituents selected from a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, and a halo-lower alkoxy group.

- 5 Further, in another aspect of the present invention, preferable examples of the compound of the formula I include a compound wherein Ring A is



- wherein R^{1a} , R^{2a} , R^{3a} , R^{1b} , R^{2b} , and R^{3b} are each independently a hydrogen atom, a halogen atom, a hydroxy group, an alkoxy group, an alkyl group, a haloalkyl group, a haloalkoxy group, a hydroxyalkyl group, an alkoxyalkyl group, an alkoxyalkoxy group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, a cycloalkenyl group, a cycloalkyloxy group, a phenyl group, a phenylalkoxy group, a cyano group, a nitro group, an amino group, a mono- or di-alkylamino group, an alkanoylamino group, a carboxyl group, an alkoxycarbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkanoyl group, an alkylsulfonylamino group, a phenylsulfonylamino group, an alkylsulfinyl group, an alkylsulfonyl group, or a phenylsulfonyl group, and

Ring B is



- wherein R^{4a} and R^{5a} are each independently a hydrogen atom; a halogen atom; a hydroxy group; an alkoxy group; an alkyl group; a haloalkyl group; a haloalkoxy group; a hydroxyalkyl group; an alkoxyalkyl group; a phenylalkyl group; an alkoxyalkoxy group; a hydroxyalkoxy group; an alkenyl group; an alkynyl group; a cycloalkyl group; a cycloalkylidenemethyl group; a cycloalkenyl group; a cycloalkyloxy group; a phenyloxy group; a phenylalkoxy group; a cyano group; a nitro group; an amino group; a mono- or di-alkylamino group; an alkanoylamino group; a carboxyl group; an alkoxycarbonyl group; a

carbamoyl group; a mono- or di-alkylcarbamoyl group; an alkanoyl group; an alkylsulfonylamino group; a phenylsulfonylamino group; an alkylsulfinyl group; an alkylsulfonyl group; a phenylsulfonyl group; a phenyl group optionally substituted by a halogen atom, a cyano group, an alkyl group, a haloalkyl group, an alkoxy group, a haloalkoxy group, an alkylenedioxy group, an alkyleneoxy group, a mono- or di-alkylamino group, a carbamoyl group, or a mono- or di-alkylcarbamoyl group; or a heterocyclyl group optionally substituted by a halogen atom, a cyano group, an alkyl group, a haloalkyl group, an alkoxy group, a haloalkoxy group, a carbamoyl group, or a mono- or di-alkylcarbamoyl group, or R^{4a} and R^{5a} are bonded to each other at the terminals thereof to form an alkylene group; and

R^{4b} , R^{5b} , R^{4c} and R^{5c} are each independently a hydrogen atom; a halogen atom; a hydroxy group; an alkoxy group; an alkyl group; a haloalkyl group; a haloalkoxy group; a hydroxyalkyl group; an alkoxyalkyl group; a phenylalkyl group; an alkoxyalkoxy group; a hydroxyalkoxy group; an alkenyl group; an alkynyl group; a cycloalkyl group; a cycloalkylidenemethyl group; a cycloalkenyl group; a cycloalkyloxy group; a phenyloxy group; a phenylalkoxy group; a cyano group; a nitro group; an amino group; a mono- or di-alkylamino group; an alkanoylamino group; a carboxyl group; an alkoxycarbonyl group; a carbamoyl group; a mono- or di-alkylcarbamoyl group; an alkanoyl group; an alkylsulfonylamino group; a phenylsulfonylamino group; an alkylsulfinyl group; an alkylsulfonyl group; a phenylsulfonyl group; a phenyl group optionally substituted by a halogen atom, a cyano group, an alkyl group, a haloalkyl group, an alkoxy group, a haloalkoxy group, a methylenedioxy group, an ethyleneoxy group, or a mono- or di-alkylamino group; or a heterocyclyl group optionally substituted by a halogen atom, a cyano group, an alkyl group, a haloalkyl group, an alkoxy group or a haloalkoxy group.

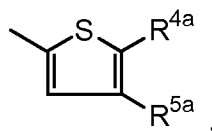
More preferred is a compound wherein R^{1a} , R^{2a} , R^{3a} , R^{1b} , R^{2b} , and R^{3b} are each independently a hydrogen atom, a halogen atom, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a phenyl group;

R^{4a} and R^{5a} are each independently a hydrogen atom; a halogen atom; a lower alkyl group; a halo-lower alkyl group; a phenyl-lower alkyl group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl

group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a methylenedioxy group, an ethyleneoxy group, a mono- or di-lower alkylamino group, a carbamoyl group, or a mono- or di-lower alkylcarbamoyl group; or a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a lower alkoxy group, a carbamoyl group, or a mono- or di-lower alkylcarbamoyl group, or R^{4a} and R^{5a} are bonded to each other at the terminals thereof to form a lower alkylene group; and

R^{4b} , R^{5b} , R^{4c} and R^{5c} are each independently a hydrogen atom, a halogen atom, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a halo-lower alkoxy group.

Further preferred is a compound in which Ring B is

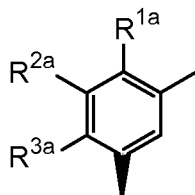


wherein R^{4a} is a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a methylenedioxy group, an ethyleneoxy group, a mono- or di-lower alkylamino group, a carbamoyl group, or a mono- or di-lower alkylcarbamoyl group; or a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a lower alkoxy group, a carbamoyl group, or a mono- or di-lower alkylcarbamoyl group, and

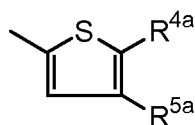
R^{5a} is a hydrogen atom, or

R^{4a} and R^{5a} are bonded to each other at the terminals thereof to form a lower alkylene group.

Further more preferred is a compound in which Ring A is



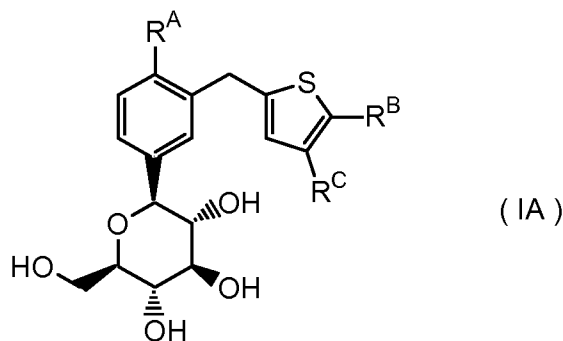
wherein R^{1a} is a halogen atom, a lower alkyl group, or a lower alkoxy group, and R^{2a} and R^{3a} are hydrogen atoms; and Ring B is



wherein R^{4a} is a phenyl group optionally substituted by a substituent selected from the group consisting of a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a mono- or di-lower alkylamino group, a carbamoyl group, and a mono- or di-lower alkylcarbamoyl group; or a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a lower alkoxy group, a carbamoyl group, or a mono- or di-lower alkylcarbamoyl group, and R^{5a} is a hydrogen atom, and Y is -CH₂-.

In more preferable embodiment, R^{4a} is a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a halo-lower alkoxy group; or a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group, or a lower alkoxy group.

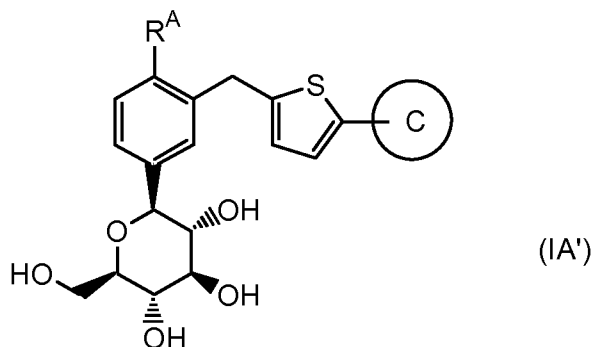
In another preferable embodiment of the present invention, a preferable compound can be represented by the following formula IA:



wherein R^A is a halogen atom, a lower alkyl group or a lower alkoxy group; R^B is a phenyl group optionally substituted by 1-3 substituents selected from a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a methylenedioxy group, an ethyleneoxy group, a mono- or di-lower alkylamino group, a carbamoyl group, and a mono- or di-lower alkylcarbamoyl group; or a heterocyclyl group optionally substituted by 1-3 substituents selected from a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a mono- or di-lower alkylamino

group, a carbamoyl group, and a mono- or di-lower alkylcarbamoyl group; and R^C is hydrogen atom; or R^B and R^C taken together are a fused benzene ring which may be substituted by a halogen atom, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group or a halo-lower alkoxy group.

- 5 In a preferable embodiment, R^A is a halogen atom or a lower alkyl group, R^C is hydrogen atom, and R^B is phenyl group substituted by 1-3 substituents selected from a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a methylenedioxy group, an ethyleneoxy group, a mono- or di-lower alkylamino group, a carbamoyl group, and a mono- or di-lower alkylcarbamoyl group; or a heterocyclyl group substituted by 1-3 substituents selected from the group consisting of a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a mono- or di-lower alkylamino group, a carbamoyl group, and a mono- or di-lower alkylcarbamoyl group. The chemical structure of such compounds are represented by the following formula (IA'):



- wherein R^A is a halogen atom, or a lower alkyl group, Ring C is a phenyl group substituted by 1-3 substituents selected from the group consisting of a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a methylenedioxy group, an ethyleneoxy group, a mono- or di-lower alkylamino group, a carbamoyl group, and a mono- or di-lower alkylcarbamoyl group; or a heterocyclyl group substituted by 1-3 substituents selected from the group consisting of a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, a mono- or di-lower alkylamino group, a carbamoyl group, and a mono- or di-lower alkylcarbamoyl group.

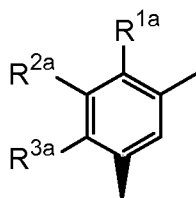
In a more preferable embodiment, Ring C is a phenyl group substituted by 1-3 substituents selected from the group consisting of a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, a halo-lower alkoxy group, and a mono- or di-lower alkylamino group; or
 5 a heterocyclyl group substituted by a substituent selected from the group consisting of a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, and a halo-lower alkoxy group.

Among them, a compound in which Ring C is a phenyl group substituted by a halogen atom, a cyano group, a lower alkyl group, a halo-lower alkyl
 10 group, a lower alkoxy group or a halo-lower alkoxy group; or a heterocyclyl group substituted by a halogen atom, a cyano group, a lower alkyl group, or a lower alkoxy group is preferred.

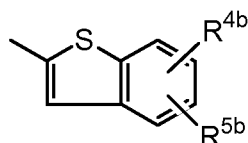
A preferred heterocyclyl group includes a 5- or 6-membered heterocyclyl group containing 1 or 2 hetero atoms independently selected from the group
 15 consisting of a nitrogen atom, an oxygen atom, and a sulfur atom, or a 9- or 10-membered heterocyclyl group containing 1 to 4 hetero atoms independently selected from the group consisting of a nitrogen atom, an oxygen atom, and a sulfur atom. Specifically, a thienyl group, a pyridyl group, a pyrimidyl group, a pyrazinyl group, pyrazolyl group, a thiazolyl group, a quinolyl group, a tetrazolyl
 20 group and an oxazolyl group are preferred.

In a further preferable embodiment, Ring C is a phenyl group substituted by a halogen atom or a cyano group, or a pyridyl group substituted by a halogen atom.

In another preferable embodiment of the present invention, preferred is a
 25 compound in which Ring A is

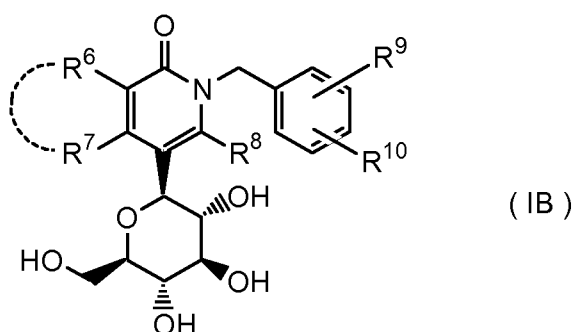


wherein R^{1a} is a halogen atom, a lower alkyl group, or a lower alkoxy group, and R^{2a} and R^{3a} are hydrogen atoms; and Ring B is



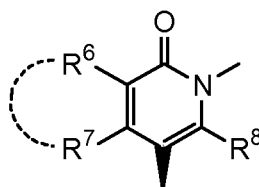
wherein R^{4b} and R^{5b} are each independently a hydrogen atom, a halogen atom, a lower alkyl group, a halo-lower alkyl group, a lower alkoxy group, or a halo-lower alkoxy group.

- 5 In another aspect of the present invention, preferable examples of the compound I include a compound represented by the following formula IB:



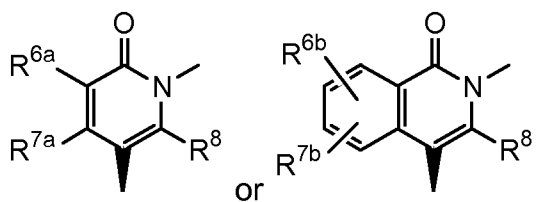
- wherein R^8 , R^9 and R^{10} are each independently a hydrogen atom, a halogen atom, a hydroxy group, an alkoxy group, an alkyl group, a haloalkyl group, a haloalkoxy group, a hydroxyalkyl group, an alkoxyalkyl group, an alkoxyalkoxy group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, a cycloalkenyl group, a cycloalkyloxy group, an aryloxy group, an arylalkoxy group, a cyano group, a nitro group, an amino group, a mono- or di-alkylamino group, an alkylcarbonylamino group, a carboxyl group, an alkoxy carbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkanoyl group, an alkylsulfonylamino group, an arylsulfonylamino group, an alkylsulfinyl group, an alkylsulfonyl group, or an arylsulfonyl group; and
- 15

a group represented by:



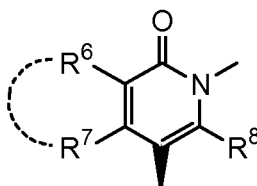
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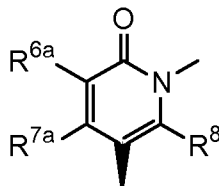


- wherein R^{6a} and R^{7a} are each independently a hydrogen atom, a halogen atom, a hydroxy group, an alkoxy group, an alkyl group, a haloalkyl group, a haloalkoxy group, a hydroxyalkyl group, an alkoxyalkyl group, an alkoxyalkoxy group, an alkenyl group, an alkynyl group, a cycloalkyl group, a cycloalkylidenemethyl group, a cycloalkenyl group, a cycloalkyloxy group, an aryloxy group, an arylalkoxy group, a cyano group, a nitro group, an amino group, a mono- or di-alkylamino group, an alkylcarbonylamino group, a carboxyl group, an alkoxy carbonyl group, a carbamoyl group, a mono- or di-alkylcarbamoyl group, an alkanoyl group, an alkylsulfonylamino group, an arylsulfonylamino group, an alkylsulfinyl group, an alkylsulfonyl group, or an arylsulfonyl group and R^{6b} and R^{7b} are each independently a hydrogen atom, a halogen atom, an alkyl group, a haloalkyl group, or an alkoxy group.

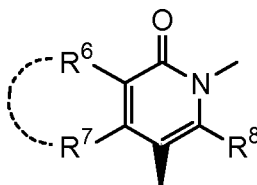
- Among the compounds represented by the formula IB, more preferred is a compound in which R^8 , R^9 and R^{10} are each independently a hydrogen atom, a halogen atom, a lower alkyl group, a cycloalkyl group, a hydroxy-lower alkyl group, a halo-lower alkyl group, a lower alkoxy-lower alkyl group, a lower alkoxy group, a cycloalkoxy group, a halo-lower alkoxy group, or a lower alkoxy-lower alkoxy group, and a group represented by:



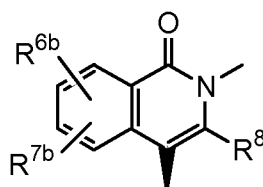
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- wherein R^{6a} , R^{7a} are each independently a hydrogen atom, a halogen atom, a lower alkyl group, a cycloalkyl group, a hydroxy-lower alkyl group, a halo-lower alkyl group, a lower alkoxy-lower alkyl group, a lower alkoxy group, a cycloalkoxy group, a halo-lower alkoxy group, or a lower alkoxy-lower alkoxy group, or a group represented by:

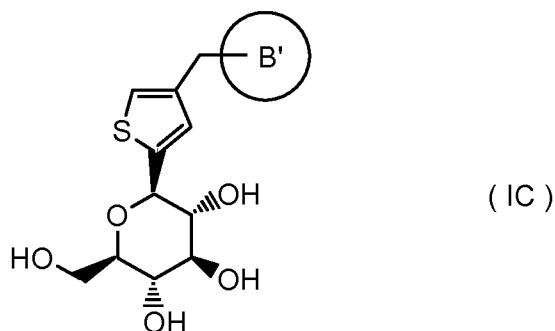


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- wherein R^{6b} and R^{7b} are each independently a hydrogen atom, a halogen atom, a lower alkyl group, a halo-lower alkyl group, or a lower alkoxy group.

In another aspect of the present invention, preferable examples of the compound I include a compound represented by the following formula IC:



- wherein Ring B' is an optionally substituted benzene ring, an optionally substituted unsaturated monocyclic heterocyclic ring, or an optionally substituted unsaturated fused heterobicyclic ring.

- Preferable examples of Ring B' include a benzene ring and a heterocyclic ring, both of which may have a substituent(s) selected from the group consisting of a halogen atom; a cyano group; a lower alkyl group optionally substituted by a halogen atom; a lower alkoxy group optionally substituted by a halogen atom; a lower alkanoyl group; a mono- or di-lower

alkylamino group; a lower alkoxycarbonyl group; a carbamoyl group; a mono- or di-lower alkylcarbamoyl group; a phenyl group optionally substituted by a substituent(s) selected from a halogen atom, a cyano group, a lower alkyl group optionally substituted by a halogen atom, a lower alkoxy group optionally substituted by a halogen atom, a lower alkanoyl group, a mono- or di-lower alkylamino group, a lower alkoxycarbonyl group, a carbamoyl group, or a mono- or di-lower alkylcarbamoyl group; a heterocyclyl group optionally substituted by a substituent(s) selected from a halogen atom, a cyano group, a lower alkyl group optionally substituted by a halogen atom, a lower alkoxy group optionally substituted by a halogen atom, a lower alkanoyl group, a mono- or di-lower alkylamino group, a lower alkoxycarbonyl group, a carbamoyl group, or a mono- or di-lower alkylcarbamoyl group; an alkylene group; and an oxo group.

More preferable examples of Ring B' include a benzene ring which may be substituted by a substituent selected from the group consisting of a halogen atom; a cyano group; a lower alkyl group optionally substituted by a halogen atom; a lower alkoxy group optionally substituted by a halogen atom; a mono- or di-lower alkylamino group; a phenyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group optionally substituted by a halogen atom, a lower alkoxy group optionally substituted by a halogen atom; a heterocyclyl group optionally substituted by a halogen atom, a cyano group, a lower alkyl group optionally substituted by a halogen atom, a lower alkoxy group optionally substituted by a halogen atom.

Preferred compound of the present invention may be selected from the following group:

- 1-(β -D-glucopyranosyl)-4-chloro-3-(6-ethylbenzo[b]thiophen-2-ylmethyl)benzene;
- 1-(β -D-glucopyranosyl)-4-chloro-3-[5-(5-thiazolyl)-2-thienylmethyl]benzene;
- 1-(β -D-glucopyranosyl)-4-chloro-3-(5-phenyl-2-thienyl-methyl)benzene;
- 1-(β -D-glucopyranosyl)-4-methyl-3-[5-(4-fluorophenyl)-2-thienylmethyl]benzene;

1-(β -D-glucopyranosyl)-4-chloro-3-[5-(2-pyrimidinyl)-2-thienylmethyl]benzene;

1-(β -D-glucopyranosyl)-4-methyl-3-[5-(2-pyrimidinyl)-2-thienylmethyl]benzene;

5 1-(β -D-glucopyranosyl)-4-chloro-3-[5-(3-cyanophenyl)-2-thienylmethyl]benzene;

1-(β -D-glucopyranosyl)-4-chloro-3-[5-(4-cyanophenyl)-2-thienylmethyl]benzene;

10 1-(β -D-glucopyranosyl)-4-methyl-3-[5-(6-fluoro-2-pyridyl)-2-thienylmethyl]benzene;

1-(β -D-glucopyranosyl)-4-chloro-3-[5-(6-fluoro-2-pyridyl)-2-thienylmethyl]benzene;

1-(β -D-glucopyranosyl)-4-methyl-3-[5-(3-difluoromethyl-phenyl)-2-thienylmethyl]benzene;

15 1-(β -D-glucopyranosyl)-4-methyl-3-[5-(3-cyanophenyl)-2-thienylmethyl]benzene;

1-(β -D-glucopyranosyl)-4-methyl-3-[5-(4-cyanophenyl)-2-thienylmethyl]benzene;

20 1-(β -D-glucopyranosyl)-4-chloro-3-[5-(6-fluoro-3-pyridyl)-2-thienylmethyl]benzene;

1-(β -D-glucopyranosyl)-4-fluoro-3-(5-(3-cyanophenyl)-2-thienylmethyl)benzene;

the pharmaceutically acceptable salt thereof; and the prodrug thereof.

Particularly Preferred compounds of the present invention include:

25 1-(β -D-glucopyranosyl)-4-methyl-3-[5-(3-cyano-phenyl)-2-thienylmethyl]benzene, or a pharmaceutically acceptable salt thereof, or a prodrug thereof;

30 1-(β -D-glucopyranosyl)-4-methyl-3-[5-(4-cyano-phenyl)-2-thienylmethyl]benzene, or a pharmaceutically acceptable salt thereof, or a prodrug thereof;

1-(β -D-glucopyranosyl)-4-methyl-3-[5-(4-fluoro-phenyl)-2-thienylmethyl]benzene, or a pharmaceutically acceptable salt thereof, or a prodrug thereof;

1-(β -D-glucopyranosyl)-4-chloro-3-[5-(3-cyano-phenyl)-2-thienylmethyl]benzene, or a pharmaceutically acceptable salt thereof, or a prodrug thereof;

5 1-(β -D-glucopyranosyl)-4-methyl-3-[5-(6-fluoro-2-pyridyl)-2-thienylmethyl]benzene, or a pharmaceutically acceptable salt thereof, or a prodrug thereof;

1-(β -D-glucopyranosyl)-4-chloro-3-[5-(6-fluoro-2-pyridyl)-2-thienylmethyl]benzene, or a pharmaceutically acceptable salt thereof, or a prodrug thereof;

10 1-(β -D-glucopyranosyl)-4-chloro-3-[5-(6-fluoro-3-pyridyl)-2-thienylmethyl]benzene, or a pharmaceutically acceptable salt thereof, or a prodrug thereof; and

15 1-(β -D-glucopyranosyl)-4-fluoro-3-(5-(3-cyanophenyl)-2-thienylmethyl)benzene, or a pharmaceutically acceptable salt thereof, or a prodrug thereof.

Abbreviations used in the specification, particularly the Schemes and Examples, are as follows:

Ac	=	Acetyl
BF ₃ ·OEt ₂	=	Boron trifluoride diethyl etherate
BF ₃ ·THF	=	Complex of boron trifluoride and tetrahydrofuran
t-Bu ₃ P·HBF ₄	=	Tri-(t-butyl)phosphine tetrafluoroboric acid adduct
DCE	=	Dichloroethane
DCM	=	Dichloromethane
DMAP	=	4-Dimethylaminopyrdine
DME	=	1,2-Dimethoxyethane
DMF	=	N,N-Dimethylformamide
dppb	=	1,4-Bis(diphenylphosphino)butane
dppe	=	1,2-Bis(diphenylposhino)ethane
dppf	=	1,1'-Bis(diphenylphosphino)ferrocene
dppp	=	1,3-Bis(diphenylposhino)propane
Et	=	Ethyl
EtOAc	=	Ethyl acetate

Et ₃ SiH	=	Triethylsilane
HPLC	=	High Performance Liquid Chromatography
<i>i</i> -Pr ₃ SiH	=	Triisopropylsilane
Me	=	Methyl
2-Me-THF	=	2-Methyl Tetrahydrofuran
Ms	=	Methanesulfonyl
MTBE	=	Methyl-t-butyl Ether
Ni(COD) ₂	=	Bis(1,5-cyclooctadiene)nickel(0)
NiCl ₂ (dppe)	=	Nickel 1,2-bis(diphenylphosphino)ethane dichloride
NiCl ₂ (dppf)	=	Nickel 1,1'-bis(diphenylphosphino)ferrocene dichloride
NiCl ₂ (dppp)	=	Nickel 1,3-bis(diphenylphosphino)propane dichloride
Ni(OAc) ₂ / dppe	=	Nickel acetate and 1,2-bis(diphenylphosphino)ethane
NMM	=	N-Methylmorpholine
Pd/C	=	Palladium on carbon
PdCl ₂ (PPh ₃) ₂	=	Bis(triphenylphosphine)palladium(II)dichloride
Pd(OAc) ₂	=	Palladium acetate
Pd(OAc) ₂ /dppp	=	Palladium acetate and 1,3-bis(diphenylphosphino)propane complex
Pd(OAc) ₂ / Et ₃ SiH	=	Palladium acetate and triethylsilane complex
Pr	=	Propyl
RaNi	=	RANEY [®] nickel (aluminum nickel alloy)
TFA	=	Trifluoroacetic acid
THF	=	Tetrahydrofuran
TMDSO	=	Tetramethyldisiloxane
TMS	=	Trimethylsilyl
TOF	=	Turnover frequency (the number of reactant moles converted to the desired product per mole of catalyst used per hour)

As used herein, unless otherwise noted, the term “**isolated form**” shall mean that the compound is present in a form which is separate from any solid mixture with another compound(s), solvent system or biological environment. In an embodiment, the present invention is directed to a process for the

preparation of a compound of formula (I), wherein the compound of formula (I) is prepared as an isolated form. In another embodiment, the present invention is directed to a process for the preparation of a compound of formula (IA'), wherein the compound of formula (IA') is prepared as an isolated form. In another embodiment, the present invention is directed to a process for the preparation of a compound of formula (I-S), wherein the compound of formula (I-S) is prepared as an isolated form. In another embodiment, the present invention is directed to a process for the preparation of a compound of formula (I-K), wherein the compound of formula (I-S) is prepared as an isolated form.

10 As used herein, unless otherwise noted, the term “**substantially pure**” shall mean that the mole percent of impurities in the isolated compound is less than about 5 mole percent, preferably less than about 2 mole percent, more preferably, less than about 0.5 mole percent, most preferably, less than about 0.1 mole percent.

15 In an embodiment, the present invention is directed to a process for the preparation of a compound of formula (I), wherein the compound of formula (I) is substantially pure. In another embodiment, the present invention is directed to a process for the preparation of a compound of formula (IA'), wherein the compound of formula (IA') is substantially pure. In another embodiment, the present invention is directed to a process for the preparation of a compound of formula (I-S), wherein the compound of formula (I-S) is substantially pure. In another embodiment, the present invention is directed to a process for the preparation of a compound of formula (I-K), wherein the compound of formula (I-K) is substantially pure.

25 As used herein, unless otherwise noted, the term “**substantially free of a corresponding salt form(s)**” when used to described the compound of formula (I) shall mean that mole percent of the corresponding salt form(s) in the isolated base of formula (I) is less than about 5 mole percent, preferably less than about 2 mole percent, more preferably, less than about 0.5 mole percent, most preferably less than about 0.1 mole percent.

30 In an embodiment, the present invention is directed to a process for the preparation of a compound of formula (I), wherein the compound of formula (I) is substantially free of corresponding salt forms. In another embodiment, the

present invention is directed to a process for the preparation of a compound of formula (IA'), wherein the compound of formula (IA') is substantially free of corresponding salt forms. In another embodiment, the present invention is directed to a process for the preparation of a compound of formula (I-S),
5 wherein the compound of formula (I-S) is substantially free of corresponding salt forms. In another embodiment, the present invention is directed to a process for the preparation of a compound of formula (I-K), wherein the compound of formula (I-K) is substantially free of corresponding salt forms.

As used herein, unless otherwise noted, the terms **"treating"**,
10 **"treatment"** and the like, shall include the management and care of a subject or patient (preferably mammal, more preferably human) for the purpose of combating a disease, condition, or disorder and includes the administration of a compound of the present invention to prevent the onset of the symptoms or complications, alleviate the symptoms or complications, or eliminate the
15 disease, condition, or disorder.

As used herein, unless otherwise noted, the term **"prevention"** shall include (a) reduction in the frequency of one or more symptoms; (b) reduction in the severity of one or more symptoms; (c) the delay or avoidance of the development of additional symptoms; and / or (d) delay or avoidance of the
20 development of the disorder or condition.

One skilled in the art will recognize that wherein the present invention is directed to methods of prevention, a subject in need of thereof (i.e. a subject in need of prevention) shall include any subject or patient (preferably a mammal, more preferably a human) who has experienced or exhibited at least one
25 symptom of the disorder, disease or condition to be prevented. Further, a subject in need thereof may additionally be a subject (preferably a mammal, more preferably a human) who has not exhibited any symptoms of the disorder, disease or condition to be prevented, but who has been deemed by a physician, clinician or other medical profession to be at risk of developing said
30 disorder, disease or condition. For example, the subject may be deemed at risk of developing a disorder, disease or condition (and therefore in need of prevention or preventive treatment) as a consequence of the subject's medical

history, including, but not limited to, family history, pre-disposition, co-existing (comorbid) disorders or conditions, genetic testing, and the like.

The term “**subject**” as used herein, refers to an animal, preferably a mammal, most preferably a human, who has been the object of treatment,
5 observation or experiment. Preferably, the subject has experienced and / or exhibited at least one symptom of the disease or disorder to be treated and / or prevented.

The term “**therapeutically effective amount**” as used herein, means that amount of active compound or pharmaceutical agent that elicits the biological or medicinal response in a tissue system, animal or human that is being sought by a
10 researcher, veterinarian, medical doctor or other clinician, which includes alleviation of the symptoms of the disease or disorder being treated.

As used herein, the term “**composition**” is intended to encompass a product comprising the specified ingredients in the specified amounts, as well
15 as any product which results, directly or indirectly, from combinations of the specified ingredients in the specified amounts.

The compound of formula (I) of the present invention exhibits an excellent inhibitory activity against sodium-dependent glucose transporter, and an excellent blood glucose lowering effect. Therefore, the compound of the
20 present invention is useful for treating or delaying the progression or onset of diabetes mellitus, diabetic retinopathy, diabetic neuropathy, diabetic nephropathy, delayed wound healing, insulin resistance, hyperglycemia, hyperinsulinemia, elevated blood levels of fatty acids, elevated blood levels of glycerol, hyperlipidemia, obesity, hypertriglyceridemia, Syndrome X, diabetic
25 complications, atherosclerosis, or hypertension. In particular, the compound of the present invention is useful in the treatment or the prophylaxis of diabetes mellitus (type 1 and type 2 diabetes mellitus, etc.), diabetic complications (such as diabetic retinopathy, diabetic neuropathy, diabetic nephropathy) or obesity, or is useful in the treatment of postprandial hyperglycemia.

30 The compound of formula (I) of the present invention or a pharmaceutically acceptable salt thereof may be administered either orally or parenterally, and can be used in the form of a suitable pharmaceutical preparation. Suitable pharmaceutical preparation for oral administration

includes, for example, solid preparation such as tablets, granules, capsules, powders, etc., or solution preparations, suspension preparations, or emulsion preparations, etc. Suitable pharmaceutical preparation for parenteral administration includes, for example, suppositories; injection preparations and
5 intravenous drip preparations using distilled water for injection, physiological saline solution or aqueous glucose solution; or inhalant preparations.

The dosage of the present compound of formula (I) or a pharmaceutically acceptable salt thereof may vary according to the administration routes, ages, body weight, conditions of a patient, or kinds and
10 severity of a disease to be treated, and it is usually in the range of about 0.01 to about 300 mg/kg/day, or any amount or range therein, preferably in the range of about 0.1 to about 50 mg/kg/day, or any amount or range therein, preferably in the range of about 0.1 to about 30 mg/kg/day, or any amount or range therein.

15 The compound of the formula I may be used, if necessary, in combination with one or more of other antidiabetic agents, one or more agents for treating diabetic complications, and/or one or more agents for treatment of other diseases. The present compound and these other agents may be administered in the same dosage form, or in a separate oral dosage form or by
20 injection.

The other antidiabetic agents include, for example, antidiabetic or antihyperglycemic agents including insulin, insulin secretagogues, or insulin sensitizers, or other antidiabetic agents having an action mechanism different from SGLT inhibition, and 1, 2, 3 or 4 of these other antidiabetic agents may
25 preferably be used. Concrete examples thereof are biguanide compounds, sulfonylurea compounds, α -glucosidase inhibitors, PPAR γ agonists (e.g., thiazolidinedione compounds), PPAR α/γ dual agonists, dipeptidyl peptidase IV (DPP4) inhibitors, mitiglinide compounds, and/or nateglinide compounds, and insulin, glucagon-like peptide-1 (GLP-1), PTP1B inhibitors, glycogen
30 phosphorylase inhibitors, RXR modulators, and/or glucose 6-phosphatase inhibitors.

The agents for treatment of other diseases include, for example, an anti-obesity agent, an antihypertensive agent, an antiplatelet agent, an anti-atherosclerotic agent and/or a hypolipidemic agent.

5 The SGLT inhibitors of the formula I may be used in combination with agents for treatment of diabetic complications, if necessary. These agents include, for example, PKC inhibitors and/or ACE inhibitors.

The dosage of those agents may vary according to ages, body weight, and conditions of patients, and administration routes, dosage forms, etc.

10 These pharmaceutical compositions may be orally administered to mammalian species including human beings, apes, dogs, etc., for example, in the dosage form of tablet, capsule, granule or powder, or parenterally administered in the form of injection preparation, or intranasally, or in the form of transdermal patch.

15 One skilled in the art will recognize that, where not otherwise specified, the reaction step(s) is performed under suitable conditions, according to known methods, to provide the desired product.

One skilled in the art will further recognize that, in the specification and claims as presented herein, wherein a reagent or reagent class/type (e.g. base, solvent, etc.) is recited in more than one step of a process, the individual
20 reagents are independently selected for each reaction step and may be the same or different from each other. For example wherein two steps of a process recite an organic or inorganic base as a reagent, the organic or inorganic base selected for the first step may be the same or different than the organic or inorganic base of the second step. Further, one skilled in the art will recognize
25 that wherein a reaction step of the present invention may be carried out in a variety of solvents or solvent systems, said reaction step may also be carried out in a mixture of the suitable solvents or solvent systems.

Examples of suitable solvents, bases, reaction temperatures, and other reaction parameters and components are provided in the detailed descriptions
30 which follows herein. One skilled in the art will recognize that the listing of said examples is not intended, and should not be construed, as limiting in any way the invention set forth in the claims which follow thereafter.

To provide a more concise description, some of the quantitative expressions herein are recited as a range from about amount X to about amount Y. It is understood that wherein a range is recited, the range is not limited to the recited upper and lower bounds, but rather includes the full range
5 from about amount X through about amount Y, or any range therein.

To provide a more concise description, some of the quantitative expressions given herein are not qualified with the term “**about**”. It is understood that whether the term “about” is used explicitly or not, every quantity given herein is meant to refer to the actual given value, and it is also
10 meant to refer to the approximation to such given value that would reasonably be inferred based on the ordinary skill in the art, including approximations due to the experimental and/or measurement conditions for such given value.

As used herein, unless otherwise noted, the term “**nitrogen protecting group**” shall mean a group which may be attached to a nitrogen atom to
15 protect said nitrogen atom from participating in a reaction and which may be readily removed following the reaction. Suitable nitrogen protecting groups include, but are not limited to carbamates – groups of the formula $-C(O)O-R$ wherein R is for example methyl, ethyl, t-butyl, benzyl, phenylethyl, $CH_2=CH-CH_2-$, and the like; amides – groups of the formula $-C(O)-R'$ wherein R' is for
20 example methyl, phenyl, trifluoromethyl, and the like; N-sulfonyl derivatives - groups of the formula $-SO_2-R''$ wherein R'' is for example tolyl, phenyl, trifluoromethyl, 2,2,5,7,8-pentamethylchroman-6-yl-, 2,3,6-trimethyl-4-methoxybenzene, and the like. Other suitable nitrogen protecting groups may be found in texts such as T.W. Greene & P.G.M. Wuts, Protective Groups in
25 Organic Synthesis, John Wiley & Sons, 1991.

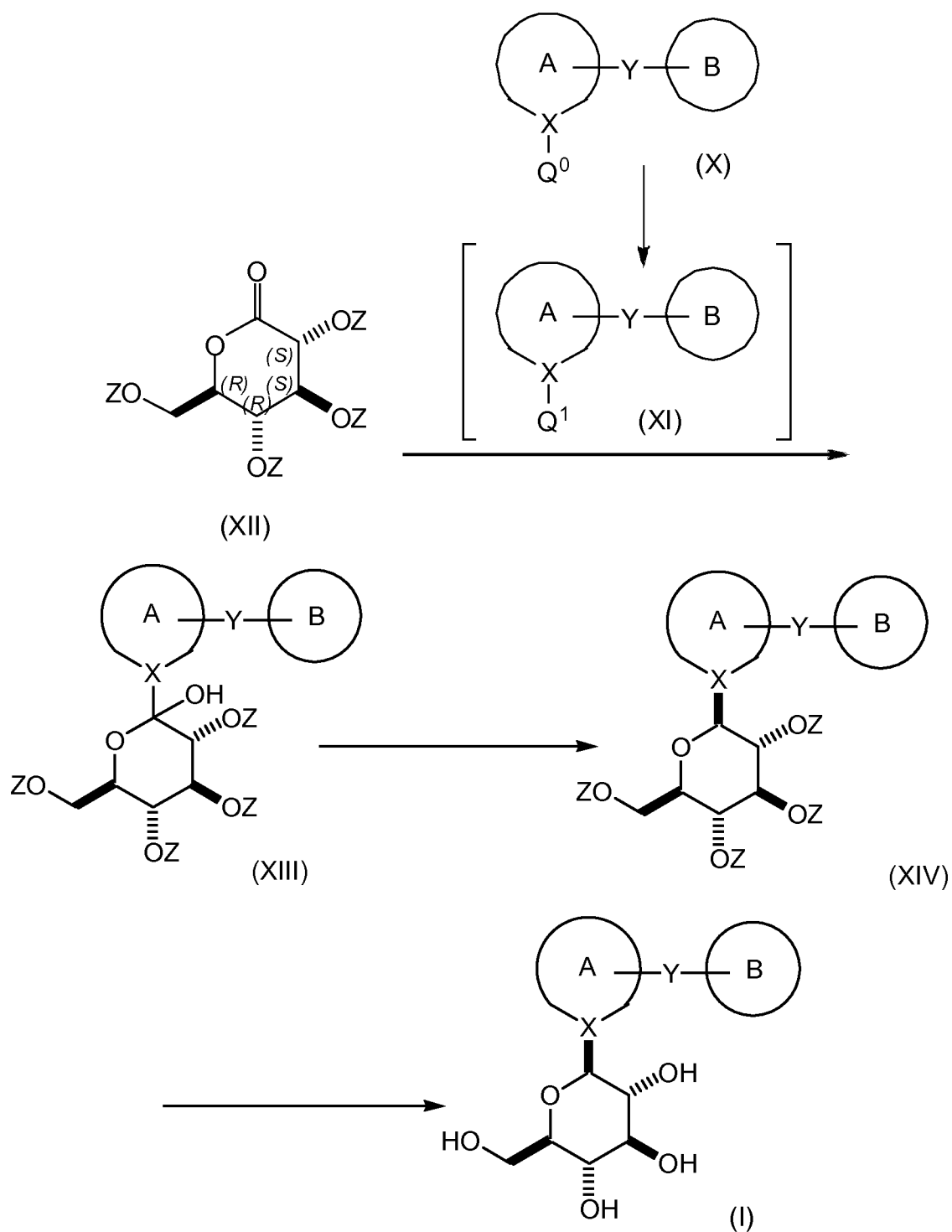
As used herein, unless otherwise noted, the term “**oxygen protecting group**” shall mean a group which may be attached to a oxygen atom to protect said oxygen atom from participating in a reaction and which may be readily removed following the reaction. Suitable oxygen protecting groups include, but
30 are not limited to, acetyl, benzoyl, t-butyl-dimethylsilyl, trimethylsilyl (TMS), MOM, THP, and the like. Other suitable oxygen protecting groups may be found in texts such as T.W. Greene & P.G.M. Wuts, Protective Groups in Organic Synthesis, John Wiley & Sons, 1991.

Where the processes for the preparation of the compounds according to the invention give rise to mixture of stereoisomers, these isomers may be separated by conventional techniques such as preparative chromatography. The compounds may be prepared in racemic form, or individual enantiomers
5 may be prepared either by enantiospecific synthesis or by resolution. The compounds may, for example, be resolved into their component enantiomers by standard techniques, such as the formation of diastereomeric pairs by salt formation with an optically active acid, such as (-)-di-p-toluoyl-D-tartaric acid and/or (+)-di-p-toluoyl-L-tartaric acid followed by fractional crystallization and
10 regeneration of the free base. The compounds may also be resolved by formation of diastereomeric esters or amides, followed by chromatographic separation and removal of the chiral auxiliary. Alternatively, the compounds may be resolved using a chiral HPLC column.

During any of the processes for preparation of the compounds of the
15 present invention, it may be necessary and/or desirable to protect sensitive or reactive groups on any of the molecules concerned. This may be achieved by means of conventional protecting groups, such as those described in Protective Groups in Organic Chemistry, ed. J.F.W. McOmie, Plenum Press, 1973; and T.W. Greene & P.G.M. Wuts, Protective Groups in Organic Synthesis, John
20 Wiley & Sons, 1991. The protecting groups may be removed at a convenient subsequent stage using methods known from the art.

One skilled in the art will recognize that in any of the processes described herein, reactive substituents on the compounds of formula (I), such as hydroxy groups, oxo groups, carboxy groups, and the like, are preferably
25 protected and subsequently de-protected, according to known methods, at suitable points along the synthesis route.

The present invention is directed to a process for the preparation of compounds of formula (I) as outlined in Scheme 1, below.



Scheme 1

- 5 Accordingly, a suitably substituted compound of formula (X), wherein Q⁰ is bromo or iodo, a known compound or compound prepared by known methods, is reacted with a complex of di(C₁₋₄alkyl) magnesium with lithium chloride such as di(sec-butyl)magnesium with lithium chloride, and the like; or a complex C₁₋₄alkyl magnesium chloride with lithium chloride or a complex of C₁-

- 4alkyl magnesium bromide with lithium chloride; wherein the C₁₋₄alkyl is preferably isopropyl or sec-butyl, more preferably sec-butyl, a known compound or compound prepared by known methods; wherein the complex of di(C₁₋₄alkyl)magnesium with lithium chloride or the complex of C₁₋₄alkyl magnesium chloride with lithium chloride or the complex of C₁₋₄alkyl magnesium bromide with lithium chloride is preferably present in an amount in the range of from about 1.0 to 1.5 molar equivalents (relative to the moles of the compound of formula (X)), or any range therein, more preferably, in an amount of about 1.2 molar equivalents;
- 10 in an organic solvent or mixture thereof, such as toluene, THF, hexane, pentane, MTBE, 1,4-dioxane, and the like, preferably a mixture of THF and toluene; at a temperature in the range of from about ambient temperature to about -78°C, or any range therein, preferably at a temperature in the range of from about 2°C to about 5°C; to yield the corresponding compound of formula
- 15 (XI), wherein Q¹ is the corresponding MgCl or MgBr.
- The compound of formula (XI) is reacted with a suitably substituted compound of formula (XII), wherein Z is a suitably selected oxygen protecting group, for example Z may selected from the group consisting of acetyl, benzyl, benzoyl, pivaloyl, and isobutyryl, preferably Z is acetyl; a known compound or
- 20 compound prepared by known methods;
- wherein the compound of formula (XII) is preferably present in an amount in the range of from about 1.0 to about 2.0 molar equivalents, or any range therein, more preferably in an amount in the range of from about 1.0 to about 1.3 molar equivalents, or any range therein;
- 25 in an organic solvent or mixture thereof, such as toluene, THF, hexane, pentane, MTBE, 1,4-dioxane, and the like, preferably a mixture of toluene and THF; at a temperature in the range of from about ambient temperature to about -78°C, or any range therein, preferably at about -35°C; to yield the corresponding compound of formula (XIII).
- 30 Preferably, the compound of formula (XI) is added to a mixture of the compound of formula (XII) in an organic solvent or mixture thereof, to yield the compound of formula (XIII).

The compound of formula (XIII) is reacted with a suitably selected Lewis acid, such as $\text{BF}_3 \cdot \text{OEt}_2$, $\text{BF}_3 \cdot \text{THF}$, aluminum chloride, zinc chloride, iron chloride, and the like, preferably, $\text{BF}_3 \cdot \text{THF}$ or aluminum chloride, more preferably aluminum chloride; wherein the Lewis acid is preferably present in
5 an amount in the range of from about 0.5 to about 10.0 molar equivalents, or any range therein, more preferably, in an amount in the range of from about 0.5 to about 2.5 molar equivalents, or any range therein, most preferably about 0.8 molar equivalents;

in the presence of a suitably selected silane reagent such as
10 triisopropylsilane, triethylsilane, tetramethyldisiloxane, and the like, preferably triethylsilane or tetramethyldisiloxane, more preferably tetramethyldisiloxane; wherein the silane reagent is preferably present in an amount in the range of from about 1.0 to about 10.0 molar equivalents, or any range therein, more preferably, in an amount in the range of from about 1.0 to about 6.0 molar
15 equivalents, or any range therein, most preferably about 1.0 molar equivalent; wherein, in an embodiment of the present invention, the ratio of the aluminum chloride to the tetramethyldisiloxane is about 1 : 1.25;

in an organic solvent or mixture thereof such as DCM, DCE, acetonitrile, toluene, and the like, or in a mixture of said organic solvents, preferably in
20 acetonitrile; preferably at a temperature in the range of from about 0°C to about reflux, or any range therein, more preferably at about 45°C; to yield the corresponding compound of formula (XIV).

The compound of formula (XIV) is preferably slurried or dissolved in a solvent, more preferably slurried; and then filtered, preferably filtered at an
25 elevated temperature, to remove impurities and / or byproducts.

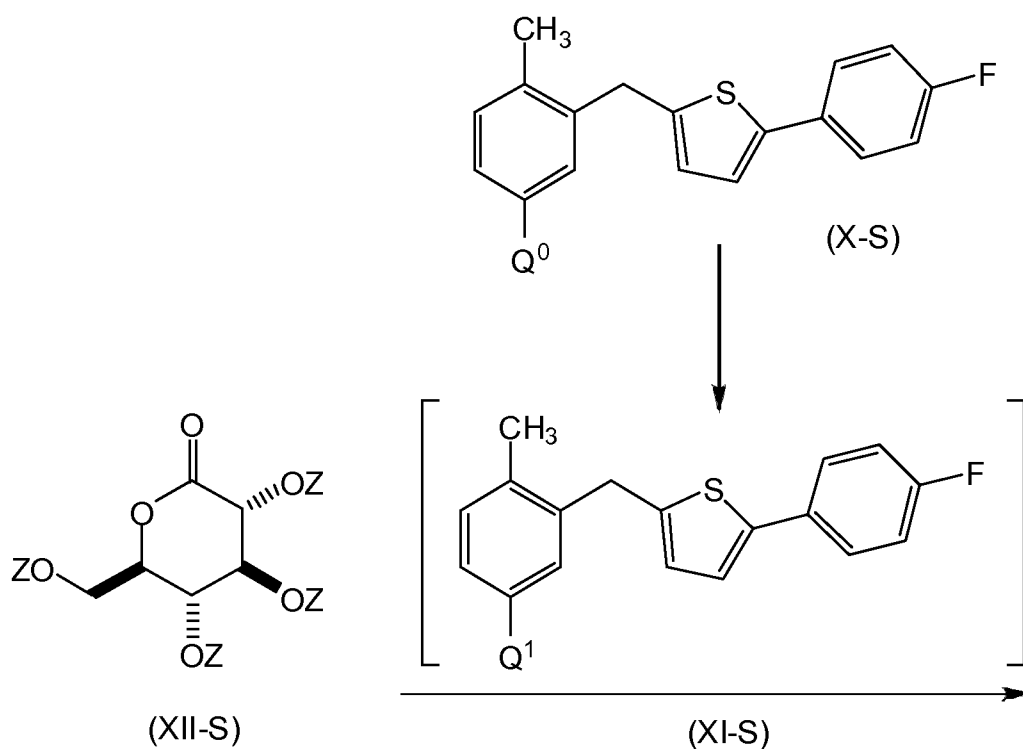
The compound of formula (XIV) is de-protected according to known methods. For example, the compound of formula (XIV) is reacted with a suitably selected base such as LiOH , NaOH , NaOCH_3 , and the like, preferably
30 NaOCH_3 ; wherein the base is preferably present in an amount in the range of from about 0.1 to about 2.0 molar equivalent, or any range therein, more preferably from about 0.5 to about 1.5 molar equivalents, or any range therein,

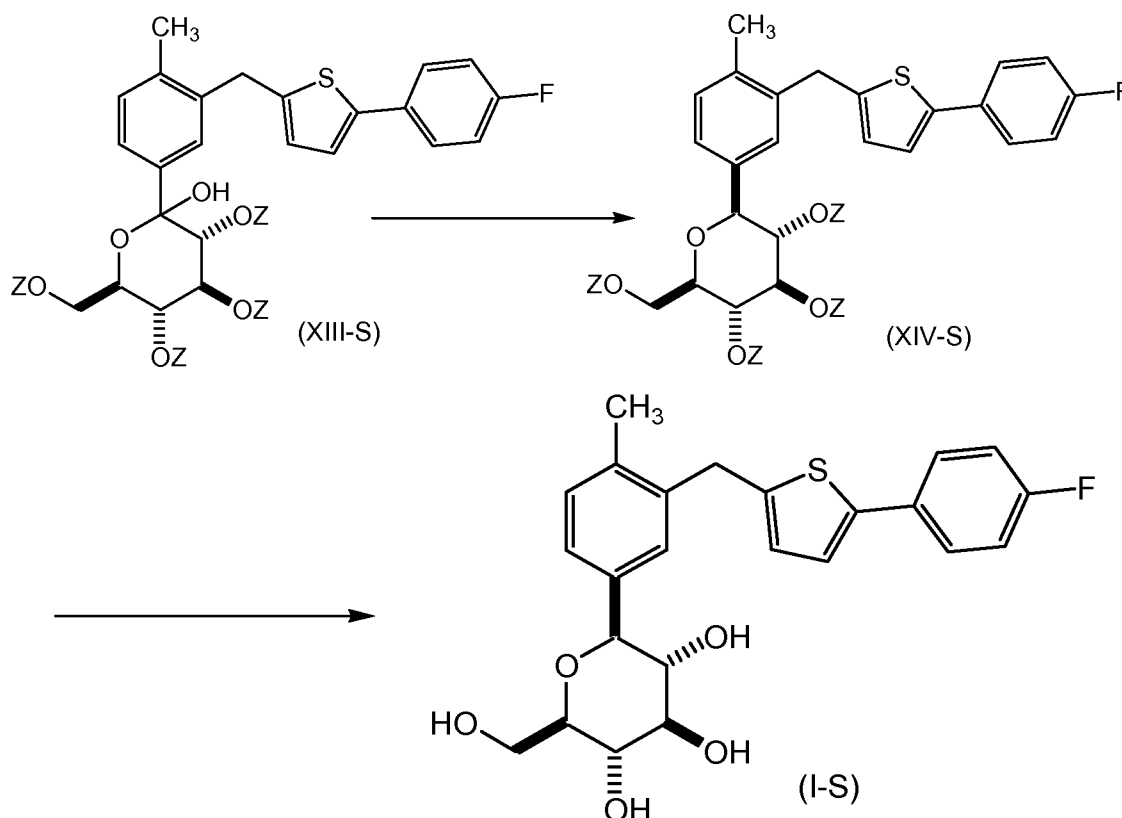
most preferably about 1.0 molar equivalents; in an organic solvent or mixture thereof, such as methanol, ethanol, THF, and the like, preferably in methanol; preferably at about room temperature; to yield the corresponding compound of formula (I).

5 One skilled in the art will further recognize that, depending on the particular protecting group, Z, other reagents may be used in the de-protection step including, but not limited to, Pd/C, Pd(OH)₂, PdCl₂, Pd(OAc)₂/Et₃SiH, and RaNi. These reagents can be employed using various solvent systems and/or additional acid or base combinations known to one of ordinary skill.

10 The compound of formula (I) is preferably isolated and/or recrystallized, according to known methods.

In an embodiment, the present invention is directed to a process for the preparation of a compound of formula (I-S), as outlined in Scheme 2, below.





- Accordingly, a suitably substituted compound of formula (X-S), wherein
- 5 Q^0 is bromo or iodo, a known compound or compound prepared by known methods, is reacted with a complex of di(C_{1-4} alkyl) magnesium with lithium chloride such as di(sec-butyl)magnesium with lithium chloride, and the like; or a complex C_{1-4} alkyl magnesium chloride with lithium chloride or a complex of C_{1-4} alkyl magnesium bromide with lithium chloride; wherein the C_{1-4} alkyl is
- 10 preferably isopropyl or sec-butyl, more preferably sec-butyl, a known compound or compound prepared by known methods; wherein the complex of di(C_{1-4} alkyl)magnesium with lithium chloride or the complex of C_{1-4} alkyl magnesium chloride with lithium chloride or the complex of C_{1-4} alkyl magnesium bromide with lithium chloride is preferably present in an amount in
- 15 the range of from about 1.0 to 1.5 molar equivalents (relative to the moles of the compound of formula (X-S)), or any range therein more preferably, in an amount of about 1.2 molar equivalents;

- in an organic solvent or mixture thereof, such as toluene, THF, hexane, pentane, MTBE, 1,4-dioxane, and the like, preferably a mixture of THF and
- 20 toluene; at a temperature in the range of from about ambient temperature to

about -78°C, or any range therein, preferably at a temperature in the range of from about 2°C to about 5°C; to yield the corresponding compound of formula (XI-S), wherein Q¹ is the corresponding MgCl or MgBr.

5 The compound of formula (XI-S) is reacted with a suitably substituted compound of formula (XII-S), wherein Z is a suitably selected oxygen protecting group, for example Z may selected from the group consisting of acetyl, benzyl, benzoyl, pivaloyl, and isobutyryl, preferably Z is acetyl; a known compound or compound prepared by known methods;

10 wherein the compound of formula (XII-S) is preferably present in an amount in the range of from about 1.0 to about 2.0 molar equivalents, or any range therein, more preferably in an amount in the range of from about 1.0 to about 1.3 molar equivalents, or any range therein;

15 in an organic solvent or mixture thereof, such as toluene, THF, hexane, pentane, MTBE, 1,4-dioxane, and the like, preferably a mixture of toluene and THF; at a temperature in the range of from about ambient temperature to about -78°C, or any range therein, preferably at about -35°C; to yield the corresponding compound of formula (XIII-S).

20 Preferably, the compound of formula (XI-S) is added to a mixture of the compound of formula (XII-S) in an organic solvent or mixture thereof, to yield the compound of formula (XIII-S).

The compound of formula (XIII-S) is reacted with a suitably selected Lewis acid, such as BF₃•OEt₂, BF₃•THF, aluminum chloride, zinc chloride, iron chloride, and the like, preferably, BF₃•THF or aluminum chloride, more preferably aluminum chloride; wherein the Lewis acid is preferably present in 25 an amount in the range of from about 0.5 to about 10.0 molar equivalents, or any range therein, more preferably, in an amount in the range of from about 0.5 to about 2.5 molar equivalents, most preferably about 0.8 molar equivalents;

30 in the presence of a suitably selected silane reagent such as iPr₃SiH, triethylsilane, tetramethyldisiloxane and the like, preferably triethylsilane or tetramethyldisiloxane, more preferably tetramethyldisiloxane; wherein the silane reagent is preferably present in an amount in the range of from about 1.0 to about 10.0 molar equivalents, or any range therein, more preferably, in an

amount in the range of from about 1.0 to about 6.0 molar equivalents, or any range therein, most preferably about 1.0 molar equivalent; wherein, in an embodiment of the present invention, the ratio of the aluminum chloride to the tetramethyldisiloxane is about 1 : 1.25;

5 in an organic solvent or mixture thereof such as DCM, DCE, acetonitrile, toluene, and the like, or in a mixture of said organic solvents, preferably in acetonitrile; preferably at a temperature in the range of from about 0°C to about reflux, or any range therein, more preferably at about 45°C; to yield the corresponding compound of formula (XIV-S).

10 The compound of formula (XIV-S) is preferably slurried or dissolved in a solvent, more preferably slurried; and then filtered, preferably filtered at an elevated temperature, to remove impurities and / or byproducts.

 The compound of formula (XIV-S) is de-protected according to known methods. For example, the compound of formula (XIV-S) is reacted with a
15 suitably selected base such as LiOH, NaOH, NaOCH₃, and the like, preferably NaOCH₃; wherein the base is preferably present in an amount in the range of from about 0.1 to about 2.0 molar equivalent, or any range therein, more preferably from about 0.5 to about 1.5 molar equivalents, or any range therein, most preferably about 1.0 molar equivalents; in an organic solvent or mixture
20 thereof, such as methanol, ethanol, THF, and the like, preferably in methanol; preferably at about room temperature; to yield the corresponding compound of formula (I-S).

 One skilled in the art will further recognize that, depending on the particular protecting group, Z, other reagents may be used in the de-protection
25 step including, but not limited to, Pd/C, Pd(OH)₂, PdCl₂, Pd(OAc)₂/Et₃SiH, and RaNi. These reagents can be employed using various solvent systems and/or additional acid or base combinations known to one of ordinary skill.

 The compound of formula (I-S) is preferably isolated and/or recrystallized, according to known methods.

30 In an embodiment, the present invention is directed to a process for the recrystallization of the compound of formula (I-S) comprising:

STEP A: dissolving the compound of formula (I-S) in an organic solvent such as ethyl acetate, isopropyl acetate, methanol, ethanol and the like, preferably ethyl acetate; then optionally filtering the resulting mixture;

5 STEP B: heating the mixture of STEP A to a temperature in the range of from about 25°C to about 45°C, preferably to a temperature in the range of from about 30°C to about 35°C; then optionally filtering the resulting mixture;

STEP C: adding water to the mixture prepared in STEP B; wherein the amount of water added is preferably in an amount in the range of from about 1.0 to about 2.0 molar equivalents (relative to the moles of the compound of
10 formula (I-S) used in STEP A), more preferably, the amount of water added is about 1.5 molar equivalents;

STEP D: adding an anti-solvent such as heptane, and the like, preferably heptane, to the mixture prepared in STEP C (wherein the anti-solvent is added to initiate precipitation); wherein the amount of anti-solvent
15 added is preferably an amount sufficient to yield a final volume : volume ratio of organic solvent (as selected in STEP A) : anti-solvent of from about 1: to about 1:5, more preferably, an amount sufficient to yield a final volume : volume ratio of about 1:2; to yield a precipitate of the compound of formula (I-S); which precipitate is preferably isolated by filtration and further, preferably dried
20 according to known methods.

In an embodiment of the present invention, the mixture prepared in STEP C is further seeded with previously prepared crystals of the desired polymorph of the compound of formula (I-S).

25 In another embodiment, the present invention is directed to an alternate process for the recrystallization of the compound of formula (I-S) comprising:

STEP A: dissolving the compound of formula (I-S) in an organic solvent such as ethyl acetate, isopropyl acetate, methanol, ethanol and the like, preferably isopropyl acetate; then optionally filtering the resulting mixture;

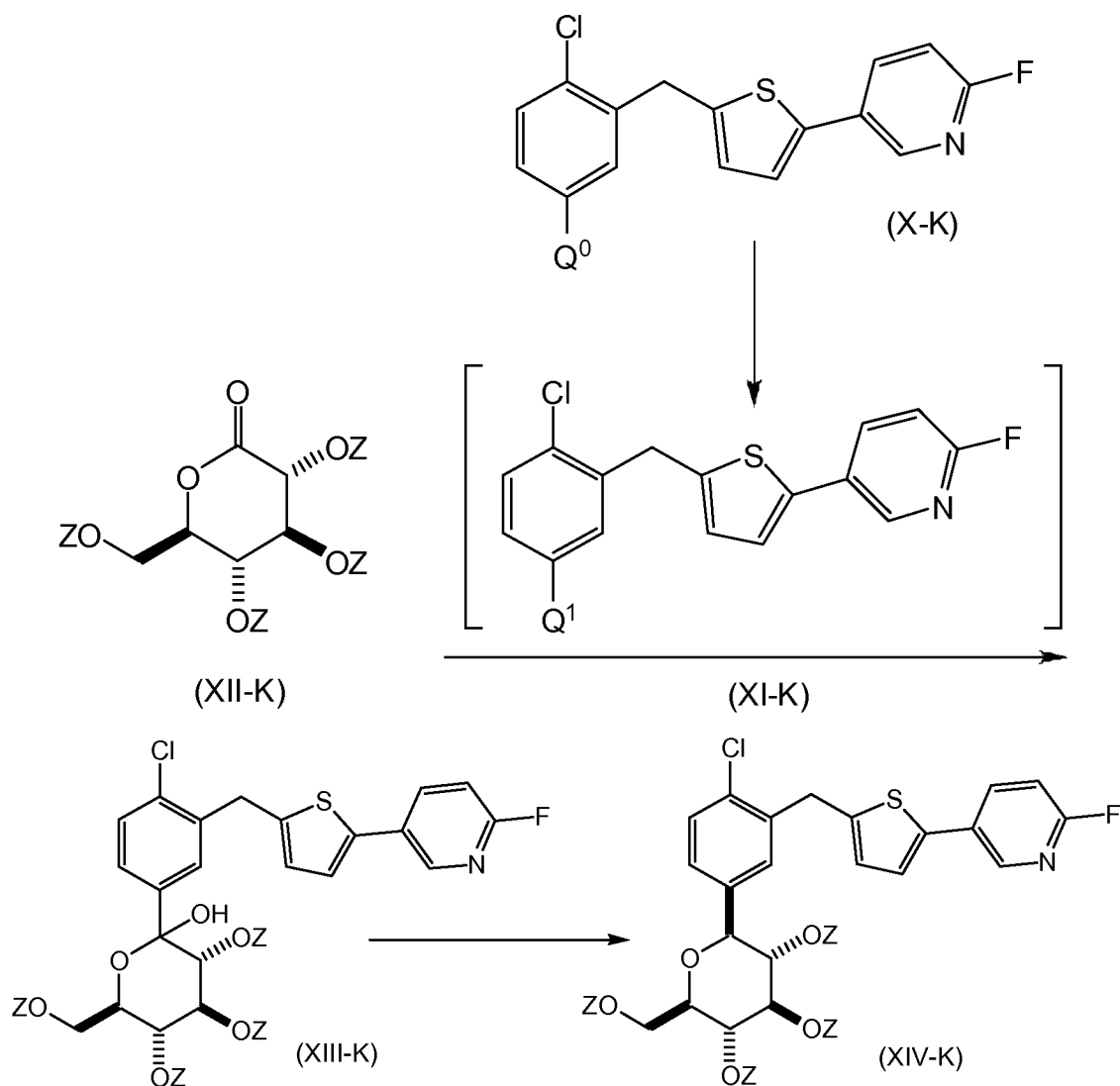
STEP B: adding water to the mixture prepared in STEP A; wherein the
30 amount of water added is preferably in an amount in the range of from about 1.0 to about 2.0 molar equivalents (relative to the moles of the compound of formula (I-S) used in STEP A), more preferably, the amount of water added is about 1.5 molar equivalents;

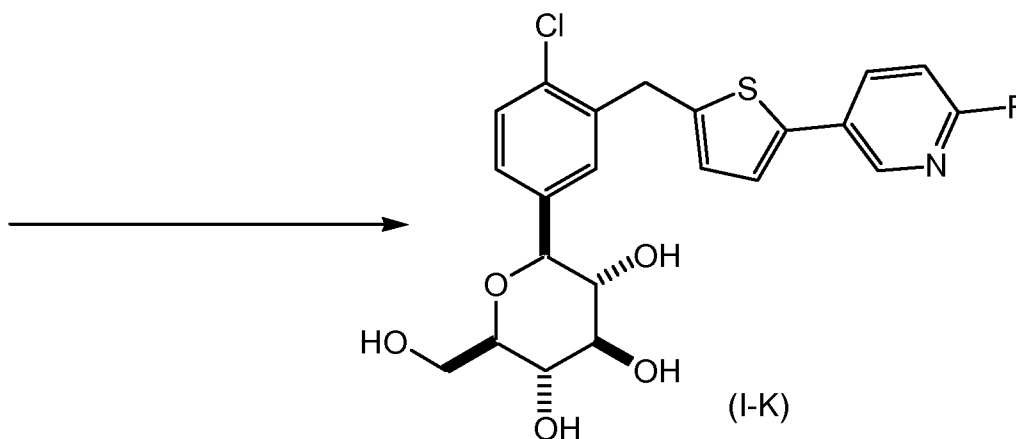
STEP C: heating the mixture of STEP B to a temperature in the range of from about 40°C to about 65°C, preferably to a temperature in the range of from about 60°C to about 65°C; then optionally filtering the resulting mixture;

STEP D: cooling the mixture prepared in STEP C; to yield a precipitate
5 of the compound of formula (I-S); which precipitate is preferably isolated by filtration and further, preferably dried according to known methods.

In an embodiment of the present invention, the mixture prepared in STEP C is further seeded with previously prepared crystals of the desired polymorph of the compound of formula (I-S).

10 In another embodiment, the present invention is directed to a process for the preparation of a compound of formula (I-K), as outlined in Scheme 3, below.





Scheme 3

Accordingly, a suitably substituted compound of formula (X-K), wherein Q^0 is bromo or iodo, a known compound or compound prepared by known methods, is reacted with a complex of di(C_{1-4} alkyl) magnesium with lithium chloride such as di(sec-butyl)magnesium with lithium chloride, and the like; or a complex C_{1-4} alkyl magnesium chloride with lithium chloride or a complex of C_{1-4} alkyl magnesium bromide with lithium chloride; wherein the C_{1-4} alkyl is preferably isopropyl or sec-butyl, more preferably sec-butyl, a known compound or compound prepared by known methods; wherein the complex of di(C_{1-4} alkyl)magnesium with lithium chloride or the complex of C_{1-4} alkyl magnesium chloride with lithium chloride or the complex of C_{1-4} alkyl magnesium bromide with lithium chloride is preferably present in an amount in the range of from about 1.0 to 1.5 molar equivalents (relative to the moles of the compound of formula (X-K)), or any range therein, more preferably, in an amount of about 1.2 molar equivalents;

in an organic solvent or mixture thereof, such as toluene, THF, hexane, pentane, MTBE, 1,4-dioxane, and the like, preferably a mixture of THF and toluene; at a temperature in the range of from about ambient temperature to about -78°C , or any range therein, preferably at a temperature in the range of from about 2°C to about 5°C ; to yield the corresponding compound of formula (XI-K), wherein Q^1 is the corresponding MgCl or MgBr.

The compound of formula (XI-K) is reacted with a suitably substituted compound of formula (XII-K), wherein Z is a suitably selected oxygen protecting group, for example Z may selected from the group consisting of acetyl, benzyl,

benzoyl, pivaloyl, and isobutyryl, preferably Z is acetyl; a known compound or compound prepared by known methods;

wherein the compound of formula (XII-K) is preferably present in an amount in the range of from about 1.0 to about 2.0 molar equivalents, or any
5 range therein, more preferably in an amount in the range of from about 1.0 to about 1.3 molar equivalents, or any range therein;

in an organic solvent or mixture thereof, such as toluene, THF, hexane, pentane, MTBE, 1,4-dioxane, and the like, preferably a mixture of toluene and THF; at a temperature in the range of from about ambient temperature to about
10 -78°C, or any range therein, preferably at about -35°C; to yield the corresponding compound of formula (XIII-K)

Preferably, the compound of formula (XI-K) is added to a mixture of the compound of formula (XII-K) in an organic solvent or mixture thereof, to yield the compound of formula (XIII-K).

15 The compound of formula (XIII-K) is reacted with a suitably selected Lewis acid, such as $\text{BF}_3 \cdot \text{OEt}_2$, $\text{BF}_3 \cdot \text{THF}$, aluminum chloride, zinc chloride, iron chloride, and the like, preferably, $\text{BF}_3 \cdot \text{THF}$ or aluminum chloride, more preferably aluminum chloride; wherein the Lewis acid is preferably present in an amount in the range of from about 0.5 to about 10.0 molar equivalents, or
20 any range therein, more preferably, in an amount in the range of from about 0.5 to about 2.5 molar equivalents, most preferably about 0.8 molar equivalents;

in the presence of a suitably selected silane reagent such as triisopropylsilane, triethylsilane, tetramethyldisiloxane and the like, preferably triethylsilane or tetramethyldisiloxane, more preferably tetramethyldisiloxane;
25 wherein the silane reagent is preferably present in an amount in the range of from about 1.0 to about 10.0 molar equivalents, or any range therein, more preferably, in an amount in the range of from about 1.0 to about 6.0 molar equivalents, or any range therein, most preferably about 1.0 molar equivalent; wherein, in an embodiment of the present invention, the ratio of the aluminum
30 chloride to the tetramethyldisiloxane is about 1 : 1.25;

in an organic solvent or mixture thereof such as DCM, DCE, acetonitrile, toluene, and the like, or in a mixture of said organic solvents, preferably in

acetonitrile; preferably at a temperature in the range of from about 0°C to about reflux, or any range therein, more preferably at about 45°C; to yield the corresponding compound of formula (XIV-K).

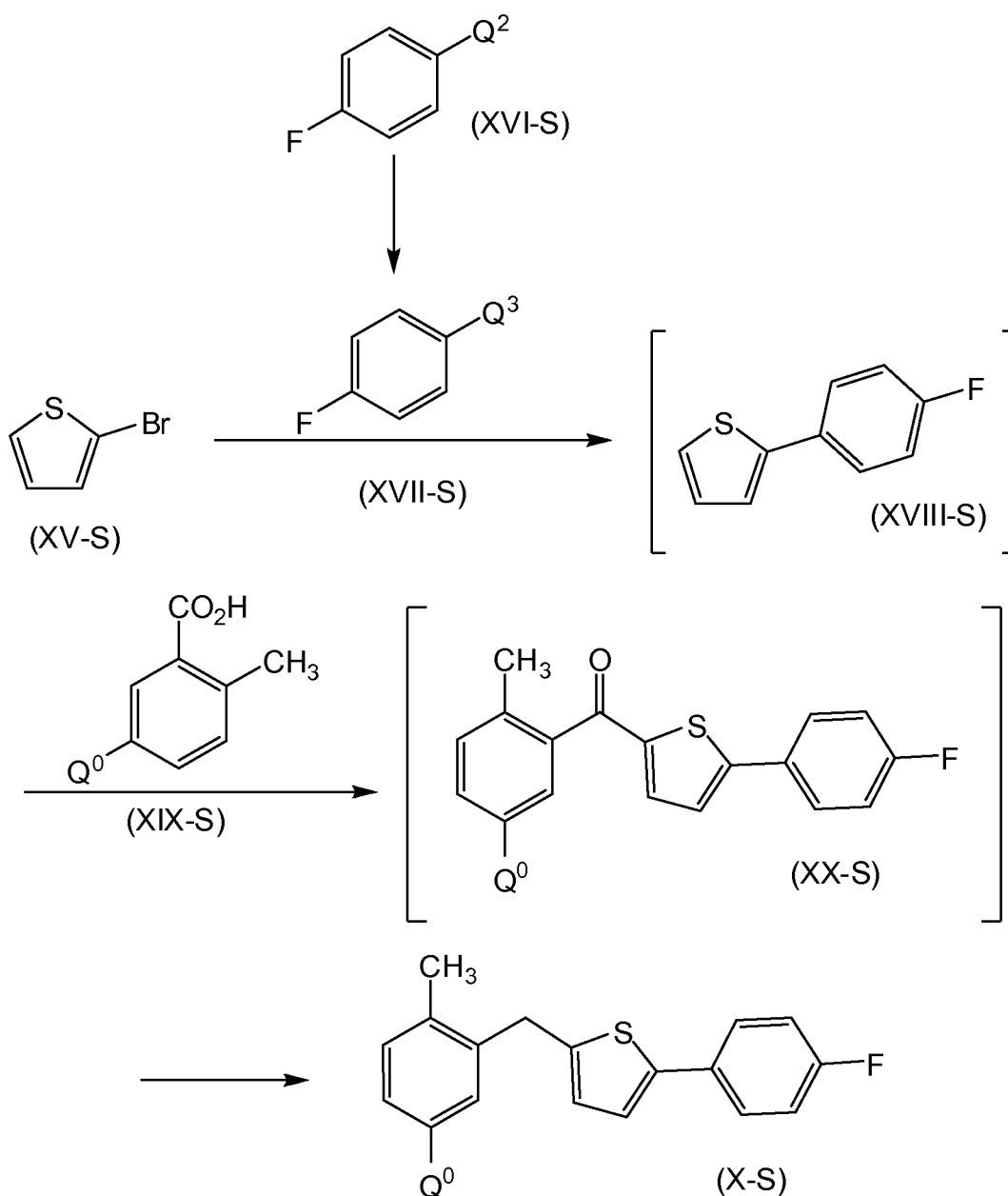
5 The compound of formula (XIV-K) is preferably slurried or dissolved in a solvent, more preferably slurried; and then filtered, preferably filtered at an elevated temperature, to remove impurities and / or byproducts.

The compound of formula (XIV-K) is de-protected according to known methods. For example, the compound of formula (XIV-K) is reacted with a suitably selected base such as LiOH, NaOH, NaOCH₃, and the like, preferably
10 NaOCH₃; wherein the base is preferably present in an amount in the range of from about 0.1 to about 2.0 molar equivalent, or any range therein, more preferably from about 0.5 to about 1.5 molar equivalents, or any range therein, most preferably about 1.0 molar equivalents; in an organic solvent or mixture thereof, such as methanol, ethanol, THF, and the like, preferably in methanol;
15 preferably at about room temperature; to yield the corresponding compound of formula (I-K).

One skilled in the art will further recognize that, depending on the particular protecting group, Z, other reagents may be used in the de-protection step including, but not limited to, Pd/C, Pd(OH)₂, PdCl₂, Pd(OAc)₂/Et₃SiH, and
20 RaNi. These reagents can be employed using various solvent systems and/or additional acid or base combinations known to one of ordinary skill.

The compound of formula (I-K) is preferably isolated and/or recrystallized, according to known methods.

In an embodiment, the present invention is directed to processes for the
25 preparation of the compound of formula (X-S) as outlined in more detail in Scheme 4, below.



Scheme 4

- 5 Accordingly, a compound of formula (XV-S), also known as 2-bromothiophene, a known compound or compound prepared by known methods, is reacted with a compound of formula (XVII-S), wherein Q^3 is –
 $B(OH)_2$, a known compound or compound prepared by known methods, under Suzuki coupling conditions, to yield the corresponding compound of formula
 10 (XVIII-S), also known as 2-(4-fluorophenyl)thiophene. More particularly, the compound of formula (XV-S) is reacted with the compound of formula (XVII-S), wherein Q^3 is – $B(OH)_2$; wherein the compound of formula (XVII-S) is preferably present in an amount in the range of from about 0.5 to about 2.0 molar

equivalents, more preferably in an amount in the range of from about 0.9 to about 1.1 molar equivalents;

in the presence of a suitably selected palladium catalyst as $\text{Pd}(\text{PPh}_3)_4$, $\text{Pd}(\text{OAc})_2$, $\text{PdCl}_2(\text{PPh}_3)_2$, and the like; in the presence of a suitably selected
5 base such as Na_2CO_3 , K_3PO_4 , and the like; in a suitably selected organic solvent such as DME and the like; preferably, at a temperature in the range of from about 60°C to about 85°C; to yield the corresponding compound of formula (XVIII-S).

Alternatively, a compound of formula (XVI-S), wherein Q^2 is bromo,
10 chloro, iodo, and the like, preferably bromo; is reacted with a suitably selected magnesium reagent such as Mg, isopropyl MgCl, isopropyl $\text{MgCl}\cdot\text{LiCl}$, sec-butyl $\text{MgCl}\cdot\text{Li}$, di-(sec-butyl)Mg, tri-(n-butyl)MgLi, and the like; in a suitably selected organic solvent such as THF, 2-methyl-THF, dibutyl ether, diethyl ether, and the like; to yield the corresponding Grignard derivative, a compound
15 of formula (XVII-S), wherein Q^3 is the corresponding Grignard species, more particularly, the corresponding MgBr, MgCl, MgI, or corresponding LiCl adduct ($\text{MgBr}\cdot\text{LiCl}$, $\text{MgCl}\cdot\text{LiCl}$, $\text{MgI}\cdot\text{LiCl}$).

The compound of formula (XVII-S) is then reacted with the compound of formula (XV-S), also known as 2-bromothiophene, a known compound or
20 compound prepared by known methods, wherein the compound of formula (XVII-S) is preferably present in an amount in the range of from about 0.5 to about 2.0 molar equivalents, more preferably in an amount in the range of from about 0.9 to about 1.2 molar equivalents;

in the presence of a suitably selected Ni or Pd catalyst such as
25 $\text{NiCl}_2(\text{dppe})$, $\text{NiCl}_2(\text{dppp})$, $\text{NiCl}_2(\text{dppf})$, $\text{Ni}(\text{OAc})_2/\text{dppe}$, $\text{Pd}(\text{OAc})_2/\text{dppp}$, and the like; in a suitably selected organic solvent such as 2-methyl-THF, THF, dibutylether, diethylether, and the like; preferably at a temperature in the range of from about 0°C to about 60°C; to yield the corresponding compound of formula (XVIII-S), also known as 2-(4-fluorophenyl)thiophene. Preferably, the
30 compound of formula (XVIII-S) is not isolated.

In an embodiment of the present invention, the compound of formula (XVII-S) Q^3 is MgBr, MgCl, MgI, or the corresponding LiCl adduct (more particularly $\text{MgBr}\cdot\text{LiCl}$, $\text{MgCl}\cdot\text{LiCl}$ or $\text{MgI}\cdot\text{LiCl}$), is reacted with the compound of

formula (XV-S), also known as 2-bromothiophene; wherein the compound of formula (XVII-S) is present in an amount in the range of from about 0.8 to about 3.0 molar equivalent, preferably in an amount in the range of from about 1.0 to about 2.0 molar equivalents, more preferably in an amount in the range of from about 1.05 to about 1.2 molar equivalents;

in the presence of a suitably selected Pd or Ni catalyst, for example Pd(OAc)₂, palladium(II) pivalate, tetrakis(triphenylphosphine)palladium(0), bis(acetonitrile)dichloropalladium(II), dichlorobis(triphenylphosphine)palladium(II), [1,1'-bis(diphenylphosphino)ferrocene]dichloropalladium(II) complex with dichloromethane, tris(dibenzylideneacetone)dipalladium(0) – chloroform adduct, palladium(II) chloride, NiCl₂(dppe), NiCl₂(dppp), NiCl₂(dppf), Ni(OAc)₂/dppe, NiCl₂(PPh₃)₂, Ni(1,10-phenanthroline)₂, NiCl₂(1,10-phenanthroline), and Ni(COD)₂; wherein the Pd(OAc)₂ is preferably present in an amount in the range of from about 0.0001 mol% to about 10 mol% (based on the amount of the compound of formula (XV-S)), more preferably in an amount in the range of from about 0.001 mol% to about 1 mol%, more preferably, in an amount in the range of from about 0.01 mol% to about 0.1 mol%;

optionally in the presence of a suitably selected ligand such as trimethylphosphine, triphenylphosphine, tricyclohexylphosphine, tri(*o*-tolyl)phosphine, 2-(dicyclohexylphosphino)-2',4',6'-tri-*i*-propyl-1,1'-biphenyl (XPhos), 2-(dicyclohexylphosphino)-2'-(*N,N*-dimethylamino)biphenyl, 2-dicyclohexylphosphino-2',6'-di-*i*-propoxy-1,1'-biphenyl, 2-dicyclohexylphosphino-2',6'-dimethoxy-1,1'-biphenyl, butyl-di-1-adamantylphosphine, 2-(di-*t*-butylphosphino)biphenyl, 2-(dicyclohexylphosphino)biphenyl, (R)-(-)-1-[(S)-2-(diphenylphosphino)ferrocenyl]ethyl-dicyclohexylphosphine, 1,2-bis(diphenylphosphino)benzene (dppbenzene), 2,2'-bis(diphenylphosphino)-1,1'-binaphthyl (BINAP), bis(2-diphenylphosphinophenyl)ether (DPEphos), 4,5-bis(diphenylphosphino)-9,9-dimethylxanthene (Xantphos), dppb, dppe, dppf, dppp or *t*-Bu₃P•HBF₄, preferably dppf, dppp, *t*-Bu₃P•HBF₄, Xantphos, tricyclohexylphosphine, or XPhos, more preferably dppp or Xphos; wherein the ligand is preferably present in an amount in the range of from about 0.0001 mol% to about 10 mol% (based on the amount of the compound of formula

(XV-S)), more preferably in an amount in the range of from about 0.001 mol% to about 1 mol%, more preferably, in an amount in the range of from about 0.01 mol% to about 0.1 mol%;

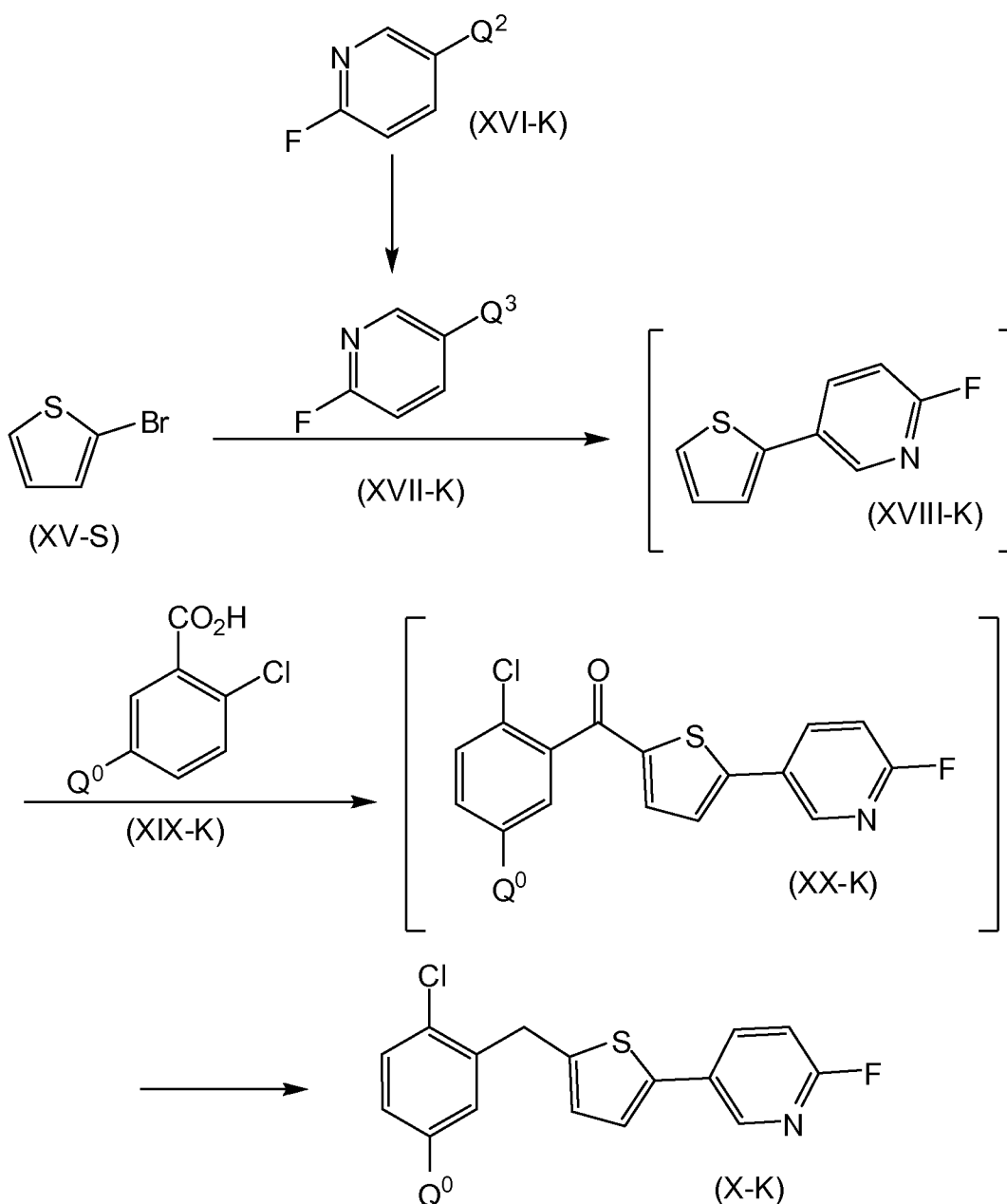
in a suitably selected solvent such as THF, dimethoxyethane, diethyl
5 ether, diisopropyl ether, cyclopentyl methyl ether, tert-butyl methyl ether, dioxane, xylene, and toluene; at lower, ambient, or elevated temperature, preferably at a temperature in the range of from about -20°C to about 150°C, more preferably at a temperature in the range of from about 30°C to about 80°C, more preferably at a temperature in the range of from about 40°C to
10 about 60°C; to yield the corresponding compound of formula (XVIII-S).

Preferably, the compound of formula (XVII-S) is added slowly, for example, at a rate where the TOF is below 12000, preferably below 2000, to a mixture of the compound of formula (XV-S), catalyst and ligand in a suitably selected solvent.

15 The compound of formula (XVIII-S) is reacted with a compound of formula (XIX-S), wherein Q^0 is bromo or iodo, preferably iodo, a known compound or compound prepared by known methods, wherein the compound of formula (XVIII-S) is preferably present in an amount in the range of from about 0.5 to about 2.0 molar equivalents, more preferably in an amount in the
20 range of from about 0.9 to about 1.1 molar equivalents; in a suitably selected solvent such as dichloromethane, chloroform, and the like; to yield the corresponding compound of formula (XX-S). Preferably, the compound of formula (XX-S) is not isolated.

The compound of formula (XX-S) is reacted with a suitably selected
25 reducing agent such as Et_3SiH , tetramethyldisiloxane, $NaBH_4$, and the like; in the presence of a Lewis Acid such as $BF_3 \cdot Et_2O$, $BF_3 \cdot THF$, $AlCl_3$, $ZnCl_2$, $FeCl_3$, and the like; in a suitably selected solvent such as dichloromethane, chloroform, acetonitrile, and the like, or mixture thereof; to yield the corresponding compound of formula (X-S).

30 In another embodiment, the present invention is directed to processes for the preparation of the compound of formula (X-K) as outlined in more detail in Scheme 5, below.



Scheme 5

- 5 Accordingly, a compound of formula (XV-S), also known as 2-bromothiophene, a known compound or compound prepared by known methods, is reacted with a compound of formula (XVII-K), wherein Q^3 is –
- 10 $B(OH)_2$, a known compound or compound prepared by known methods, under Suzuki coupling conditions, to yield the corresponding compound of formula (XVIII-K), also known as 2-(4-fluorophenyl)thiophene. More particularly, the compound of formula (XV-S) is reacted with the compound of formula (XVII-K), wherein Q^3 is $-B(OH)_2$; wherein the compound of formula (XVII-K) is preferably

present in an amount in the range of from about 0.5 to about 2.0 molar equivalents, more preferably in an amount in the range of from about 0.9 to about 1.1 molar equivalents;

in the presence of a suitably selected palladium catalyst as $\text{Pd}(\text{PPh}_3)_4$,
5 $\text{Pd}(\text{OAc})_2$, $\text{PdCl}_2(\text{PPh}_3)_2$, and the like; in the presence of a suitably selected base such as Na_2CO_3 , K_3PO_4 , and the like; in a suitably selected organic solvent such as DME and the like; preferably, at a temperature in the range of from about 60°C to about 85°C; to yield the corresponding compound of formula (XVIII-K).

10 Alternatively, a compound of formula (XVI-K), wherein Q^2 is bromo, chloro, iodo, and the like, preferably bromo; is reacted with a suitably selected magnesium reagent such as Mg, isopropyl MgCl, isopropyl $\text{MgCl}\cdot\text{LiCl}$, sec-butyl $\text{MgCl}\cdot\text{Li}$, di-(sec-butyl)Mg, tri-(n-butyl)MgLi, and the like; in a suitably selected organic solvent such as THF, 2-methyl-THF, dibutyl ether, diethyl
15 ether, and the like; to yield the corresponding Grignard derivative, a compound of formula (XVII-K), wherein Q^3 is the corresponding Grignard species, more particularly, the corresponding MgBr, MgCl, MgI, or corresponding LiCl adduct ($\text{MgBr}\cdot\text{LiCl}$, $\text{MgCl}\cdot\text{LiCl}$, $\text{MgI}\cdot\text{LiCl}$).

The compound of formula (XVII-K) is then reacted with the compound of
20 formula (XV-S), also known as 2-bromothiophene, a known compound or compound prepared by known methods, wherein the compound of formula (XVII-K) is preferably present in an amount in the range of from about 0.5 to about 2.0 molar equivalents, more preferably in an amount in the range of from about 0.9 to about 1.2 molar equivalents;

25 in the presence of a suitably selected Ni or Pd catalyst such as $\text{NiCl}_2(\text{dppe})$, $\text{NiCl}_2(\text{dppp})$, $\text{NiCl}_2(\text{dppf})$, $\text{Ni}(\text{OAc})_2/\text{dppe}$, $\text{Pd}(\text{OAc})_2/\text{dppp}$, and the like; in a suitably selected organic solvent such as 2-methyl-THF, THF, dibutylether, diethylether, and the like; preferably at a temperature in the range of from about 0°C to about 60°C; to yield the corresponding compound of
30 formula (XVIII-K), also known as 2-fluoro-5-(thiophen-2-yl)pyridine. Preferably, the compound of formula (XVIII-K) is not isolated.

In an embodiment of the present invention, the compound of formula (XVII-K) Q^3 is MgBr, MgCl, MgI, or the corresponding LiCl adduct (more

particularly $\text{MgBr}\cdot\text{LiCl}$, $\text{MgCl}\cdot\text{LiCl}$ or $\text{MgI}\cdot\text{LiCl}$), is reacted with the compound of formula (XV-K), also known as 2-bromothiophene; wherein the compound of formula (XVII-K) is present in an amount in the range of from about 0.8 to about 3.0 molar equivalent, preferably in an amount in the range of from about 1.0 to about 2.0 molar equivalents, more preferably in an amount in the range of from about 1.05 to about 1.2 molar equivalents;

in the presence of a suitably selected Pd or Ni catalyst, for example $\text{Pd}(\text{OAc})_2$, palladium(II) pivalate, tetrakis(triphenylphosphine)palladium(0), bis(acetonitrile)dichloropalladium(II), dichlorobis(triphenylphosphine)palladium(II), [1,1'-bis(diphenylphosphino)ferrocene]dichloropalladium(II) complex with dichloromethane, tris(dibenzylideneacetone)dipalladium(0) – chloroform adduct, palladium(II) chloride, $\text{NiCl}_2(\text{dppe})$, $\text{NiCl}_2(\text{dppp})$, $\text{NiCl}_2(\text{dppf})$, $\text{Ni}(\text{OAc})_2/\text{dppe}$, $\text{NiCl}_2(\text{PPh}_3)_2$, $\text{Ni}(1,10\text{-phenanthroline})_2$, $\text{NiCl}_2(1,10\text{-phenanthroline})$, and $\text{Ni}(\text{COD})_2$; wherein the $\text{Pd}(\text{OAc})_2$ is preferably present in an amount in the range of from about 0.0001 mol% to about 10 mol% (based on the amount of the compound of formula (XV-K)), more preferably in an amount in the range of from about 0.001 mol% to about 1 mol%, more preferably, in an amount in the range of from about 0.01 mol% to about 0.1 mol%;

optionally in the presence of a suitably selected ligand such as trimethylphosphine, triphenylphosphine, tricyclohexylphosphine, tri(*o*-tolyl)phosphine, 2-(dicyclohexylphosphino)-2',4',6'-tri-*i*-propyl-1,1'-biphenyl (XPhos), 2-(dicyclohexylphosphino)-2'-(*N,N*-dimethylamino)biphenyl, 2-dicyclohexylphosphino-2',6'-di-*i*-propoxy-1,1'-biphenyl, 2-dicyclohexylphosphino-2',6'-dimethoxy-1,1'-biphenyl, butyldi-1-adamantylphosphine, 2-(di-*t*-butylphosphino)biphenyl, 2-(dicyclohexylphosphino)biphenyl, (R)-(-)-1-[(S)-2-(diphenylphosphino)ferrocenyl]ethyldicyclohexylphosphine, 1,2-bis(diphenylphosphino)benzene (dppbenzene), 2,2'-bis(diphenylphosphino)-1,1'-binaphthyl (BINAP), bis(2-diphenylphosphinophenyl)ether (DPEphos), 4,5-bis(diphenylphosphino)-9,9-dimethylxanthene (Xantphos), dppb, dppe, dppf, dppp or $\text{t-Bu}_3\text{P}\cdot\text{HBF}_4$, preferably dppf, dppp, $\text{t-Bu}_3\text{P}\cdot\text{HBF}_4$, Xantphos, tricyclohexylphosphine, or XPhos, more preferably dppp or Xphos; wherein the ligand is preferably present in an amount in the range of from about 0.0001

mol% to about 10 mol% (based on the amount of the compound of formula (XV-S)), more preferably in an amount in the range of from about 0.001 mol% to about 1 mol%, more preferably, in an amount in the range of from about 0.01 mol% to about 0.1 mol%;

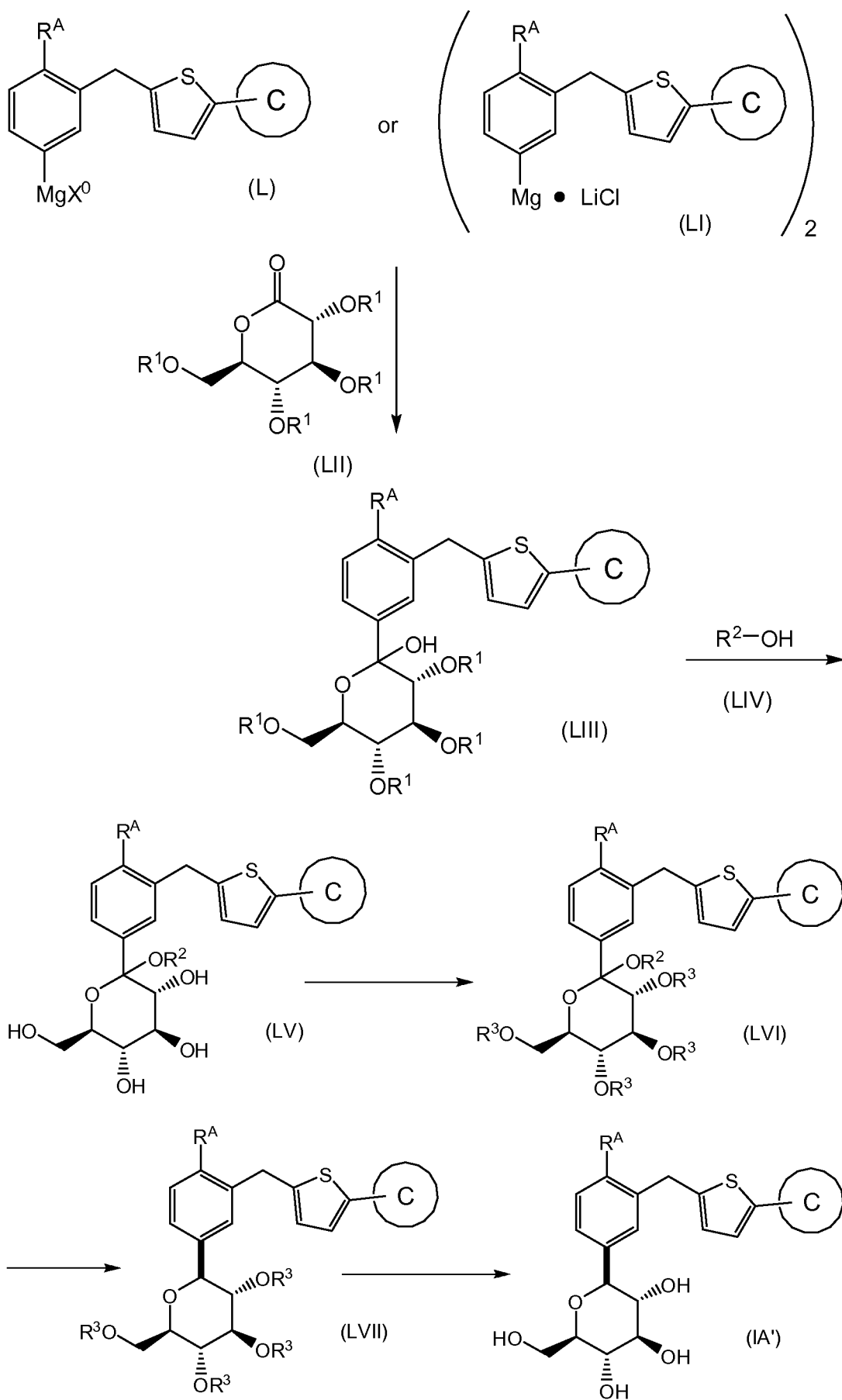
- 5 in a suitably selected solvent such as THF, dimethoxyethane, diethyl ether, diisopropyl ether, cyclopentyl methyl ether, tert-butyl methyl ether, dioxane, xylene, and toluene; at lower, ambient, or elevated temperature, preferably at a temperature in the range of from about -20°C to about 150°C, more preferably at a temperature in the range of from about 30°C to about 10 80°C, more preferably at a temperature in the range of from about 40°C to about 60°C; to yield the corresponding compound of formula (XVIII-K).

- Preferably, the compound of formula (XVII-K) is added slowly, for example, at a rate where the TOF is below 12000, preferably below 2000, to a mixture of the compound of formula (XV-K), catalyst and ligand in a suitably
15 selected solvent.

- The compound of formula (XVIII-K) is reacted with a compound of formula (XIX-K), wherein Q⁰ is bromo or iodo, preferably bromo, a known compound or compound prepared by known methods, wherein the compound of formula (XVIII-K) is preferably present in an amount in the range of from
20 about 0.5 to about 2.0 molar equivalents, more preferably in an amount in the range of from about 0.9 to about 1.1 molar equivalents; in a suitably selected solvent such as dichloromethane, chloroform, and the like; to yield the corresponding compound of formula (XX-K). Preferably, the compound of formula (XX-K) is not isolated.

- 25 The compound of formula (XX-K) is reacted with a suitably selected reducing agent such as Et₃SiH, tetramethyldisiloxane, NaBH₄, and the like; in the presence of a Lewis Acid such as BF₃•Et₂O, BF₃•THF, AlCl₃, ZnCl₂, FeCl₃, and the like; in a suitably selected solvent such as dichloromethane, chloroform, acetonitrile, and the like, or mixture thereof; to yield the
30 corresponding compound of formula (X-K).

 The present invention is further directed to a process for the preparation of compounds of formula (IA'), as outlined in Scheme 6, below.



Scheme 6

Accordingly, a suitably substituted compound of formula (L), wherein X^0 is selected from the group consisting of Cl, Br, I and $Cl \cdot LiCl$, preferably $Cl \cdot LiCl$, a known compound or compound prepared by known methods, or a suitably substituted compound of formula (LI), a known compound or compound prepared by known methods, is reacted with a suitably substituted compound of formula (LII), wherein each R^1 is tri-lower alkyl silyl, such as trimethylsilyl, triethylsilyl, and the like, preferably, each R^1 is the same and is trimethylsilyl; in a suitably selected solvent (which does not affect the reaction) such as an ether (such as diethyl ether, tetrahydrofuran, dimethoxyethane, and the like), a hydrocarbon (such as n-pentane, n-hexane, c-hexane, n-heptane, n-octane, and the like), an aromatic hydrocarbon (such as benzene, toluene, and the like) or a mixture of these solvents; to yield the corresponding compound of formula (LIII). One skilled in the art will further recognize that the reaction may be carried out ambient temperature or a temperature lower than ambient temperature; although the reaction need not be carried out at extremely low temperature. The reaction may be carried out, for example, at a temperature in the range of from about $-40^\circ C$ to about $20^\circ C$, preferably in the range of from about $-20^\circ C$ to about $10^\circ C$.

The compound of formula (LIII) is reacted with a suitably substituted alcohol of formula (LIV), such as a lower-alkyl alcohol which does not disturb the reaction, such as methanol, ethanol, n-propanol, i-propanol, n-butanol, and the like, wherein R^2 is the corresponding lower alkyl, preferably R^2 is methyl, ethyl or isopropyl; in the presence of a suitably selected acid such as an inorganic acid such as, hydrochloric acid, nitric acid, sulfuric acid, and the like, or an organic acid such as, p-toluenesulfonic acid, methanesulfonic acid, and trifluoroacetic acid, and the like; neat or in a suitably selected solvent (which does not affect the reaction) such as a hydrocarbon (such as n-pentane, n-hexane, c-hexane, n-heptane, and the like), an aromatic hydrocarbon (such as benzene, toluene, and the like), an ether (such as diethyl ether, tetrahydrofuran, and the like), a halogenated hydrocarbon (such as dichloromethane, carbon tetrachloride, and the like), an ester (such as ethyl acetate, methyl acetate, and the like), a ketone (such as acetone, 2-butanone,

and the like), acetonitrile, or a mixture of these solvents; to yield the corresponding compound of formula (LV).

One skilled in the art will further recognize that the reaction may be carried out at lower, ambient, or elevated temperature. Preferably, the reaction
5 may be carried out at a temperature in the range of from about -20°C to about 40°C, more preferably in the range of from about -20°C to about 10°C.

In an embodiment of the present invention, the alcohol of formula (LIV) is methanol or ethanol, and the acid is an organic acid such as p-toluenesulfonic acid, methanesulfonic acid or trifluoroacetic acid. In another
10 embodiment of the present invention, the alcohol of formula (LIV) is used as the solvent, thereby running the reaction neat.

The compound of formula (LV) is protected according to known methods, to yield the corresponding compound of formula (LVI), wherein each R^3 is a suitably selected oxygen protecting group, preferably each R^3 is the
15 same and is acetyl. The protection may be carried out with conventional methods well known to those skilled in the art. For a general description of protecting groups and their use, see T. W. Greene et al., "Protecting Groups in Organic Synthesis", John Wiley & Sons, New York, 1999. The protection reaction may be carried out at lower, ambient, or elevated temperature.
20 Preferably, the reaction is carried out at a temperature in the range of from about -10°C to about 100°C, more preferably in the range of from about 5°C to about 35°C.

Preferably, the oxygen protecting group is selected from those conventionally used as oxygen protecting groups. Suitable examples of the
25 oxygen protecting groups include alkanoyl (such as acetyl, and the like), arylalkyl (such as benzyl, tolyl, anisyl, and the like), alkylsilyl (such as trimethylsilyl, t-butyldimethylsilyl, triethylsilyl, and the like). Further, the oxygen protecting group may form acetal or silylacetal together with adjacent hydroxyl group(s). Examples of such protecting groups include alkylidene such as
30 isopropylidene, s-butyldiene, benzylidene, or dialkylsilylene such as di-tert-butylsilylene.

The compound of formula (LVI) is reduced, according to known methods, neat or in a suitably selected solvent; to yield the corresponding

compound of formula (LVII). One skilled in the art will further recognize that the reaction may be carried out at lower, ambient, or elevated temperature.

Preferably, the reduction is carried out at a temperature in the range of from about -40°C to about 40°C, more preferably in the range of from about 0°C to about 25°C; to yield the corresponding compound of formula (LVII).

For example, the compound of formula (LVI) may be reduced by reacting with a suitably selected silane reagent such as a tri-lower alkylsilanes (such as triethylsilane, triisopropylsilane, and the like) or a polyalkyl silanes (such as poly(methylhydrosiloxane) , and the like); in the presence of a suitably selected acid, such as a suitably selected Lewis acid (such as boron trifluoride diethyl ether complex, aluminum chloride, titanium tetrachloride, and the like), or suitably selected organic acids (such as trifluoroacetic acid, trifluoromethanesulfonic acid, methanesulfonic acid, and the like); in a suitably selected solvent such as acetonitrile, dichloromethane, a mixture of acetonitrile and dichloromethane, and the like.

Alternatively, the compound of formula (LVI) may be reduced by reacting with a suitably selected borane reagent such as a suitably selected borane complex (such as borane·tetrahydrofuran, pyridine·borane, borane dimethylsulfide, t-butylamine·borane, borane·morpholine, and the like), or a suitably selected borohydride (such as sodium borohydride, sodium triacetoxyborohydride, and the like); in the presence of a suitably selected acid, such as a suitably selected Lewis acid (such as boron trifluoride diethyl ether complex, aluminum chloride, titanium tetrachloride, and the like), or suitably selected organic acids (such as trifluoroacetic acid, trifluoromethanesulfonic acid, methanesulfonic acid, and the like); neat or in a suitable solvent such as an ether such as diethyl ether, tetrahydrofuran, and the like.

Alternatively, the compound of formula (LVI) may be reduced under catalytic reduction conditions, using a suitably selected palladium catalyst such as palladium-carbon, palladium hydroxide, and the like; under a hydrogen atmosphere or in the presence of a suitably selected reducing agent (such as ammonium formate, formic acid, and the like); in a suitable selected solvent such as a carboxylic acid (such as acetic acid, and the like), an alcohol (such

as methanol, and ethanol, and the like), or an ester (such as ethyl acetate, and the like).

Preferably, the compound of formula (LVI) is reduced by reacting with a suitably selected silane reagent, more preferably triethylsilane; in the presence
5 of a suitably selected acid, more preferably a Lewis acid, more preferably, boron trifluoride etherate; in a suitably selected solvent, more preferably in acetonitrile.

The compound of formula (LVI) is de-protected according to known methods, to yield the corresponding compound of formula (IA'). More
10 particularly, the compound of formula (LVI) is reacted to remove the oxygen protecting groups, by reduction, hydrolysis, acid treatment, or fluoride treatment. One skilled in the art will recognize that the deprotection reaction can be carried out at lower, ambient, or elevated temperature. Preferably, the de-protection reaction is carried out at a temperature in the range of from about
15 -20°C to about 150°C , more preferably in the range of from about 20°C to about 50°C .

In an example, the compound of formula (LVI) is de-protected by reacting with a suitably selected base; such as an alkali metal hydroxides (such as sodium hydroxide, potassium hydroxide, lithium hydroxide, and the like), or
20 an alkali metal alkoxide (such as sodium methoxide, sodium ethoxide, and the like); in a suitably selected solvent such as an ether (such as tetrahydrofuran, dioxane, and the like), alcohol (such as methanol, ethanol, and the like), water, or a mixture of these solvents.

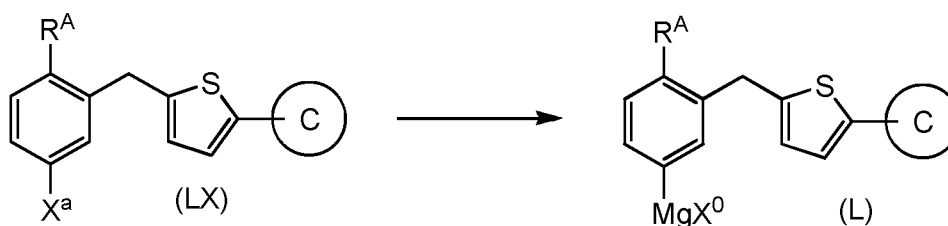
In another example, the compound of formula (LVI) is de-protected by
25 reacting with a suitably selected acid such as hydrochloric acid, p-toluenesulfonic acid, methanesulfonic acid, trifluoroacetic acid, and the like; in a suitably selected solvent such as an alcohol such as methanol, ethanol, and the like.

In another example, the compound of formula (LVI) is de-protected by
30 reacting with a suitably selected fluoride reagent such as hydrogen fluoride, hydrogen fluoride-pyridine, tetrabutylammonium fluoride, and the like; in a suitably selected solvent such as acetic acid, an alcohol such as methanol, or ethanol, acetonitrile, or an ether such as tetrahydrofuran.

In an embodiment of the present invention, the R^3 protecting groups on the compound of formula (LVI) are each benzyl. Wherein the compound of formula (LVI), the protecting groups are each benzyl, the compound of formula (LVI) is de-protected by (a) catalytic reduction using a suitably selected metal catalyst (such as palladium-carbon, palladium hydroxide, platinum oxide, rhodium-carbon, and the like) under a hydrogen atmosphere in a suitably selected solvent (such as acetic acid methanol, ethanol, ethyl acetate, and the like); (b) reacting with a suitably selected de-alkylating agent such as boron tribromide, boron trichloride, boron trichloride • dimethylsulfide complex, or iodotrimethylsilane in a suitably selected solvent (such as acetonitrile, dichloromethane, and the like); or by (3) reacting with a suitably selected lower alkylthiol such as ethanethiol in the presence of a suitably selected Lewis acid (such as boron trifluoride diethyl ether complex, and the like) in a suitably selected solvent (such as dichloromethane, and the like).

In an embodiment of the present invention, R^1 is trimethylsilyl, R^2 is methyl, ethyl or isopropyl, and R^3 is acetyl.

Compounds of formula (L) are known compounds or compounds prepared according to known methods. In an example, the compounds of formula (L) may be prepared as outlined in Scheme 7 below.



Scheme 7

Accordingly, a suitably substituted compound of formula (LX), wherein X^a is bromo or iodo, a known compound or compound prepared by known methods, is reacted with a suitably selected alkylmagnesium halide, such as an alkylmagnesium chloride such as methylmagnesium chloride, i-propylmagnesium chloride, s-butylmagnesium chloride, and the like; an alkylmagnesium bromide such as methylmagnesium bromide, i-propylmagnesium bromide, s-butylmagnesium bromide, and the like ; or an

alkylmagnesium iodide such as methylmagnesium chloride, i-propylmagnesium chloride, s-butylmagnesium chloride, and the like;

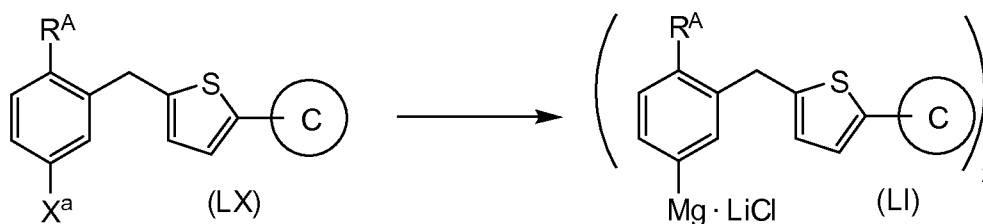
or with a suitably selected alkylmagnesium chloride / lithium chloride reagent such as i-propylmagnesium chloride / lithium chloride, s-

5 butylmagnesium chloride / lithium chloride, and the like; wherein the i-propylmagnesium chloride / lithium chloride is used for the preparation of the compounds of formula (L) wherein X^0 is $Cl \cdot LiCl$; wherein the i-propylmagnesium chloride / lithium chloride is preferably present in an amount in the range of from about 0.95 to about 1.6 molar equivalent, more preferably
10 in an amount in the range of from about 1.05 to about 1.10 molar equivalent;

in a suitably selected solvent (which does not disturb the reaction) such as a suitably selected ether such as tetrahydrofuran, diethyl ether, and the like, to yield the corresponding compound of formula (L).

One skilled in the art will recognize that the compound of formula (LX)
15 may be reacted to yield the corresponding compound of formula (L) at lower, ambient, or elevated temperature. Preferably, the reaction is carried out at a temperature in the range of from about $-20^\circ C$ to about $40^\circ C$, preferably in the range of from about $-10^\circ C$ to about $10^\circ C$.

Compounds of formula (LI) are known compounds or compounds
20 prepared according to known methods. In an example, the compounds of formula (LI) may be prepared as outlined in Scheme 8, below.

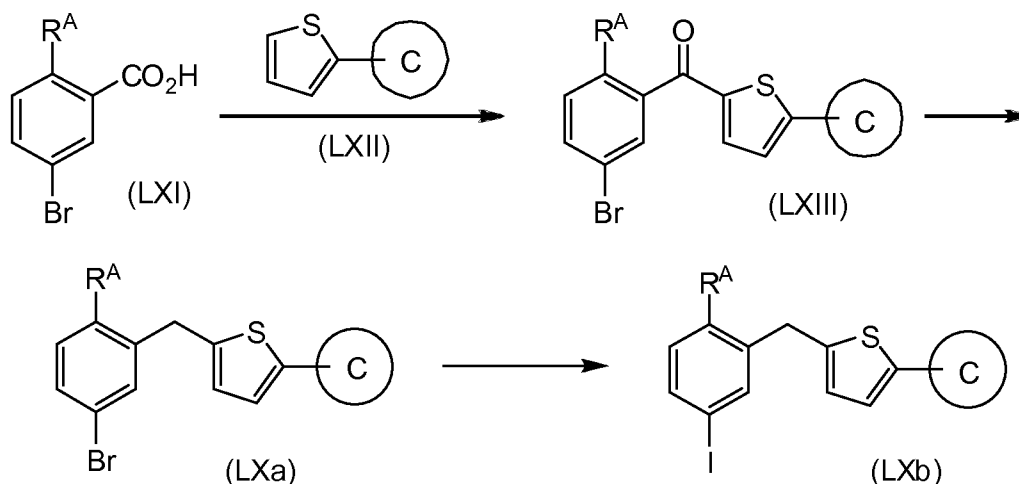


Scheme 8

Accordingly, a suitably substituted compound of formula (LX), wherein
25 X^a is bromo or iodo, a known compound or compound prepared by known methods, is reacted with a suitably selected dialkylmagnesium / lithium chloride such as di(i-propyl)magnesium chloride / lithium chloride, di(s-butyl)magnesium chloride / lithium chloride, and the like; in a suitably selected solvent;

One skilled in the art will recognize that compounds of formula (L) and compounds of formula (LI), prepared as described above may be used without further purification.

- 5 Compounds of formula (LX) are known compounds or compounds prepared according to known methods. In an example, the compounds of formula (LX) may be prepared as outlined in Scheme 9, below.



Scheme 9

- 10 Accordingly, a suitably substituted compound of formula (LXI), a known compound or compound prepared by known methods, is reacted with a suitably substituted compound of formula (LXII), a known compound or compound prepared by known methods, under acylating conditions, to yield the corresponding compound of formula (LXIII).

- 15 In an embodiment, the compound of formula (LXI) is reacted with a suitably selected halogenating reagent such as thionyl chloride, oxalyl chloride, and the like; optionally in the presence of a catalytic amount of a suitably selected activator (such as dimethylformamide, and the like); neat or in a suitably selected solvent such as a suitably selected halogenated hydrocarbon
 20 such as dichloromethane, chlorobenzene, carbon tetrachloride, and the like; at lower, ambient, or elevated temperature, for example, at a temperature in the range of from about $0^{\circ}C$ to about $50^{\circ}C$; followed by reaction with the compound of formula (LXIII).

- 25 In another embodiment, the compound of formula (LXI) is reacted with a suitably substituted compound of formula (LXII); in the presence of a suitably

selected Lewis acid such as AlCl_3 , TiCl_4 , FeCl_3 , and the like, according to known Friedel-Crafts acylation methods; in a suitably selected solvent; such as a hydrocarbon (such as n-pentane, n-hexane, c-hexane, n-heptane, and the like), an ethers (such as diethyl ether, tetrahydrofuran, and the like), a
5 halogenated hydrocarbon (such as dichloromethane, carbon tetrachloride, and the like), an esters (such as ethyl acetate, methyl acetate, and the like) or a mixture of these solvents; at lower, ambient, or elevated temperature, preferably at a temperature of from about 0°C to about 50°C .

The compound of formula (LXIII) reduced by reacting with a suitably
10 selected reducing agent; according to known methods, to yield the corresponding compound of formula (LXa).

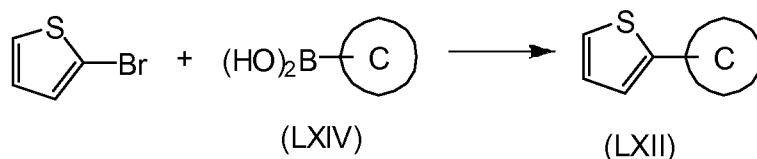
The compound of formula (LXIII) may be reduced by reacting with a suitably selected silane reagent such as a tri-lower alkylsilanes (such as triethylsilane, triisopropylsilane, and the like) or a polyalkyl silanes (such as
15 poly(methylhydrosiloxane) , and the like); in the presence of a suitably selected acid, such as a suitably selected Lewis acid (such as boron trifluoride diethyl ether complex, aluminum chloride, titanium tetrachloride, and the like), or suitably selected organic acids (such as trifluoroacetic acid, trifluoromethanesulfonic acid, methanesulfonic acid, and the like); in a suitably
20 selected solvent such as acetonitrile, dichloromethane, a mixture of acetonitrile and dichloromethane, and the like.

Alternatively, the compound of formula (LXIII) may be reduced by reacting with a suitably selected borane reagent such as a suitably selected borane complex (such as borane·tetrahydrofuran, pyridine·borane, borane
25 dimethylsulfide, and t-butylamine·borane, borane·morpholine, and the like), or a suitably selected borohydride (such as sodium borohydride, sodium triacetoxymethylborohydride, and the like); in the presence of a suitably selected acid, such as a suitably selected Lewis acid (such as boron trifluoride diethyl ether complex, aluminum chloride, titanium tetrachloride, and the like), or suitably
30 selected organic acids (such as trifluoroacetic acid, trifluoromethanesulfonic acid, methanesulfonic acid, and the like); neat or in a suitable solvent such as an ether such as diethyl ether, tetrahydrofuran, and the like.

Alternatively, the compound of formula (LXIII) may be reduced under catalytic reduction conditions, using a suitably selected palladium catalyst such as palladium-carbon, palladium hydroxide, and the like; under a hydrogen atmosphere or in the presence of a suitably selected reducing agent (such as ammonium formate, formic acid, and the like); in a suitable selected solvent such as a carboxylic acid (such as acetic acid), and the like, an alcohol (such as methanol, ethanol, and the like), or an ester (such as ethyl acetate, and the like).

The compound of formula (LXa) may be further, optionally reacted with a suitably selected iodinating reagent such as and alkali metal iodide such as sodium iodide, potassium iodide, and the like; in the presence of a catalytic amount of copper (I) iodide, in a suitably selected solvent such as a halogenated hydrocarbon such as dichloromethane, chlorobenzene, carbon tetrachloride, and the like; at ambient temperature or at an elevated temperature, for example, at a temperature in the range of from about 50°C to about 150°C; to yield the corresponding compound of formula (LXb). (See for example, Klapars, A., et al., "Copper-Catalyzed Halogen Exchange in Aryl Halides: An Aromatic Finkelstein Reaction", J. Am. Chem. Soc., (2002), 124(50), pp14844-14845).

Compounds of formula (LXII) are known compounds or compounds prepared according to known methods. In an example, the compounds of formula (LXII) may be prepared as outlined in Scheme 10, below.



Scheme 10

Accordingly, 2-bromothiophene, a known compound, is reacted with a suitably substituted compound of formula (LXIV), a known compound or compound prepared by known methods;

in the presence of a suitably selected palladium catalyst such as tetrakis(triphenyl- phosphine)palladium(0), palladium(II) acetate, bis(acetonitrile)dichloropalladium(II), dichlorobis(triphenylphosphine)palladium(II), [1,1'-

bis(diphenylphosphino)ferrocene]dichloropalladium(II) complex with dichloromethane, tris(dibenzylidene- acetone)dipalladium(0) – chloroform adduct, palladium(II) chloride, and the like; in the presence of a suitably selected base such as an alkali metal carbonate (such as potassium carbonate, sodium carbonate, sodium bicarbonate, and the like), an alkali metal phosphate (such as potassium phosphate tribasic, sodium phosphate, sodium hydrogen-phosphate, and the like), an organic base (such as *N,N*-diisopropylethylamine, and the like) or an alkali metal fluoride (such as cesium fluoride, potassium fluoride, and the like); optionally in the presence of a suitably selected ligand such as tricyclohexylphosphine, tri(*o*-tolyl)phosphine, and the like; optionally in the presence of a suitably selected additive such as copper(I) iodide, and the like;

in a suitably selected solvent such as and aromatic hydrocarbon (such as benzene, toluene, and the like), an ether (such as tetrahydrofuran, 1,2-dimethoxyethane, 1,4-dioxane, and the like), an amide (such as dimethylformamide, dimethylacetamide, 1,3-dimethyl-2- imidazolidinone, *N*-methylpyrrolidone, and the like), an alcohol (such as methanol, ethyl alcohol, 2-propanol, and the like), water, or a mixture of these solvents; at ambient temperature or at an elevated temperature, for example, at a temperature in the range of from about 25°C to about 150°C, preferably in the range of from about 80°C to about 150°C; to yield the corresponding compound of formula (LXII).

One skilled in the art will recognize that additional starting compounds and / or reagents are commercially available or may be easily prepared according to conventional methods well known to those skilled in the art.

The present invention further comprises pharmaceutical compositions containing a compound prepared according to any of the processes described herein with a pharmaceutically acceptable carrier. Pharmaceutical compositions containing one or more of the compounds of the invention described herein as the active ingredient can be prepared by intimately mixing the compound or compounds with a pharmaceutical carrier according to conventional pharmaceutical compounding techniques. The carrier may take a wide variety of forms depending upon the desired route of administration (e.g., oral, parenteral). Thus for liquid oral preparations such as suspensions, elixirs

and solutions, suitable carriers and additives include water, glycols, oils, alcohols, flavoring agents, preservatives, stabilizers, coloring agents and the like; for solid oral preparations, such as powders, capsules and tablets, suitable carriers and additives include starches, sugars, diluents, granulating agents, lubricants, binders, disintegrating agents and the like. Solid oral preparations may also be coated with substances such as sugars or be enteric-coated so as to modulate major site of absorption. For parenteral administration, the carrier will usually consist of sterile water and other ingredients may be added to increase solubility or preservation. Injectable suspensions or solutions may also be prepared utilizing aqueous carriers along with appropriate additives.

To prepare the pharmaceutical compositions of this invention, one or more compounds of the present invention as the active ingredient is intimately admixed with a pharmaceutical carrier according to conventional pharmaceutical compounding techniques, which carrier may take a wide variety of forms depending of the form of preparation desired for administration, e.g., oral or parenteral such as intramuscular. In preparing the compositions in oral dosage form, any of the usual pharmaceutical media may be employed. Thus, for liquid oral preparations, such as for example, suspensions, elixirs and solutions, suitable carriers and additives include water, glycols, oils, alcohols, flavoring agents, preservatives, coloring agents and the like; for solid oral preparations such as, for example, powders, capsules, caplets, gelcaps and tablets, suitable carriers and additives include starches, sugars, diluents, granulating agents, lubricants, binders, disintegrating agents and the like. Because of their ease in administration, tablets and capsules represent the most advantageous oral dosage unit form, in which case solid pharmaceutical carriers are obviously employed. If desired, tablets may be sugar coated or enteric coated by standard techniques. For parenterals, the carrier will usually comprise sterile water, through other ingredients, for example, for purposes such as aiding solubility or for preservation, may be included. Injectable suspensions may also be prepared, in which case appropriate liquid carriers, suspending agents and the like may be employed. The pharmaceutical compositions herein will contain, per dosage unit, e.g., tablet, capsule, powder, injection, teaspoonful and the like, an amount of the active ingredient

necessary to deliver an effective dose as described above. The pharmaceutical compositions herein may contain, per unit dosage unit, e.g., tablet, capsule, powder, injection, suppository, teaspoonful and the like, of from about 0.01 to about 1000 mg or any amount or range therein, and may be
5 given at a dosage of from about 0.01 to about 300 mg/kg/day, or any amount or range therein, preferably from about 0.1 to about 50 mg/kg/day, or any amount or range therein. The dosages, however, may be varied depending upon the requirement of the patients, the severity of the condition being treated and the compound being employed. The use of either daily administration or
10 post-periodic dosing may be employed.

Preferably these compositions are in unit dosage forms from such as tablets, pills, capsules, powders, granules, sterile parenteral solutions or suspensions, metered aerosol or liquid sprays, drops, ampoules, autoinjector devices or suppositories; for oral parenteral, intranasal, sublingual or rectal
15 administration, or for administration by inhalation or insufflation. Alternatively, the composition may be presented in a form suitable for once-weekly or once-monthly administration; for example, an insoluble salt of the active compound, such as the decanoate salt, may be adapted to provide a depot preparation for intramuscular injection. For preparing solid compositions such as tablets, the
20 principal active ingredient is mixed with a pharmaceutical carrier, e.g. conventional tableting ingredients such as corn starch, lactose, sucrose, sorbitol, talc, stearic acid, magnesium stearate, dicalcium phosphate or gums, and other pharmaceutical diluents, e.g. water, to form a solid preformulation composition containing a homogeneous mixture of a compound of the present
25 invention, or a pharmaceutically acceptable salt thereof. When referring to these preformulation compositions as homogeneous, it is meant that the active ingredient is dispersed evenly throughout the composition so that the composition may be readily subdivided into equally effective dosage forms such as tablets, pills and capsules. This solid preformulation composition is
30 then subdivided into unit dosage forms of the type described above containing from 0.1 to about 500 mg of the active ingredient of the present invention. The tablets or pills of the novel composition can be coated or otherwise compounded to provide a dosage form affording the advantage of prolonged

action. For example, the tablet or pill can comprise an inner dosage and an outer dosage component, the latter being in the form of an envelope over the former. The two components can be separated by an enteric layer which serves to resist disintegration in the stomach and permits the inner component to pass intact into the duodenum or to be delayed in release. A variety of material can be used for such enteric layers or coatings, such materials including a number of polymeric acids with such materials as shellac, cetyl alcohol and cellulose acetate.

The liquid forms in which the novel compositions of the present invention may be incorporated for administration orally or by injection include, aqueous solutions, suitably flavoured syrups, aqueous or oil suspensions, and flavoured emulsions with edible oils such as cottonseed oil, sesame oil, coconut oil or peanut oil, as well as elixirs and similar pharmaceutical vehicles. Suitable dispersing or suspending agents for aqueous suspensions, include synthetic and natural gums such as tragacanth, acacia, alginate, dextran, sodium carboxymethylcellulose, methylcellulose, polyvinyl-pyrrolidone or gelatin.

The methods of treating described in the present invention may also be carried out using a pharmaceutical composition comprising any of the compounds as defined herein and a pharmaceutically acceptable carrier. The pharmaceutical composition may contain between about 0.01 mg and about 1000 mg of the compound, or any amount or range therein; preferably about 10 to about 500 mg, or any amount or range therein, of the compound, and may be constituted into any form suitable for the mode of administration selected. Carriers include necessary and inert pharmaceutical excipients, including, but not limited to, binders, suspending agents, lubricants, flavorants, sweeteners, preservatives, dyes, and coatings. Compositions suitable for oral administration include solid forms, such as pills, tablets, caplets, capsules (each including immediate release, timed release and sustained release formulations), granules, and powders, and liquid forms, such as solutions, syrups, elixirs, emulsions, and suspensions. Forms useful for parenteral administration include sterile solutions, emulsions and suspensions.

Advantageously, compounds of the present invention may be administered in a single daily dose, or the total daily dosage may be administered in divided

doses of two, three or four times daily. Furthermore, compounds for the present invention can be administered in intranasal form via topical use of suitable intranasal vehicles, or via transdermal skin patches well known to those of ordinary skill in that art. To be administered in the form of a transdermal delivery system, the dosage administration will, of course, be continuous rather than intermittent throughout the dosage regimen.

For instance, for oral administration in the form of a tablet or capsule, the active drug component can be combined with an oral, non-toxic pharmaceutically acceptable inert carrier such as ethanol, glycerol, water and the like. Moreover, when desired or necessary, suitable binders; lubricants, disintegrating agents and coloring agents can also be incorporated into the mixture. Suitable binders include, without limitation, starch, gelatin, natural sugars such as glucose or beta-lactose, corn sweeteners, natural and synthetic gums such as acacia, tragacanth or sodium oleate, sodium stearate, magnesium stearate, sodium benzoate, sodium acetate, sodium chloride and the like. Disintegrators include, without limitation, starch, methyl cellulose, agar, bentonite, xanthan gum and the like.

The liquid forms in suitably flavored suspending or dispersing agents such as the synthetic and natural gums, for example, tragacanth, acacia, methyl-cellulose and the like. For parenteral administration, sterile suspensions and solutions are desired. Isotonic preparations which generally contain suitable preservatives are employed when intravenous administration is desired.

To prepare a pharmaceutical composition of the present invention, a compound prepared according to any of the processes described herein as the active ingredient is intimately admixed with a pharmaceutical carrier according to conventional pharmaceutical compounding techniques, which carrier may take a wide variety of forms depending of the form of preparation desired for administration (e.g. oral or parenteral). Suitable pharmaceutically acceptable carriers are well known in the art. Descriptions of some of these pharmaceutically acceptable carriers may be found in The Handbook of Pharmaceutical Excipients, published by the American Pharmaceutical Association and the Pharmaceutical Society of Great Britain.

Methods of formulating pharmaceutical compositions have been described in numerous publications such as Pharmaceutical Dosage Forms:

Tablets, Second Edition, Revised and Expanded, Volumes 1-3, edited by Lieberman et al; Pharmaceutical Dosage Forms: Parenteral Medications, Volumes 1-2, edited by Avis et al; and Pharmaceutical Dosage Forms: Disperse Systems, Volumes 1-2, edited by Lieberman et al; published by

5 Marcel Dekker, Inc.

Compounds of this invention may be administered in any of the foregoing compositions and according to dosage regimens established in the art whenever treatment of disorders as described herein is required.

10 Optimal dosages to be administered may be readily determined by those skilled in the art, and will vary with the particular compound used, the mode of administration, the strength of the preparation, the mode of administration, and the advancement of the disease condition. In addition, factors associated with the particular patient being treated, including patient age, weight, diet and time of administration, will result in the need to adjust dosages.

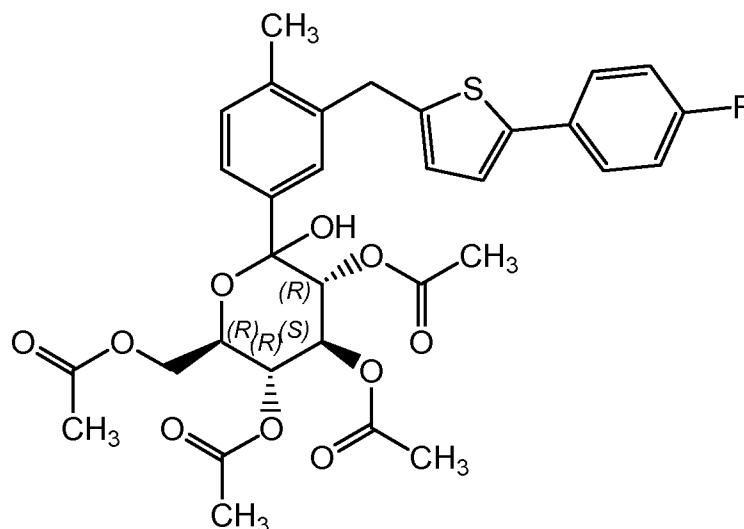
15 One skilled in the art will recognize that, both *in vivo* and *in vitro* trials using suitable, known and generally accepted cell and / or animal models are predictive of the ability of a test compound to treat or prevent a given disorder.

One skilled in the art will further recognize that human clinical trials including first-in-human, dose ranging and efficacy trials, in healthy patients
20 and / or those suffering from a given disorder, may be completed according to methods well known in the clinical and medical arts.

The following Examples are set forth to aid in the understanding of the invention, and are not intended and should not be construed to limit in any way the invention set forth in the claims which follow thereafter.

25 In the Examples which follow, some synthesis products are listed as having been isolated as a residue. It will be understood by one of ordinary skill in the art that the term "**residue**" does not limit the physical state in which the product was isolated and may include, for example, a solid, an oil, a foam, a gum, a syrup, and the like. Unless otherwise noted, the identity and / or purity
30 of the products prepared in Examples 1 through 6 was determined by HPLC.

Example 1: 3(R),4(S),5(R)-triacetox-6-{3-[5-(4-fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-6-hydroxy-tetrahydro-pyran-2(R)-ylmethyl ester acetic acid



STEP A: Preparation of Grignard Reagent

2-(4-Fluoro-phenyl)-5-(5-iodo-2-methyl-benzyl)-thiophene (122.48g, 0.3 mol) was stirred in toluene (0.75 L/mol) at ambient temperature, then cooled to
 5 -10°C. To the resulting mixture was then added, via addition funnel, under argon, over about 45 minutes at -5°C to -7°C, sec-butyl MgCl•LiCl (ca. 15% in THF; 269.70 g, 0.36 mol) and the resulting dark green solution stirred for 1 hour at between -5°C and 0°C.

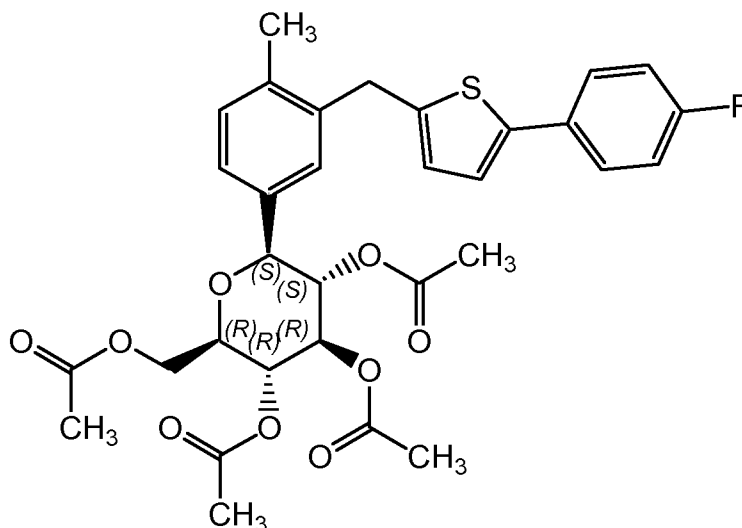
STEP B:

10 3(R),4(S),5(R)-triacetoxy-6-oxo-tetrahydro-pyran-2(R)-ylmethyl ester acetic acid (ca 50% in toluene, 0.39 mol) was diluted with THF (0.25 L/mol) and the resulting mixture cooled to -35°C. To the mixture was then added, via syringe / addition funnel, under argon, over about 1 hour at less than about -
 35°C, the solution prepared in STEP A above. After 15 minutes of stirring at -
 15 35°C, a mixture of acetic acid (23 ml) and water (225 mL) was added over about 5 minutes. The resulting mixture was then allowed to warm to 25°C. The layers of the resulting biphasic mixture were separated, and the upper organic layer was washed twice with water (100 mL). The organic layer was then concentrated by distilling off the solvent to yield a residue. To the residue
 20 was then added acetonitrile (420 mL) and the resulting mixture washed with methylcyclohexane (300 mL). The resulting mixture comprised two organic layers which separated quickly. The acetonitrile solution, containing the title

compound was then used in the next step without further purification or isolation of the title compound.

Example 2: 3(R),4(R),5(S)-triacetoxy-6(S)-{3-[5-(4-fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-tetrahydro-pyran-2(R)-ylmethyl ester acetic

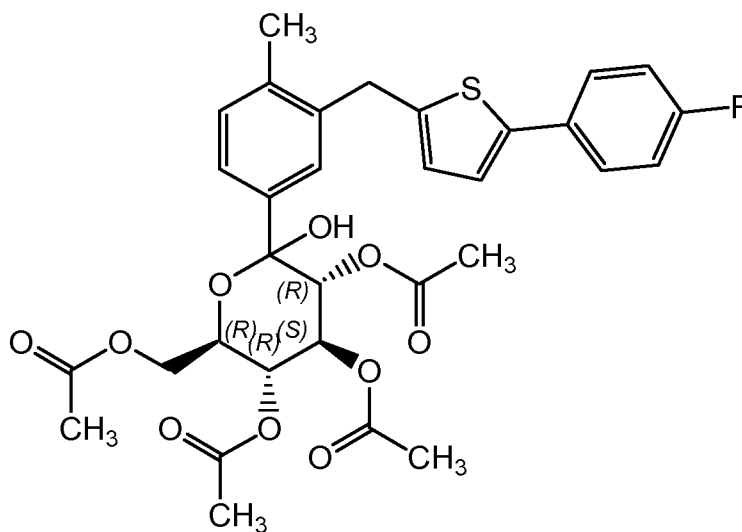
5

acid

Triethylsilane (87.2 g, 0.75 mol) was added to an acetonitrile solution containing 3(R),4(S),5(R)-triacetoxy-6-{3-[5-(4-fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-6-hydroxy-tetrahydro-pyran-2(R)-ylmethyl ester acetic acid (prepared as in Example 1 above, 0.30 mol) and the resulting brownish solution cooled to 2°C. Boron trifluoride etherate (46.84 g, 0.33 mol) was then added over about 30 minutes, via syringe, and the resulting mixture stirred in the ice-water bath for 1 hour. To the resulting mixture was then added 10% w/w aqueous Na₂CO₃ (330 ml), via addition funnel over about 20 minutes. The resulting mixture was then heated until complete dissolution was observed at about 45°C. The layers of the resulting tri-layer mixture were separated, the middle organic layer was allowed to cool to ambient temperature, with stirring for 16 hours, over which time crystallization was observed. The resulting mixture was then cooled in an ice bath to 2°C and stirred for an additional 4 hours. The precipitate was filtered, washed once with methanol (75 mL) and then a second time with methanol (30 mL). The resulting off-white precipitate was dried at 50°C, in vacuo to yield the title compound.

Example 3: 3(R),4(S),5(R)-triacetoxy-6-{3-[5-(4-fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-6-hydroxy-tetrahydro-pyran-2(R)-ylmethyl

ester acetic acid



5 **STEP A: Preparation of Grignard Reagent**

2-(4-Fluoro-phenyl)-5-(5-iodo-2-methyl-benzyl)-thiophene (204.14g, 0.5 mol) was slurried in toluene (0.3L/mol) at ambient temperature and the resulting mixture cooled to 2°C. *sec*-Butyl MgCl•LiCl (ca 15% in THF; 1.2 mol/mol-pure LR) was added via an addition funnel over 1 hour at 2-5°C. The resulting dark brown solution was then stirred at 2°C for 2 hours.

STEP B:

3(R),4(S),5(R)-triacetoxy-6-oxo-tetrahydro-pyran-2(R)-ylmethyl ester acetic acid (ca 50% in toluene, 0.65 mol) was diluted with THF (0.2 l/mol) and the resulting mixture cooled to -40°C. To the mixture was then added, via syringe over 1/2 hour at -35° to -40°C, the mixture prepared in STEP A above. The resulting mixture was then cooled to -40°C and stirred for 30 minutes. A mixture of HCl (59.8 mL) in water (100 mL) was then added, at -40°C over 10 minutes. The resulting mixture was warmed over 15 minutes to 20°C and then further diluted with water (150 mL). The resulting bi-phasic mixture was separated and toluene (100 mL) was added to the organic layer. The organic layer was then washed with water (250 mL), the layers separated and the organic layer concentrated on a rotavap, under minimum pressure of 50 mbar,

70°C to yield the title compound as a residue (which was used in the next synthesis step without further purification).

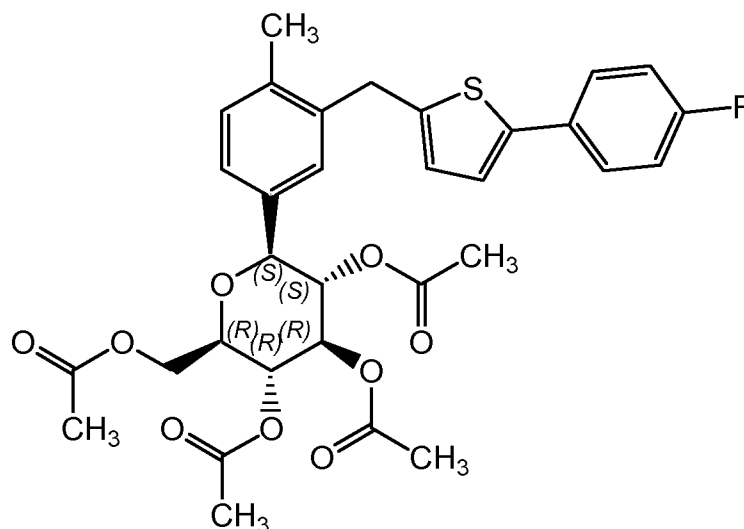
A sample of the prepared compound was dissolved in deuterated chloroform and the ¹H and ¹³C NMR spectra recorded. A Bruker

- 5 AVANCE-400 MHz NMR spectrometer equipped with a Bruker 5 mm BBO 400 MHz Z-gradient high resolution probe and running TOPSPIN 2.0 software, was used to collect 1-dimensional proton and carbon spectra.

¹H NMR (400 MHz, CHLOROFORM-*d*) δ ppm 1.82 (s, 3 H) 1.96 (s, 3 H) 2.05 (s, 3 H) 2.07 (s, 3 H) 2.31 (s, 3 H) 3.13 (br. s., 1 H) 4.11 (d, *J*=3.02 Hz, 2 H) 4.19 (dd, *J*=12.34, 2.52 Hz, 1 H) 4.31 (dd, *J*=12.34, 4.28 Hz, 1 H) 4.38 - 4.43 (m, 1 H) 5.08 (d, *J*=9.82 Hz, 1 H) 5.27 (t, *J*=9.82 Hz, 1 H) 5.59 (t, *J*=9.82 Hz, 1 H) 6.59 (d, *J*=3.53 Hz, 1 H) 6.98 - 7.05 (m, 3 H) 7.18 (d, *J*=7.81 Hz, 1 H) 7.36 (dd, *J*=7.81, 2.01 Hz, 1 H) 7.39 (d, *J*=1.76 Hz, 1 H) 7.44 - 7.48 (m, 2 H)

¹³C NMR (101 MHz, CHLOROFORM-*d*) δ ppm 19.23 (s, 1 C) 20.35 (s, 1 C) 20.59 (s, 1 C) 20.61 (s, 1 C) 20.73 (s, 1 C) 34.11 (s, 1 C) 62.24 (s, 1 C) 68.64 (s, 1 C) 68.80 (s, 1 C) 71.60 (s, 1 C) 73.59 (s, 1 C) 97.11 (s, 1 C) 115.70 (d, *J*=22.01 Hz, 2 C) 122.65 (s, 1 C) 124.12 (s, 1 C) 125.90 (s, 1 C) 126.73 (s, 1 C) 127.06 (d, *J*=8.07 Hz, 2 C) 130.66 (s, 1 C) 130.72 (s, 1 C) 137.68 (s, 1 C) 137.80 (s, 1 C) 138.08 (s, 1 C) 141.62 (s, 1 C) 142.95 (s, 1 C) 162.08 (d, *J*=246.49 Hz, 1 C) 168.96 (s, 1 C) 169.61 (s, 1 C) 170.16 (s, 1 C) 170.82 (s, 1 C)

Example 4: 3(R),4(R),5(S)-triacetoxy-6(S)-{3-[5-(4-fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-tetrahydro-pyran-2(R)-ylmethyl ester acetic acid



Triethylsilane (132.27 g, 1.14 mol) was added to an acetonitrile solution containing 3(R),4(S),5(R)-triacetoxy-6-{3-[5-(4-fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-6-hydroxy-tetrahydro-pyran-2(R)-ylmethyl ester
 5 acetic acid (prepared as in Example 3 above, 0.455 mol) and the resulting solution stirred at 22°C. Boron trifluoride-THF complex (76.39 g, 0.55 mol) was added via addition funnel over about 3 minutes to yield a homogeneous darkbrown mixture. The mixture was then warmed to 40°C, stirred strongly at 40°C for 2.5 hours, then cooled to 20°C. Methanol (910 mL) was added to the
 10 resulting mixture over 15 minutes and the mixture stirred at 20°C for 0.5 hours. Aq ammonium hydroxide (31.8 mL) was added to the resulting mixture (at ≤ 20°C, to a pH 7.2) and then stirred for 16 hours at 20°C. The resulting precipitate was filtered, washed with methanol (3 X 114 mL), and dried in vacuo at 60°C, to yield the title compound as a solid.

15 A sample of the prepared compound was dissolved in deuterated DMSO and the ¹H and ¹³C NMR spectra recorded. A Bruker AVANCE-400 MHz NMR spectrometer equipped with a Bruker 5 mm BBO CPDUL 1H/2H-13C Z-GRD high resolution probe and running XWIN-NMR 3.5.6 software, was used to collect 1-dimensional proton and carbon spectra.

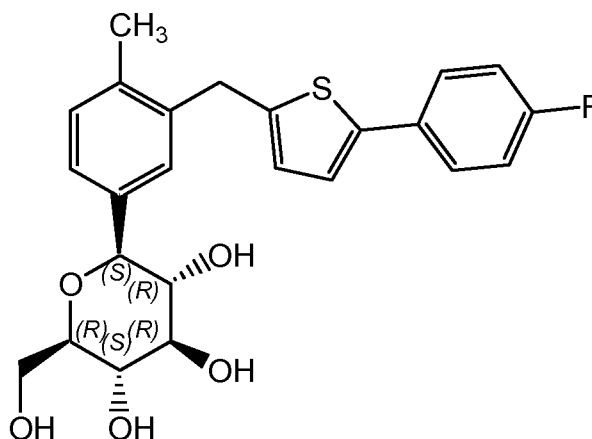
20 ¹H NMR (600 MHz, DMSO-*d*₆) δ ppm 1.72 (s, 3 H) 1.93 (s, 3 H) 1.99 (s, 3 H) 2.02 (s, 3 H) 2.26 (s, 3 H) 4.04 - 4.09 (m, 2 H) 4.10 - 4.16 (m, 3 H) 4.65 (d, *J*=9.82 Hz, 1 H) 4.98 (t, *J*=9.63 Hz, 1 H) 5.06 (t, *J*=9.63 Hz, 1 H) 5.36 (t, *J*=9.63

Hz, 1 H) 6.76 (d, $J=3.40$ Hz, 1 H) 7.17 (s, 3 H) 7.20 (t, $J=8.69$ Hz, 2 H) 7.29 (d, $J=3.78$ Hz, 1 H) 7.58 (dd, $J=8.50, 5.48$ Hz, 2 H)

^{13}C NMR (151 MHz, DMSO- d_6) δ ppm 18.81 (s, 1 C) 20.12 (s, 1 C) 20.30 (s, 1 C) 20.42 (s, 1 C) 20.52 (s, 1 C) 33.14 (s, 1 C) 62.34 (s, 1 C) 68.48 (s, 1 C) 72.37 (s, 1 C) 73.44 (s, 1 C) 74.54 (s, 1 C) 77.90 (s, 1 C) 115.91 (d, $J=20.86$ Hz, 2 C) 123.42 (s, 1 C) 125.37 (s, 1 C) 126.41 (s, 1 C) 126.89 (d, $J=8.78$ Hz, 2 C) 128.40 (s, 1 C) 130.29 (s, 1 C) 130.48 (d, $J=3.29$ Hz, 1 C) 134.76 (s, 1 C) 136.21 (s, 1 C) 137.97 (s, 1 C) 140.36 (s, 1 C) 143.32 (s, 1 C) 161.39 (d, $J=244.80$ Hz, 1 C) 168.42 (s, 1 C) 169.40 (s, 1 C) 169.62 (s, 1 C) 170.08 (s, 1 C)

Melting Point = 161.8°C

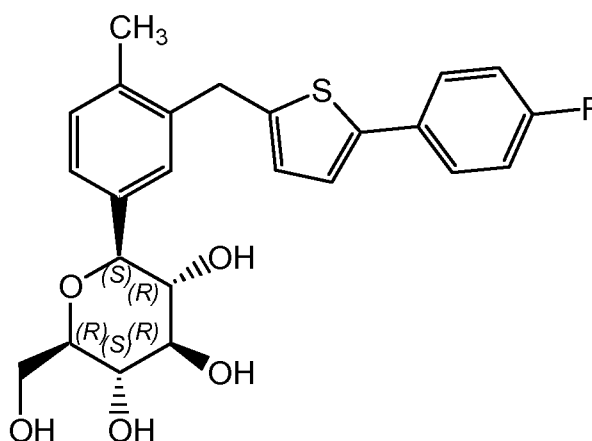
Example 5: 2(S)-{3-[5-(4-Fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-6(R)-hydroxymethyl-tetrahydro-pyran-3(R),4(R),5(S)-triol



To a 3-necked round bottom flask was added methanol (244.80 mL, 3 L/mol-pure-LR), sodium methoxide (15.31 mL, 81.60 mmol) and 3(R),4(R),5(S)-triacetoxy-6(S)-{3-[5-(4-fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-tetrahydro-pyran-2(R)-ylmethyl ester acetic acid (prepared as in for example, Example 4 above; 49.99g, 81.60 mmol) and the resulting thick homogeneous mixture stirred at 20-25°C for 1 hour. The resulting mixture was then heated to reflux temperature, about 82 mL of solvent distilled off and then cooled to 2°C over 30 minutes. To the resulting mixture was added acetic acid (4.68 mL, 81.60mmol). Water (114 mL) was then added with cooling, over about 15 minutes and the resulting mixture warmed to 22°C. The resulting mixture was seeded with previously prepared material (300 mg), then stirred at 22°C for 19

hours. Additional water (49 mL) was added over 2.5 hours (to a methanol : water ratio of 50:50), the resulting mixture was cooled to 0°C over 15 minutes, then stirred at 0°C for 2 hours. The resulting suspension was filtered, the solid washed with 50:50 mixture of methanol:water (20 mL total), then dried at 50°C, under vacuum for 18 hours, to yield the title compound as a solid.

Example 6: Recrystallization of 2(S)-{3-[5-(4-Fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-6(R)-hydroxymethyl-tetrahydro-pyran-3(R),4(R),5(S)-triol



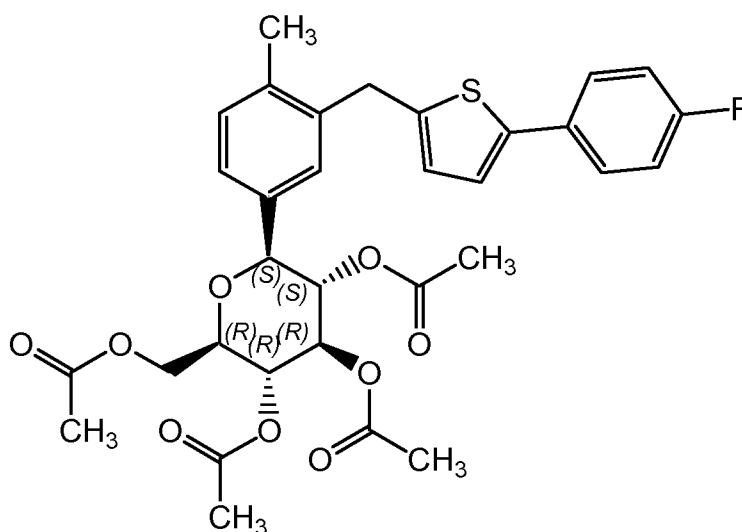
To a 3-necked round bottom flask were added 2(S)-{3-[5-(4-Fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-6(R)-hydroxymethyl-tetrahydro-pyran-3(R),4(R),5(S)-triol (25.0 g, 55.15 mmol), isopropyl acetate (also known as 1-methylethyl ester acetic acid; 110 mL) and water (1.25 mL, 69.39 mmol) and the resulting mixture heated to 65°C. To the resulting mixture was then added charcoal (1 NORIT A SUPRA[®], 0.5 g) and the mixture stirred at 60-65°C for 15 minutes. The charcoal was filtered off, then washed with isopropyl acetate (15 mL). The filtrate was cooled to 50°C, seeded with previously prepared material (0.25 g), then stirred at 50°C for 4 hours. The resulting mixture was then cooled to 0°C over 12 hours, then stirred at 0°C for 2 hours. The resulting suspension was filtered, the solid washed with isopropyl acetate, then dried at 50°C, under vacuum to yield the title compound as a solid.

A sample of the prepared compound was dissolved in deuterated DMSO and the ¹H NMR and ¹³C NMR spectra recorded. A Bruker AVANCE-600 MHz NMR spectrometer equipped with a Bruker 5 mm CPDUL 1H/2H-13C Z-GRD high resolution probe and running XWIN-NMR 3.5.6 software was used.

^1H NMR (600 MHz, $\text{DMSO}-d_6$) δ ppm 2.27 (s, 3 H) 3.14 - 3.17 (m, 1 H) 3.17 - 3.19 (m, 1 H) 3.20 - 3.24 (m, 1 H) 3.25 - 3.29 (m, 1 H) 3.42 - 3.47 (m, 1 H) 3.68 - 3.73 (m, 1 H) 3.97 (d, $J=9.44$ Hz, 1 H) 4.07 - 4.17 (m, 2 H) 4.44 (t, $J=6.04$ Hz, 1 H) 4.73 (d, $J=5.67$ Hz, 1 H) 4.93 (d, $J=4.91$ Hz, 2 H) 6.80 (d, $J=3.78$ Hz, 1 H) 7.12 (d, $J=7.55$ Hz, 1 H) 7.15 (dd, $J=7.55, 1.51$ Hz, 1 H) 7.20 (t, $J=8.69$ Hz, 2 H) 7.23 (d, $J=1.13$ Hz, 1 H) 7.28 (d, $J=3.40$ Hz, 1 H) 7.57 - 7.61 (m, 2 H)

^{13}C NMR (151 MHz, $\text{DMSO}-d_6$) δ ppm 18.81 (s, 1 C) 33.44 (s, 1 C) 61.43 (s, 1 C) 70.42 (s, 1 C) 74.67 (s, 1 C) 78.48 (s, 1 C) 81.21 (s, 1 C) 81.32 (s, 1 C) 115.88 (d, $J=21.96$ Hz, 2 C) 123.39 (s, 1 C) 126.25 (s, 1 C) 126.36 (s, 1 C) 126.95 (d, $J=7.68$ Hz, 2 C) 129.06 (s, 1 C) 129.65 (s, 1 C) 130.52 (d, $J=3.29$ Hz, 1 C) 134.93 (s, 1 C) 137.36 (s, 1 C) 138.24 (s, 1 C) 140.22 (s, 1 C) 143.63 (s, 1 C) 161.37 (d, $J=243.70$ Hz, 1 C)

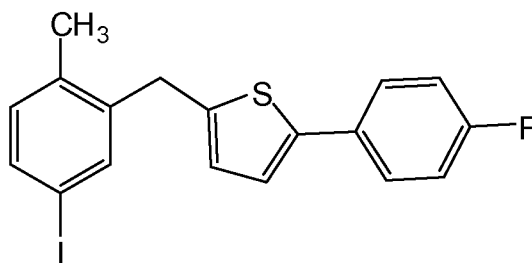
Example 7: 3(R),4(R),5(S)-triacetoxy-6(S)-{3-[5-(4-fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-tetrahydro-pyran-2(R)-ylmethyl ester acetic acid



Under a nitrogen atmosphere, acetonitrile (112.50 mL, 88.12 g) was cooled to 2°C. Aluminum trichloride (13.33 g) was added in one portion and the resulting mixture stirred for 15 min, cooling to 15°C. $((\text{CH}_3)_2\text{SiH})_2\text{O}$ (22.13 mL, 16379 g) was added in one portion at 15°C and the resulting mixture stirred for 15 min. To the mixture was then added, at 15°C over about 3 hours, 3(R),4(S),5(R)-triacetoxy-6-{3-[5-(4-fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-6-hydroxy-tetrahydro-pyran-2(R)-ylmethyl ester acetic acid (1.0

equiv. 146.46 ml (145.26 g, 54.10 %w/w in acetonitrile)). Following addition, the resulting mixture was stirred at 15°C for 15 min, then warmed to 45°C over about 30 min. 4-Methyl-2-pentanone (32.92 mL, 26.29 g) was added to the resulting mixture over about 15 min, which was then allowed to warm to 50°C, and stirred at 50°C for 1 hour. Aqueous NH₄Cl was then added via addition funnel and the resulting mixture warmed to 65°C over about 15 min, then stirred at 65°C for 15 min. The resulting layers were separated, with the colorless layer between the organic and aqueous layers kept with the upper organic layer. The organic layer was washed at 65°C with a solution of ammonium chloride (3.21 g) in water (20.00 mL), and the resulting three layers separated. The organic layer was heated to 65°C over about 15 min, cooled to 55°C over 15 min, then seeded with 3(R),4(R),5(S)-triacetoxy-6(S)-{3-[5-(4-fluoro-phenyl)-thiophen-2-ylmethyl]-4-methyl-phenyl}-tetrahydro-pyran-2(R)-ylmethyl ester acetic acid (1.15 g). The resulting mixture was stirred at 55°C for 6 hours, cooled over about 15 hours to 1°C, then stirred at 1°C for 5 hours. The resulting precipitate was filtered, washed with methanol (2X, 46.88 mL) and then dried in vacuo at 60°C to yield the title compound as a solid.

Example 8: 2-(4-Fluorophenyl)-5-(5-iodo-2-methylbenzyl)thiophene



The following reactions were carried out under an argon atmosphere.

STEP A: 4-Fluoro-phenylmagnesium bromide

2-Me-THF (80 ml, 0.1 L/mole) was added to Mg (19.44 g, 0.8 mol) and the resulting mixture was stirred slowly. 1-Bromo-4-fluoro-benzene (142.8 g, 0.816 mole) was dissolved in 2-Me-THF (200 ml, 0.25 L/mole) and 25 ml of this solution was added to the Mg mixture. The resulting mixture was heated to about 43°C, the remaining 1-bromo-4-fluorobenzene solution was added over about 40 minutes, while maintaining the mixture at reflux temperature. The addition funnel used to add the 1-bromo-4-fluorobenzene was rinsed with 2-methyl-THF (40 mL) and the rinse was added. The resulting mixture was

stirred at 90°C for 1 hour, then cooled to 20°C to yield a brown-green solution containing 4-fluoro-phenylmagnesium bromide.

STEP B: 2-(4-Fluorophenyl)thiophene

2-Bromothiophene (130.4 g, 0.8 mol) was dissolved in 2-Me-THF (240 ml, 0.3 L/mole) and the resulting mixture cooled to 2°C. NiCl₂(dppe) (2.11 g, 4.0 mmol) was added followed by addition, over about 40 min. at ≤ 30°C, of the 4-fluoro-phenylmagnesium bromide solution prepared as in STEP A above to yield a dark red solution. The solution was then stirred at 22°C for 1.5 hrs. A solution of acetic acid (91.7 ml, 1.6 mol) in water (240 ml, 0.3 L/mol) was then added and the resulting mixture stirred strongly for 15 min. The resulting layers were separated, the organic layer was washed with water (80 ml, 0.1 L/mol), then concentrated in vacuo at 75°C to yield 2-(4-fluorophenyl)thiophene as a brown oil.

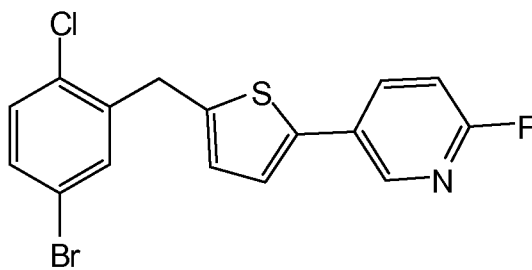
STEP C: 2-(4-fluorophenyl)-5-(5-iodo-2-methylbenzyl)thiophene

DCM (350 ml, 1 L/mol) was added to 91.7 g 5-iodo-2-methylbenzoic acid (91.7 g, 0.35 mol) and the resulting heterogeneous mixture stirred at 22°C. To the resulting mixture was then added thionyl chloride (42.5 g, 0.35 mol) via an addition funnel. The resulting mixture was warmed slowly to reflux temperature (over which time the mixture became a colorless solution and gas evolution was observed), then stirred for 1 hr, then cooled to 2°C. Aluminum chloride granules (56.0 g, 0.42 mol) were added to the resulting mixture, which was then stirred for 15 min at 2°C. A solution of 2-(4-fluorophenyl)thiophene (0.35 mol, 89.7 %w/w) in DCM (0.5 L/mol) was then added via addition funnel over 10 minutes, allowing the temperature to rise during addition to 20°C. The resulting mixture was stirred at 20°C for 2 hrs, then cooled to 2°C. Additional aluminum chloride granules (107.3 g, 0.805 mol) were added and the resulting mixture stirred for 15 min. Acetonitrile (210 ml, 0.6 L/mol) was added via addition funnel over 20 minutes at T ≤ 20°C. Tetramethyldisiloxane (131.6 g, 0.98 mol) was then added via addition funnel over 5 minutes. The resulting mixture was slowly warmed to reflux temperature (42°C), maintained at reflux for 3 hours, allowed to cool to 22°C and then stirred for 16 hrs. Water (420 ml, 1.2 L/mol) was added over 30 minutes at T ≤ 35°C and the resulting mixture stirred strongly for 15 min. The resulting layers were separated, the organic

layer washed with water (70 ml, 0.2 L/mol), then concentrated in vacuo at 50°C to yield the title compound as a residue.

The residue (62.0 g, 0.1 mol theoretically) was suspended in a mixture of ethyl acetate (40 ml) and 2-propanol (50 ml). To the resulting mixture was added charcoal (1.2g) and the resulting mixture heated to reflux, then stirred at reflux for 15 min. The resulting mixture was filtered warm over a filter aid, the filter washed with ethyl acetate (10 ml) and the combined filtrate and washes cooled to 2°C over 16 hrs, over which time spontaneous crystallization was observed. The precipitate was filtered, washed with 2-propanol (50 ml) and dried in vacuo at 60°C to yield 2-(4-fluorophenyl)-5-(5-iodo-2-methylbenzyl)thiophene as a solid.

Example 9: 5-(5-(5-bromo-2-chlorobenzyl)thiophen-2-yl)-2-fluoropyridine



STEP A: (6-fluoropyridin-3-yl)magnesium bromide

Under a nitrogen atmosphere, 5-bromo-2-fluoropyridine (8.8 g, 50 mmol) was dissolved in dry THF (50ml). To the resulting mixture was then added sec-butyl MgCl•LiCl (15% in THF, 1.5 equiv.) over about 30 min at room temperature and the resulting mixture stirred at room temperature for 2 hours.

STEP B: 2-Fluoro-5-(thiophen-2-yl)pyridine

In a separate reaction vessel, under a nitrogen atmosphere were added NiCl₂(dppp) (0.02 equiv, 0.60 g) and THF (50 ml). 2-Bromothiophene (8.1 g, 4.81 ml, 50 mmol, 1 equiv.) was added and the resulting solution stirred for 2 min. To the resulting mixture was then added the mixture prepared in STEP A above, over about 30 min at 0°C, then allowed to warm to room temperature, with stirring. To the resulting mixture was then added diethylether, then cooled to 0°C and treated with 1N HCl. The resulting mixture was extracted with diethylether (3X), the layers separated, the organic layer dried over MgSO₄, then filtered and the filtrate evaporated to yield 2-fluoro-5-(thiophen-2-yl)pyridine as a liquid residue.

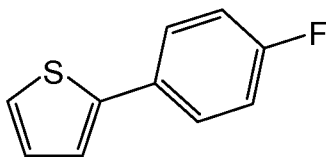
STEP C: (5-bromo-2-chlorophenyl)(5-(6-fluoropyridin-3-yl)thiophen-2-yl)methanone

Under a nitrogen atmosphere, 5-bromo-2-chlorobenzoic acid (5.26 g, 22.3 mmol) was added to a mixture of DCM (30 ml) and 1 drop DMF. To the
5 resulting mixture was then added oxalyl chloride (4.26 g, 2.93 ml, 33.5 mmol, 1.5 equiv.), which was then stirred for 2 hrs. The resulting mixture was evaporated to a residue. DCM (30 ml) was added to the residue and the mixture evaporated. This addition of DCM was repeated twice. To the
10 resulting residue was then added, dropwise, AlCl_3 (3.6 g, 1.2 equiv.) in DCM (40 ml) and the resulting mixture stirred at room temperature for 2 hrs. The reaction was then quenched with water, the resulting layers separated, and the aqueous layer extracted with DCM. The combined organic fractions were washed with K_2CO_3 , then dried over MgSO_4 , filtered and evaporated to yield (5-bromo-2-chlorophenyl)(5-(6-fluoropyridin-3-yl)thiophen-2-yl)methanone as a
15 residue.

STEP D: 5-(5-(5-bromo-2-Chlorobenzyl)thiophen-2-yl)-2-fluoropyridine

Under a nitrogen atmosphere, (5-bromo-2-chlorophenyl)(5-(6-fluoropyridin-3-yl)thiophen-2-yl)methanone (1.96 g, 4.9 mmol) was dissolved in DCM (12.5 ml). To the resulting mixture was then added acetonitrile (12.5 ml)
20 and Et_3SiH (2.29 ml, 14.3 mmol, 2.9 equiv.), resulting in the formation of a yellow suspension. The suspension was cooled to 0°C , then treated, dropwise with $\text{BF}_3 \cdot \text{OEt}_2$ (13.8 mmol, 1.75 ml, 2.8 equiv.). The resulting mixture was allowed to warm to room temperature overnight. Saturated Na_2CO_3 (6ml) was added, the resulting mixture extracted with chloroform, the resulting phases
25 separated, the organic layer dried over MgSO_4 and evaporated to yield a residue. The residue was dissolved in ethyl acetate, then treated with methanol, resulting in the formation of a precipitate, which was filtered, to yield 5-(5-(5-bromo-2-chlorobenzyl)thiophen-2-yl)-2-fluoropyridine as a solid.

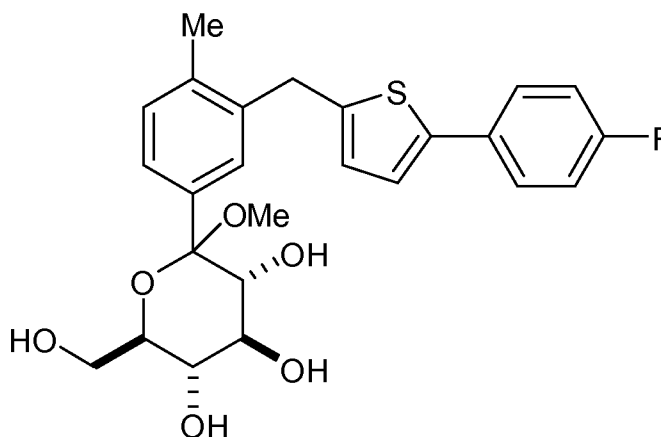
Example 10: 2-(4-Fluorophenyl)thiophene



A solution of 2-bromothiophene (233.0 g, 1.43 mol), 4-fluorophenyl boronic acid (200.0 g, 1.43 mol), bis(triphenylphosphine)palladium(II) dichloride (10.0 g, 14.2 mmol) and aqueous Na₂CO₃ (454.5 g, 4.3 mol in 1.5 L of H₂O) in 1,2-dimethoxyethane (2 L) was stirred at 75-80°C (internal temperature) for 2 hours. The resulting mixture was cooled to room temperature and then stirred overnight. The solid was separated and discarded. The liquid was washed with water (2 x 500 mL). The combined aqueous layer was extracted with diethylether (2 x 500 mL). The combined organic layers were then dried over NaCl, concentrated and purified by flask distillation to yield the title compound as a white solid.

Example 11

(3R,4S,5S,6R)-2-(3-((5-(4-fluorophenyl)thiophen-2-yl)methyl)-4-methylphenyl)-6-(hydroxymethyl)-2-methoxytetrahydro-2H-pyran-3,4,5-triol



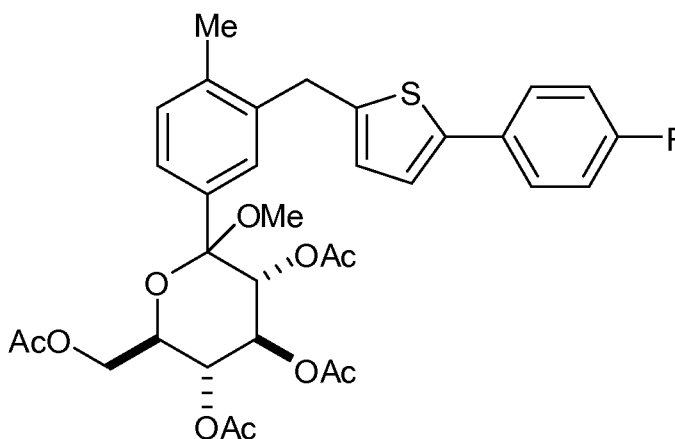
To a solution of 2-(5-iodo-2-methylbenzyl)-5-(4-fluorophenyl)thiophene (40.0 g) in anhydrous THF (200 mL) was added a solution of *i*-propyl magnesium chloride / lithium chloride in THF (14.5 wt%, 76.4 g) dropwise under N₂ at 0 - 5°C. The mixture was stirred for 1 hour at the same temperature, and then the mixture was added dropwise to a solution of 2,3,4,6-tetrakis-O-(trimethylsilyl)-D-glucopyrano-1,5-lactone (54.9 g; see U.S. patent No. 6,515,117) in anhydrous THF (80 mL) at 0 - 5°C. The reaction mixture was stirred for 2 hours and quenched with a solution of methanesulfonic acid (11.3 g) in methanol (400 mL) under cooling. Upon complete addition, the mixture was stirred for 2 hours under cooling, and then was warmed to room

temperature and stirred for 4 hours. The mixture was quenched in a solution of NaHCO₃ (4.12 g) in H₂O (400 mL) under cooling. The mixture was allowed to warm to room temperature, and then n-heptane was added to the mixture. After phase separation, the aqueous phase was extracted with ethyl acetate and toluene. The combined organic layer was washed with 5% aqueous NaHCO₃ solution, dried over anhydrous MgSO₄, and filtered to afford a solution of methyl 1-C-(3-[[5-(4-fluorophenyl)-2-thienyl]methyl]-4-methylphenyl)-D-glucopyranoside in ethyl acetate and toluene (assay yield 80% by HPLC; Column: Symmetry C18 4.6 mm x 150 mm; Mobile Phase: Phase A, 0.1% TFA in H₂O; Phase B, 0.1% TFA in CH₃CN).

m/z (APCI), 443 (M⁺-MeOH).

Example 12

(3R,4S,5R,6R)-6-(acetoxymethyl)-2-(3-((5-(4-fluorophenyl)thiophen-2-yl)methyl)-4-methylphenyl)-2-methoxytetrahydro-2H-pyran-3,4,5-triyl triacetate



To a stirred solution of methyl 1-C-(3-[[5-(4-fluorophenyl)-2-thienyl]methyl]-4-methylphenyl)-D-glucopyranoside (net weight 10.54 g) in toluene and ethyl acetate was added N-methylmorpholine (11.9 g) and 4-dimethylaminopyridine (217 mg) at room temperature. The solution was cooled to 0°C and acetic anhydride (52.7 mL) was added dropwise below 15°C. The reaction mixture was allowed to warm to room temperature and stirred for 15 hours. The mixture was quenched with 28% NH₃ aqueous solution (ca. 31.6 mL) while maintaining pH range of 6 to 7. Water was added to the mixture and separated. The organic layer was washed with water and brine, dried over

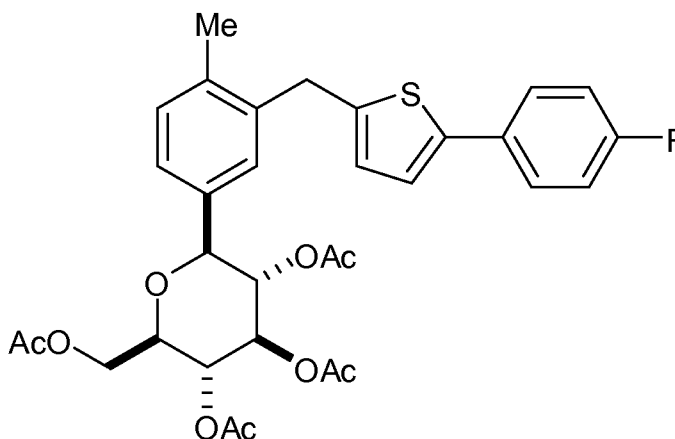
anhydrous MgSO_4 and filtered. The filtrate was concentrated in vacuo to give methyl 2,3,4,6-tetra-O-acetyl-1-C-(3-{[5-(4-fluorophenyl)-2-thienyl]methyl}-4-methylphenyl)-D-glucopyranoside (17.59 g) as yellow oil.

m/z (APCI) 660 ($\text{M}^+ + \text{NH}_4$).

5

Example 13

(2R,3R,4R,5S,6S)-2-(acetoxymethyl)-6-(3-((5-(4-fluorophenyl)thiophen-2-yl)methyl)-4-methylphenyl)tetrahydro-2H-pyran-3,4,5-triyl triacetate



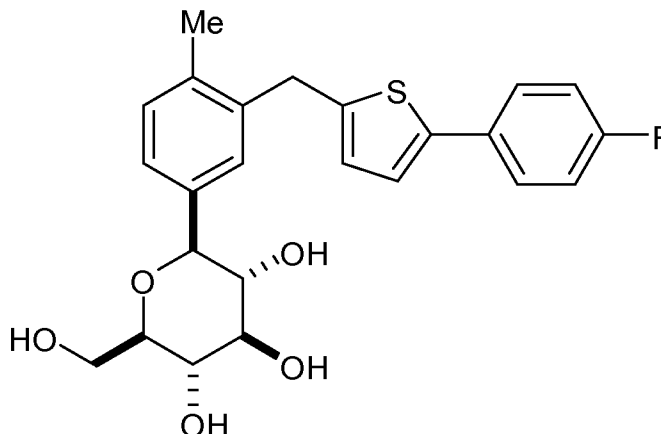
To a stirred solution of the above compound (net weight 14.25 g) in acetonitrile (114 mL) was added triethylsilane (7.74 g) at room temperature. The solution was cooled to 0°C and boron trifluoride etherate (9.45 g) was added dropwise for 10 minutes. The reaction mixture was stirred at 0°C for 4 hours. The mixture was quenched in a solution of 10% K_2CO_3 aqueous solution (156.8 mL) under cooling. The mixture was allowed to warm to room temperature and stirred for 15 minutes. After separation, water and ethyl acetate was added to the organic layer. The organic layer was washed with brine, and filtered. The filtrate was concentrated in vacuo. The resulting residue was suspended in ethanol and evaporated (twice). Ethanol was added to the residue and the resulting mixture was stirred for 30 minutes at 50°C, then cooled on an ice-bath. The precipitate was filtered and washed twice with ethanol, then dried to give (1S)-2,3,4,6-tetra-O-acetyl-1,5-anhydro-1-(3-{[5-(4-fluorophenyl)-2-thienyl]methyl}-4-methylphenyl)-D-glucitol (11.12 g) as white crystals.

m/z (APCI) 630 ($\text{M}^+ + \text{NH}_4$); mp. 160-170°C.

25

Example 14

(2S,3R,4R,5S,6R)-2-(3-((5-(4-fluorophenyl)thiophen-2-yl)methyl)-4-methylphenyl)-6-(hydroxymethyl)tetrahydro-2H-pyran-3,4,5-triol

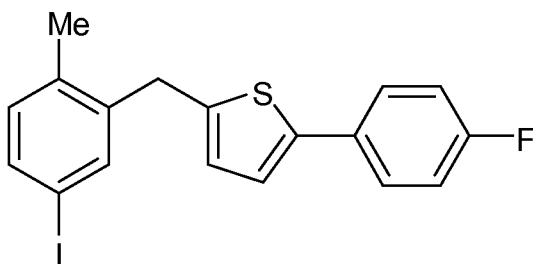


(1S)-2,3,4,6-tetra-O-acetyl-1,5-anhydro-1-(3-[[5-(4-fluorophenyl)-2-thienyl]methyl]-4-methylphenyl)-D-glucitol (5 g) was dissolved in methanol (35 mL) and tetrahydrofuran (25 mL) at room temperature. A solution of LiOH hydrate (192 mg) in water (10 mL) was added dropwise to the mixture for 30 minutes at 20 - 24°C. After the mixture was stirred for 19 hours at room temperature, the solvent was evaporated in vacuo. The residue was partitioned to ethyl acetate (50 mL) and water (25 mL), stirred for 15 minutes, then the layers were separated. The organic layer was washed with water. The organic layer was dried over Na₂SO₄, filtered using activated carbon pre-coated filter and evaporated. The resulting residue was dissolved in ethyl acetate (11.1 mL) at 40°C, water (241 mL) was added to the mixture at the same temperature. n-Heptane (5.6 mL) was added to the mixture at 40°C, then the mixture was seeded with a slight amount of (1S)-1,5-anhydro-1-(3-[[5-(4-fluorophenyl)-2-thienyl]methyl]-4-methylphenyl)-D-glucitol at same temperature. After stirred for 1 hour at 35°C, n-heptane (2.6 mL) was added slowly to the mixture. The resulting mixture was cooled. The precipitate was filtered and washed with ethyl acetate/n-heptane, then dried to give hemihydrate of (1S)-1,5-anhydro-1-(3-[[5-(4-fluorophenyl)-2-thienyl]methyl]-4-methylphenyl)-D-glucitol (2.93 g) as white crystals.

m/z (APCI) 462 (M⁺+NH₄); mp. 106-107°C

Example 15

2-(4-fluorophenyl)-5-(5-iodo-2-methylbenzyl)thiophene

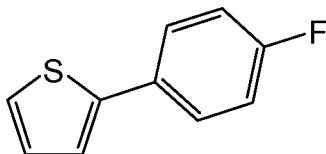


2-(5-bromo-2-methylbenzyl)-5-(4-fluorophenyl)thiophene (100 g); (see Nomura S., et al., PCT Publication, WO 2005/012326 A1, published February 10, 2005) was dissolved in toluene (300 mL) at room temperature under N₂ atmosphere. Sodium iodide (83 g), copper (I) iodide (2.64 g), *N,N'*-dimethyl ethylenediamine (2.94 mL) and diglyme (50 mL) was added to the mixture at room temperature. The reaction mixture was heated to reflux temperature and stirred for 36 hours. Ethyl acetate (300 mL) was added to the mixture at 40°C and the mixture was filtered using activated carbon pre-coated filter. The filtrate was washed twice with 5% aqueous NH₃ solution (100 mL). The organic layer was washed with water (100 mL) and then evaporated. The resulting residue was suspended in methanol (426 mL) at reflux temperature for 75 minutes. The resulting slurry was cooled to 25°C and stirred for 1 hour. The precipitate was filtered and washed with methanol, then dried at 50°C in vacuo to give 2-(5-iodo-2-methylbenzyl)-5-(4-fluorophenyl)thiophene (94.9 g) as white crystals.

m/z (APCI), 409(M⁺+H); mp 109-110°C; ¹H NMR (400 MHz, CDCl₃); δ 7.54 (d, ⁴J_{HH} = 1.8 Hz, 1H), 7.45-7.42 (m, 3H), 7.07-6.99 (m, 3H), 6.92 (d, ³J_{HH} = 6.0 Hz, 1H), 6.66 (d, ³J_{HH} = 3.6 Hz, 1H), 4.05 (s, 2H), 2.26 (s, 3H).

20

Example 16: 2-(4-Fluorophenyl)thiophene



To a stirred solution of 2-bromothiophene (100g, 613.3 mol) in dry THF (220mL), at 50°C, under a nitrogen atmosphere were added Pd(OAc)₂ (13.8 mg, 0.06 mmol) and 1,3-bis(diphenylphosphino)propane (25.3 mg, 0.06 mmol). After 5 minutes, 1.05 M 4-fluorophenylmagnesium bromide in THF (613 mL) was added over 6.0 hours (TOF = 1750). The resulting mixture was stirred for

25

- 1 hour at 60°C, then cooled to 30°C and slowly poured into a 2M HCl aqueous solution (600 mL) in an ice bath. DCM (300 mL) was added and the resulting mixture was separated, and washed with brine (200 mL). MgSO₄ (20 g) and activated charcoal (10g) were added and the resulting mixture was stirred. The
- 5 mixture was then filtered, and the filtrate concentrated to yield the title compound as a residue, which was used without further purification.

Example 17:

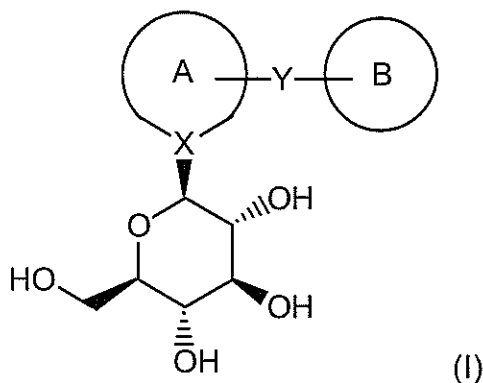
Oral Solid Dosage Form – Prophetic Example

- As a specific embodiment of an oral composition, 100 mg of the
- 10 compound prepared as in Example 5 or Example 6 above, is formulated with sufficient finely divided lactose to provide a total amount of 580 to 590 mg to fill a size O hard gel capsule.

- While the foregoing specification teaches the principles of the present invention, with examples provided for the purpose of illustration, it will be
- 15 understood that the practice of the invention encompasses all of the usual variations, adaptations and/or modifications as come within the scope of the following claims and their equivalents.

We claim

1. A process for the preparation of compounds of formula (I)



wherein Ring A and Ring B are one of the following:

(1) Ring A is an optionally substituted unsaturated monocyclic heterocyclic ring, and Ring B is an optionally substituted unsaturated monocyclic heterocyclic ring, an optionally substituted unsaturated fused heterobicyclic ring, or an optionally substituted benzene ring; or

(2) Ring A is an optionally substituted benzene ring, and Ring B is an optionally substituted unsaturated monocyclic heterocyclic ring, or an optionally substituted unsaturated fused heterobicyclic ring wherein Y is linked to the heterocyclic ring of the fused heterobicyclic ring; or

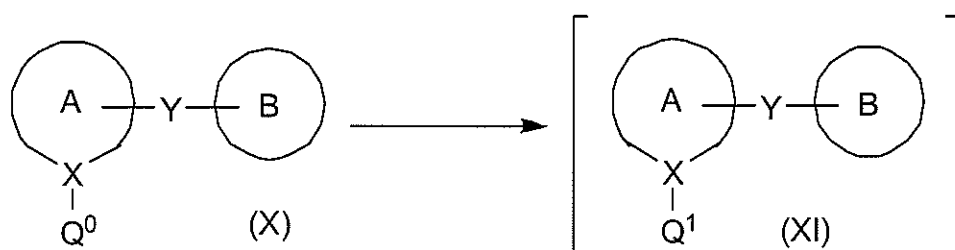
(3) Ring A is an optionally substituted unsaturated fused heterobicyclic ring, wherein the sugar moiety X-(sugar) and the moiety -Y-(Ring B) are both on the same heterocyclic ring of the fused heterobicyclic ring, and Ring B is an optionally substituted unsaturated monocyclic heterocyclic ring, an optionally substituted unsaturated fused heterobicyclic ring, or an optionally substituted benzene ring;

X is a carbon atom;

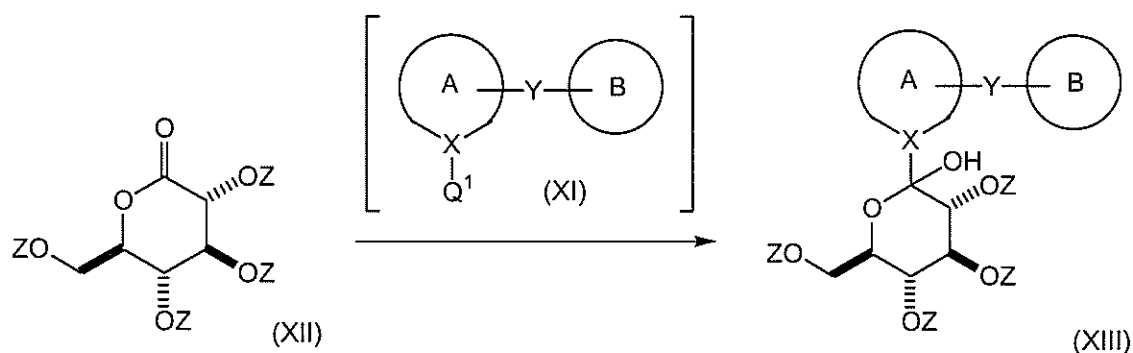
Y is $-(CH_2)_n-$; wherein n is 1 or 2;

provided that in Ring A, X is part of an unsaturated bond;

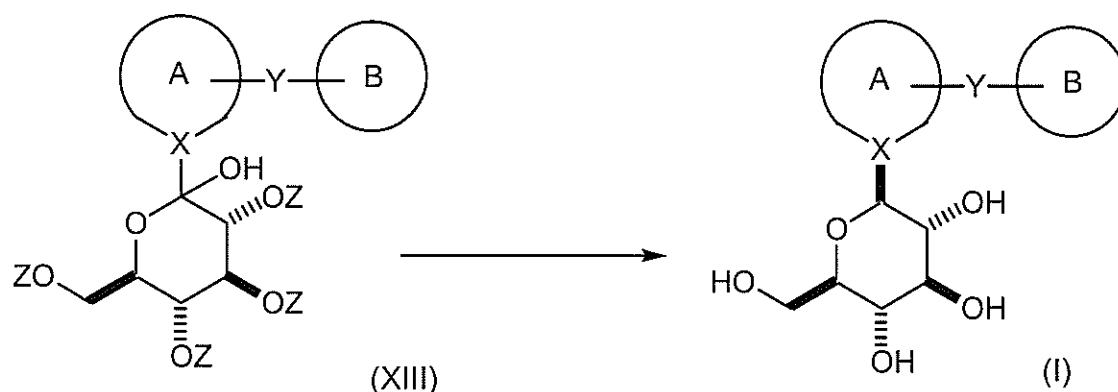
or a pharmaceutically acceptable salt or solvate thereof; comprising



reacting a compound of formula (X) wherein Q^0 is bromo or iodo with a complex of di(C_{1-4} alkyl)magnesium with lithium chloride or a complex of C_{1-4} alkyl magnesium chloride with lithium chloride or a complex of C_{1-4} alkyl magnesium bromide with lithium chloride; in an organic solvent or mixture thereof; at a temperature in the range of from about ambient temperature to about -78°C ; to yield the corresponding compound of formula (XI), wherein Q^1 is the corresponding MgCl or MgBr;

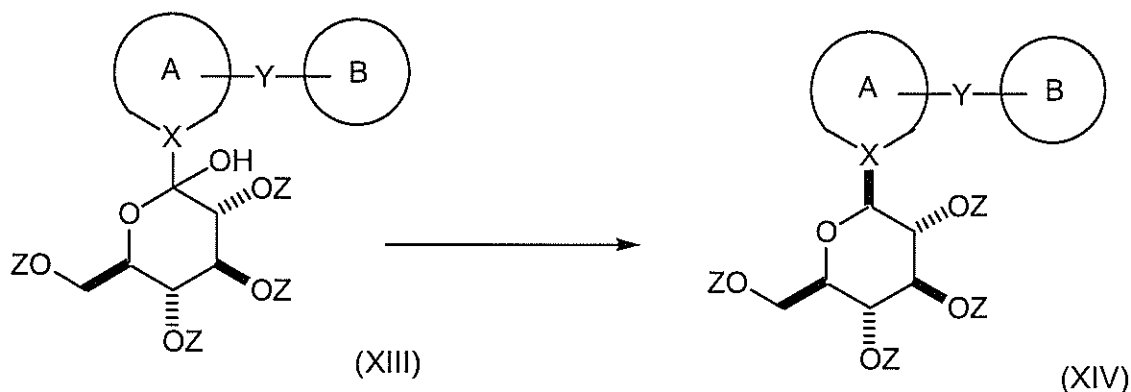


reacting the compound of formula (XI) with a compound of formula (XII), wherein Z is an oxygen protecting group selected from the group consisting of acetyl and pivaloyl; in an organic solvent or mixture thereof; at a temperature in the range of from about ambient temperature to about -78°C ; to yield the corresponding compound of formula (XIII);

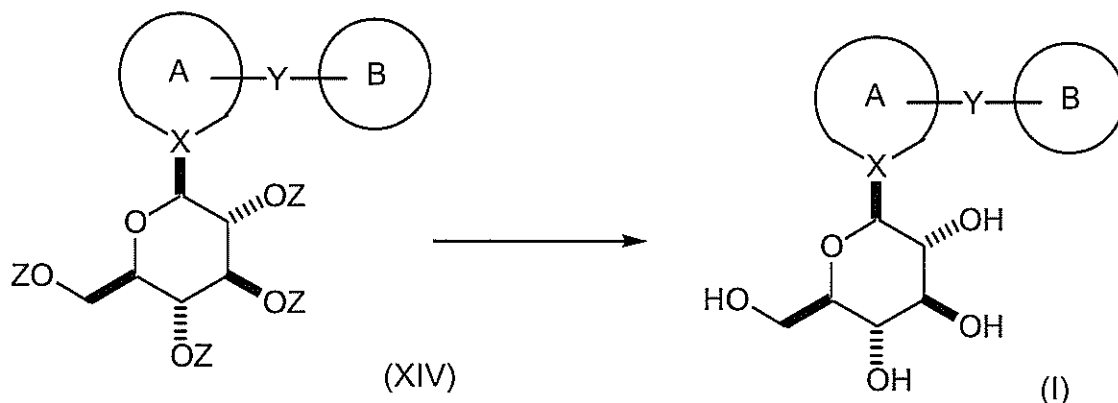


reacting the compound of formula (XIII), to yield the corresponding compound of formula (I).

2. A process as in Claim 1, further comprising



reacting the compound of formula (XIII) with a Lewis acid; in the presence of a trialkylsilane; in an organic solvent or mixture thereof; at a temperature in the range of from about 0°C to about reflux; to yield the corresponding compound of formula (XIV);



de-protecting the compound of formula (XIV); to yield the corresponding compound of formula (I).

3. A process as in Claim 1, wherein

X is a carbon atom;

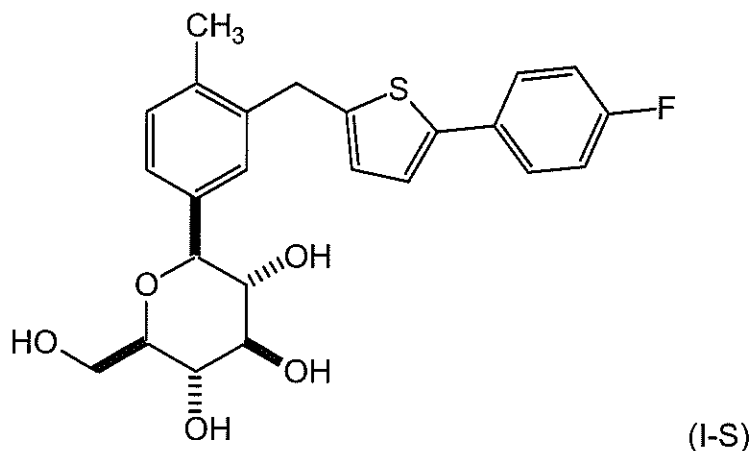
Ring A is selected from the group consisting of 4-methylphenyl and 4-chlorophenyl;

Y is $-\text{CH}_2-$ and is bound at the 3-position of Ring A; and

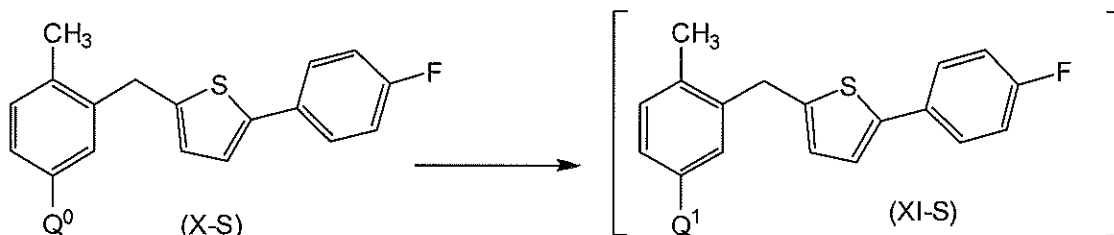
Ring B is selected from the group consisting of 2-(5-(4-fluorophenyl)-thienyl) and 2-(5-(6-fluoro-pyrid-3-yl)-thienyl).

4. A process as in Claim 1, wherein the compound of formula (X) is reacted with a complex of di(C₁₋₄alkyl)magnesium with lithium chloride; and wherein the complex of di(C₁₋₄alkyl)magnesium with lithium chloride is a complex of di(sec-butyl)magnesium with lithium chloride; to yield the corresponding compound of formula (XI) wherein Q¹ is MgCl.

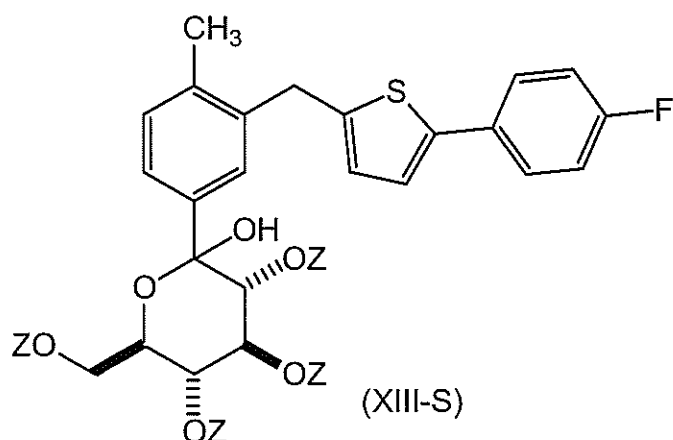
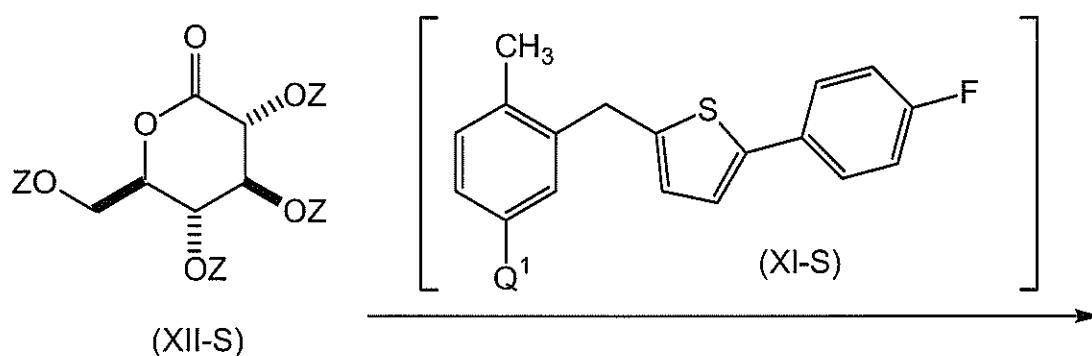
5. A process for the preparation of a compound of formula (I-S)



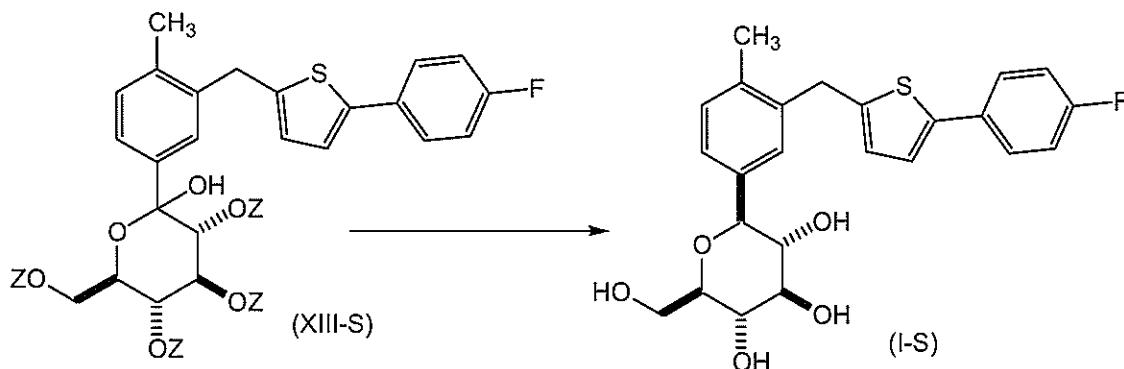
or solvate thereof; comprising



reacting a compound of formula (X-S) wherein Q⁰ is bromo or iodo with a complex of di(C₁₋₄alkyl)magnesium with lithium chloride or complex of C₁₋₄alkyl magnesium chloride with lithium chloride or a complex of C₁₋₄alkyl magnesium bromide with lithium chloride; in an organic solvent or mixture thereof; at a temperature in the range of from about ambient temperature to about -78°C; to yield the corresponding compound of formula (XI-S), wherein Q¹ is the corresponding MgCl or MgBr;

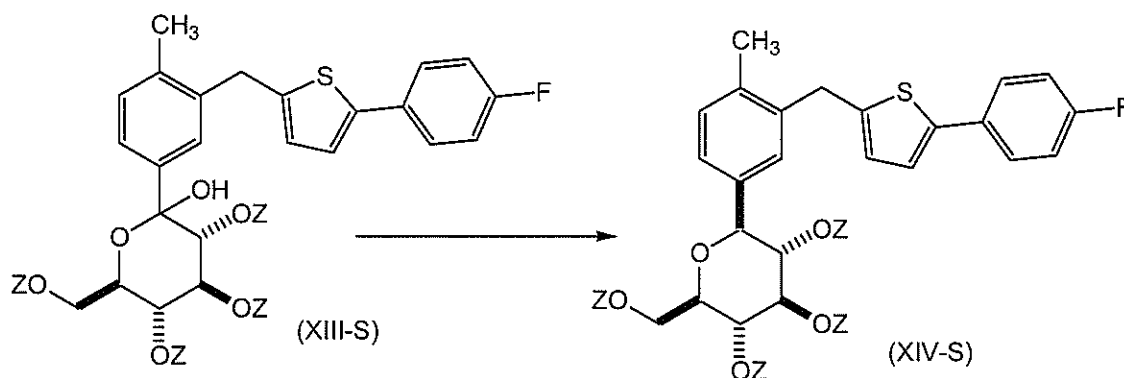


reacting the compound of formula (XI-S) with a compound of formula (XII-S), wherein Z is an oxygen protecting group selected from the group consisting of acetyl and pivaloyl; in an organic solvent or mixture thereof; at a temperature in the range of from about ambient temperature to about -78°C ; to yield the corresponding compound of formula (XIII-S);

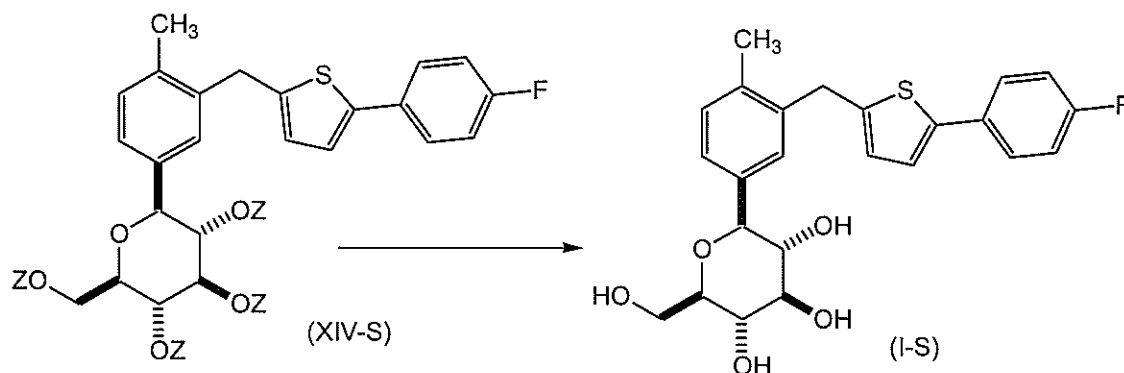


reacting the compound of formula (XIII-S), to yield the corresponding compound of formula (I-S).

6. A process as in Claim 5, further comprising



reacting the compound of formula (XIII-S) with a Lewis acid; in the presence of a silane reagent; in an organic solvent or mixture thereof; at a temperature in the range of from about 0°C to about reflux; to yield the corresponding compound of formula (XIV-S);



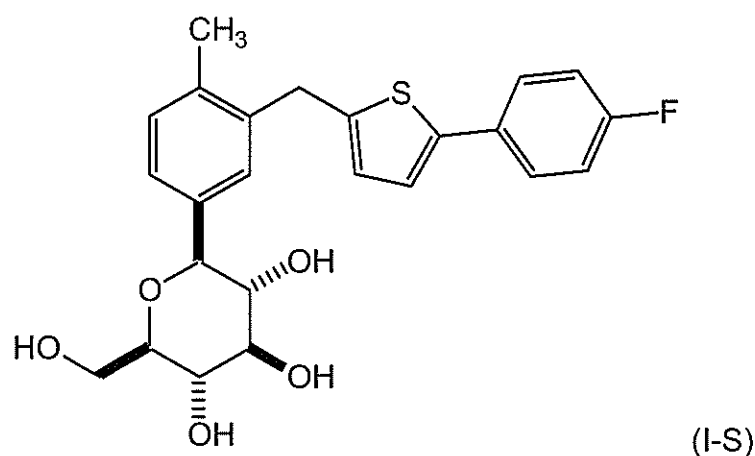
de-protecting the compound of formula (XIV-S); to yield the corresponding compound of formula (I-S).

7. A process as in Claim 5, wherein the complex of di(C₁₋₄alkyl)magnesium with lithium chloride or the complex of C₁₋₄alkyl magnesium chloride with lithium chloride or the complex of C₁₋₄alkyl magnesium bromide with lithium chloride is present in an amount in the range of from about 1.0 to about 1.5 molar equivalents.

8. A process as in Claim 5, wherein the compound of formula (X-S) is reacted with a complex of di(C₁₋₄alkyl)magnesium with lithium chloride; and wherein the complex of di(C₁₋₄alkyl)magnesium with lithium chloride is a complex of di(sec-butyl)magnesium with lithium chloride; to yield the corresponding compound of formula (XI-S) wherein Q¹ is MgCl.

9. A process as in Claim 8, wherein the complex of di(sec-butyl)magnesium with lithium chloride is present in an amount in the range of from about 1.0 to about 1.5 molar equivalents.
10. A process as in Claim 5, wherein Z is acetyl.
11. A process as in Claim 5, wherein the compound of formula (XII-S) is present in an amount in the range of from about 1.0 to about 2.0 molar equivalents.
12. A process as in Claim 5, wherein, when the compound of formula (XI-S) is reacted with the compound of formula (XII-S), the compound of formula (XI-S) is added to a mixture of the compound of formula (XII-S) in an organic solvent or mixture thereof.
13. A process as in Claim 6, wherein the Lewis acid is selected from the group consisting of $\text{BF}_3 \cdot \text{OEt}_2$, $\text{BF}_3 \cdot \text{THF}$, aluminum chloride, zinc chloride and iron chloride; and wherein the silane is selected from the group consisting of triethylsilane, triisopropylsilane and tetramethyldisiloxane.
14. A process as in Claim 13, wherein the Lewis acid is aluminum chloride and wherein the aluminum chloride is present in an amount in the range of from about 0.5 to about 2.5 molar equivalents.
15. A process as in Claim 13, wherein the silane reagent is tetramethyldisiloxane; and wherein the tetramethyldisiloxane is present in an amount in the range of from about 1.0 to about 2.5 molar equivalents.
16. A process as in Claim 13, wherein the Lewis acid is aluminum chloride; wherein the silane reagent is tetramethyldisiloxane; and wherein the molar ratio of aluminum chloride to tetramethyldisiloxane is about 1 : 1.25.

17. The process of claim 5, further comprising recrystallizing the compound of formula (I-S)



comprising

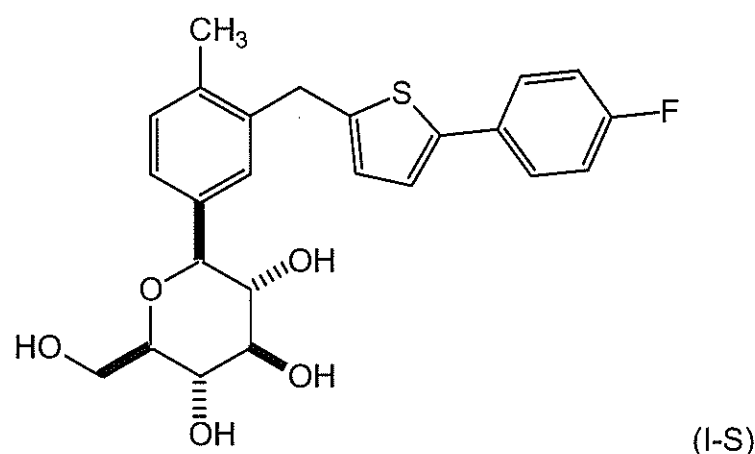
STEP A: dissolving a compound of formula (I-S) in an organic solvent;

STEP B: heating the mixture of STEP A to a temperature in the range of from about 25°C to about 45°C;

STEP C: adding water to the mixture prepared in STEP B; wherein the amount of water added is preferably in an amount in the range of from about 1.0 to about 2.0 molar equivalents;

STEP D: adding an anti-solvent to the mixture prepared in STEP C; to yield a precipitate of the compound of formula (I-S).

18. The process of claim 5, further comprising recrystallizing the compound of formula (I-S)



comprising

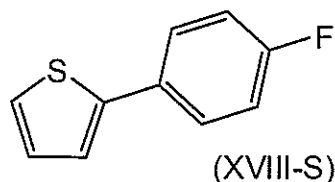
STEP A: dissolving a compound of formula (I-S) in an organic solvent;

STEP B: adding water to the mixture prepared in STEP A; wherein the amount of water added is preferably in an amount in the range of from about 1.0 to about 2.0 molar equivalents;

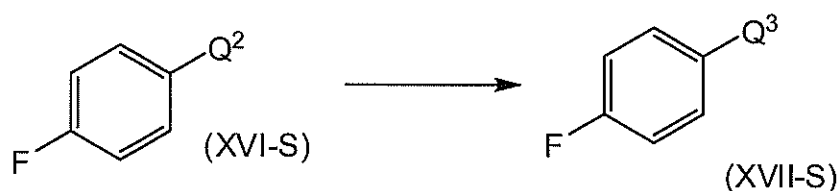
STEP C: heating the mixture of STEP B to a temperature in the range of from about 40°C to about 65°C;

STEP D: cooling the mixture prepared in STEP C; to yield a precipitate of the compound of formula (I-S).

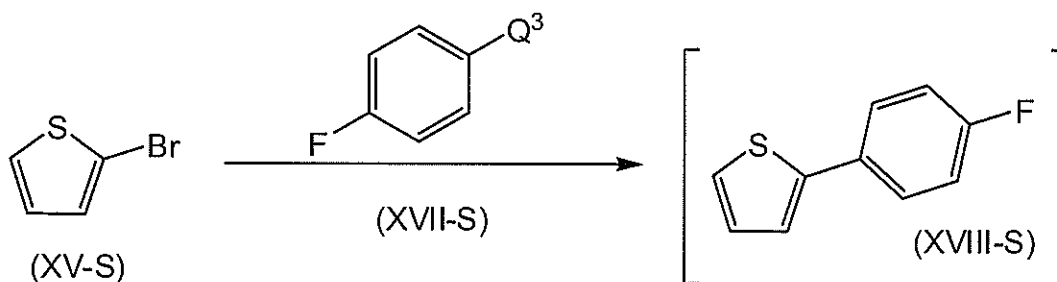
19. A process for the preparation of a compound of formula (XVIII-S)



comprising



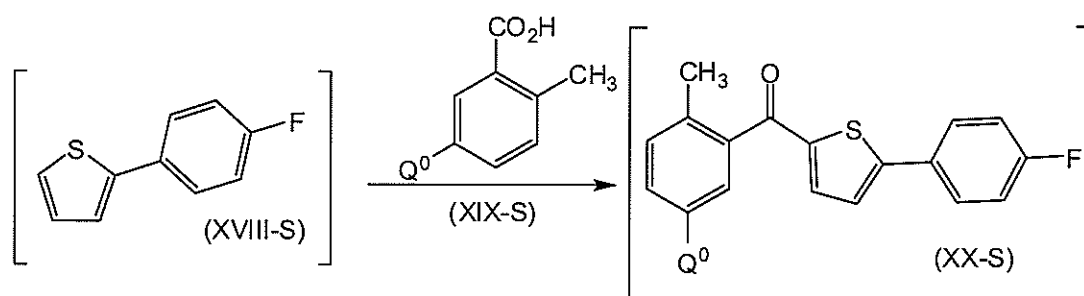
reacting a compound of formula (XVI-S), wherein Q^2 is bromo, chloro or iodo, with a magnesium reagent; in an organic solvent; to yield the corresponding compound of formula (XVII-S), wherein Q^3 is the corresponding Grignard species;



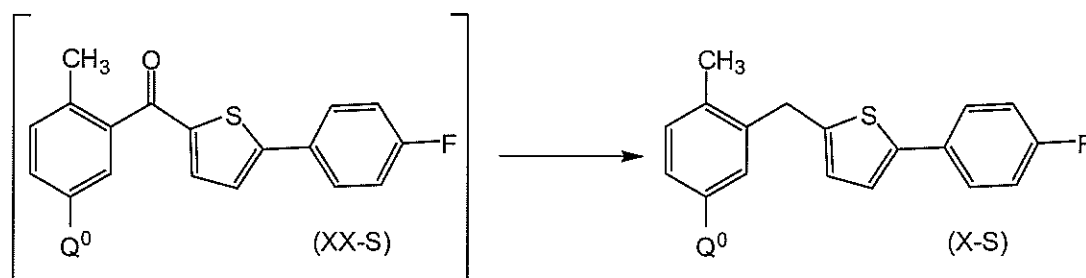
reacting a compound of formula (XV-S) with the compound of formula (XVII-S); in the presence of a Ni or Pd catalyst; in an organic solvent to yield the corresponding compound of formula (XVIII-S).

20. A process as in Claim 19, wherein Q^2 is bromo and wherein Q^3 is MgBr.

21. A process as in Claim 19, wherein the magnesium reagent is magnesium.
22. A process as in Claim 19, wherein the Ni or Pd catalyst is $\text{NiCl}_2(\text{dppe})$.
23. A process as in Claim 19, wherein the compound of formula (XV-S) is reacted with the compound of formula (XVII-S) in the presence of a ligand.
24. A process as in Claim 23, wherein the Ni or Pd catalyst is $\text{Pd}(\text{OAc})_2$ and the ligand is 1,3-bis(diphenylphosphino)propane.
25. A process as in Claim 19, further comprising

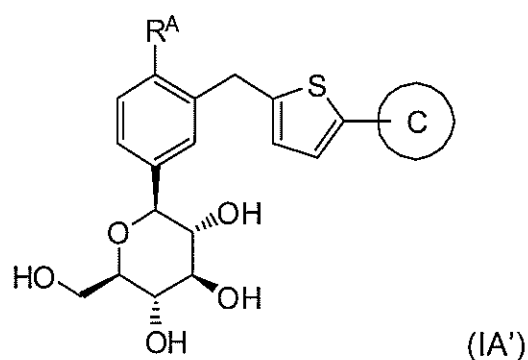


reacting the compound of formula (XVIII-S) with a compound of formula (XIX-S), wherein Q^0 is bromo or iodo; to yield the corresponding compound of formula (XX-S);



reducing the compound of formula (XX-S); to yield the corresponding compound of formula (X-S).

26. A process as in Claim 25, wherein Q^0 is iodo.
27. A process for the preparation of a compound of formula (IA')



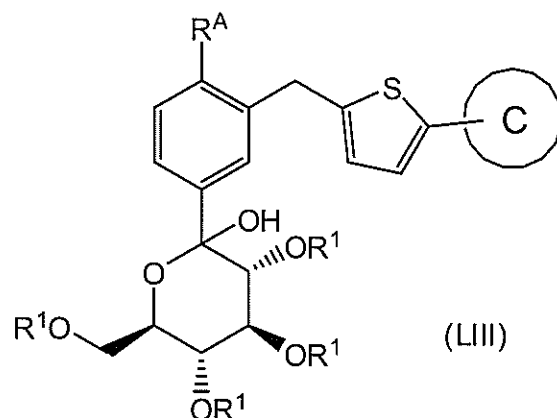
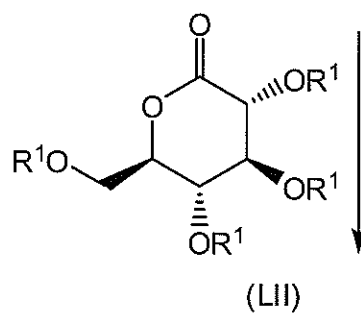
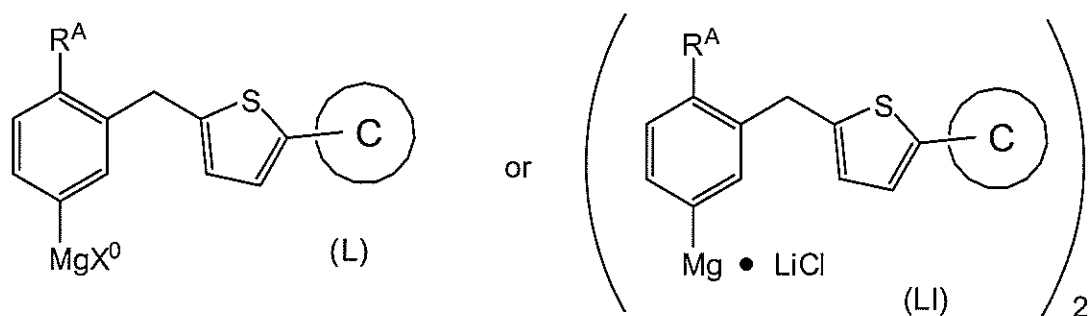
wherein

R^A is halogen or lower alkyl;

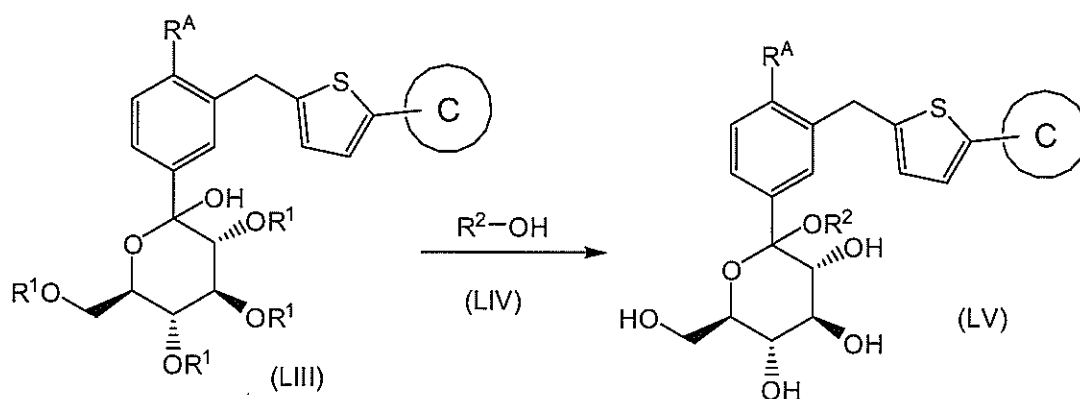
Ring C is phenyl substituted with 1-3 substituents selected from the group consisting of halogen, cyano, lower alkyl, halo-lower alkyl, lower alkoxy, halo-lower alkoxy, methylenedioxy, ethyleneoxy, mono- or di-lower alkylamino, carbamoyl, and mono- or di-lower alkylcarbamoyl;

or heterocyclyl substituted by 1-3 substituents selected from the group consisting of halogen, cyano, lower alkyl, halo-lower alkyl, lower alkoxy, halo-lower alkoxy, mono- or di-lower alkylamino, carbamoyl, and mono- or di-lower alkylcarbamoyl;

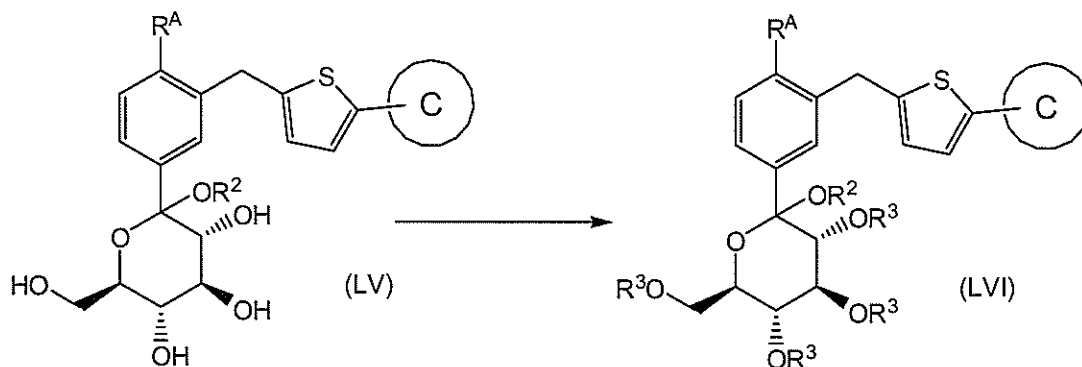
or a pharmaceutically acceptable salt thereof; comprising steps of:



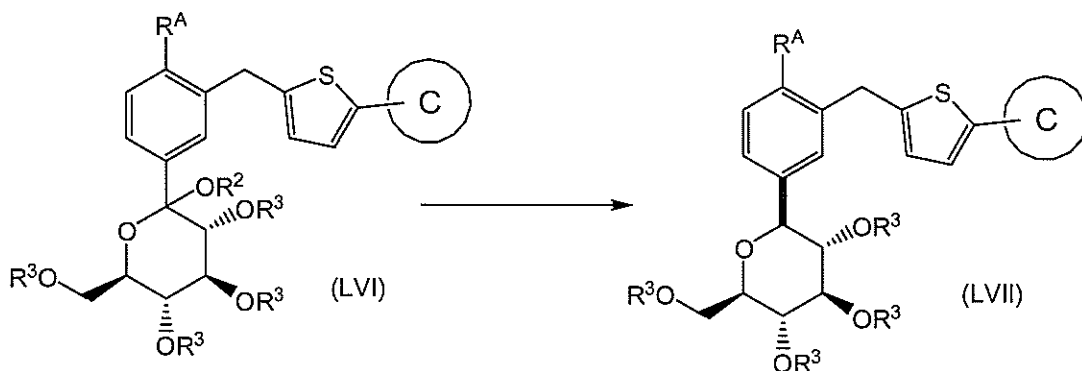
reacting a compound of formula (L) wherein X^0 is selected from the group consisting of Cl, Br, I and $Cl \cdot LiCl$ or a compound of formula (LI) with a compound of formula (LII), wherein R^1 is tri-lower alkyl silyl; to yield the corresponding compound of formula (LIII);



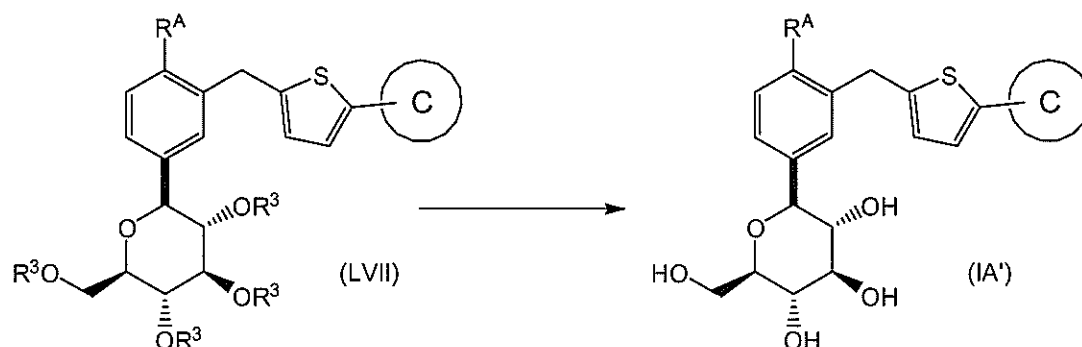
reacting the compound of formula (LVII) with an alcohol of formula (LIV), wherein R^2 is lower alkyl; in the presence of an acid; to yield the corresponding compound of formula (LV);



protecting the hydroxyl groups on the compound of formula (LV); to yield the corresponding compound of formula (LVI); wherein each R^3 is an oxygen protecting group which is acetyl;



reducing the compound of formula (LVI); to yield the corresponding compound of formula (LVII);



removing the oxygen protecting groups of the compound of formula (LVII); to yield the corresponding compound of formula (IA').

28. A process as in Claim 27, wherein R^1 is trimethylsilyl, R^2 is methyl or ethyl, and R^3 is acetyl.
29. A process as in Claim 27, wherein the alcohol of formula (LIV) is methanol or ethanol and wherein the acid is an organic acid.
30. A process as in Claim 27, wherein the compound of formula (LVI) is reduced by reacting with a silane reagent, in the presence of an acid.
31. A process as in Claim 27, wherein the silane reagent is a tri-lower alkyl silane and wherein the acid is a Lewis acid.